

This Page Is Inserted by IFW Operations
and is not a part of the Official Record

BEST AVAILABLE IMAGES

Defective images within this document are accurate representations of the original documents submitted by the applicant.

Defects in the images may include (but are not limited to):

- BLACK BORDERS
- TEXT CUT OFF AT TOP, BOTTOM OR SIDES
- FADED TEXT
- ILLEGIBLE TEXT
- SKEWED/SLANTED IMAGES
- COLORED PHOTOS
- BLACK OR VERY BLACK AND WHITE DARK PHOTOS
- GRAY SCALE DOCUMENTS

IMAGES ARE BEST AVAILABLE COPY.

**As rescanning documents *will not* correct images,
please do not report the images to the
Image Problem Mailbox.**

PCT

WORLD INTELLECTUAL PROPERTY ORGANIZATION
International Bureau



INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(51) International Patent Classification 6 : C07C 45/00, 209/40, 239/08, 259/06, 291/04, C07D 307/33, 311/68, 313/12, C08F 212/08, 212/36		A1	(11) International Publication Number: WO 98/29376 (43) International Publication Date: 9 July 1998 (09.07.98)
 (21) International Application Number: PCT/US97/23920 (22) International Filing Date: 17 December 1997 (17.12.97) (30) Priority Data: 60/032,453 19 December 1996 (19.12.96) US 60/033,881 24 December 1996 (24.12.96) US (71) Applicant (for all designated States except US): RHONE-POULENC RORER PHARMACEUTICALS INC. [US/US]; Legal/Patents, Mail Stop #3C43, P.O. Box 5093, Collegeville, PA 19426-0997 (US). (72) Inventors; and (75) Inventors/Applicants (for US only): SALVINO, Joseph, M. [US/US]; 272 Second Street, Schwenksville, PA 19473 (US). MORTON, George, C. [US/US]; 206 Bassett Court, Limerick, PA 19468 (US). MASON, Helen, J. [US/US]; 8 Foxcroft Lane, Phoenixville, PA 19460 (US). LABAUDINIÈRE, Richard, F. [FR/US]; 220 Richard Way, Collegeville, PA 19426 (US). (74) Agents: MARTIN, Michael, B. et al.; Rhône-Poulenc Rorer Pharmaceuticals Inc., P.O. Box 5093, Mail Stop 3C43, Collegeville, PA 19426-0997 (US).		 (81) Designated States: AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, CA, CN, CU, CZ, DE, DK, EE, ES, FI, GB, GE, GH, HU, IL, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MD, MG, MK, MN, MW, MX, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR, TT, UA, UG, US, UZ, VN, YU, ZW, ARIPO patent (GH, GM, KE, LS, MW, SD, SZ, UG, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, CH, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, ML, MR, NE, SN, TD, TG). Published With international search report. Before the expiration of the time limit for amending the claims and to be republished in the event of the receipt of amendments.	
 (54) Title: PROCESS FOR THE SOLID PHASE SYNTHESIS OF ALDEHYDES, KETONES, OXIMES, AMINES AND HYDROXAMIC ACID COMPOUNDS (57) Abstract This invention is directed to processes for the solid-phase synthesis of aldehydes, ketones, oximes, amines and hydroxamic acid compounds and to polymeric hydroxylamine resin compounds useful therefor.			

FOR THE PURPOSES OF INFORMATION ONLY

Codes used to identify States party to the PCT on the front pages of pamphlets publishing international applications under the PCT.

AL	Albania	ES	Spain	LS	Lesotho	SI	Slovenia
AM	Armenia	FI	Finland	LT	Lithuania	SK	Slovakia
AT	Austria	FR	France	LU	Luxembourg	SN	Senegal
AU	Australia	GA	Gabon	LV	Latvia	SZ	Swaziland
AZ	Azerbaijan	GB	United Kingdom	MC	Monaco	TD	Chad
BA	Bosnia and Herzegovina	GE	Georgia	MD	Republic of Moldova	TG	Togo
BB	Barbados	GH	Ghana	MG	Madagascar	TJ	Tajikistan
BE	Belgium	GN	Guinea	MK	The former Yugoslav Republic of Macedonia	TM	Turkmenistan
BF	Burkina Faso	GR	Greece	ML	Mali	TR	Turkey
BG	Bulgaria	HU	Hungary	MN	Mongolia	TT	Trinidad and Tobago
BJ	Benin	IE	Ireland	MR	Mauritania	UA	Ukraine
BR	Brazil	IL	Israel	MW	Malawi	UG	Uganda
BY	Belarus	IS	Iceland	MX	Mexico	US	United States of America
CA	Canada	IT	Italy	NE	Niger	UZ	Uzbekistan
CF	Central African Republic	JP	Japan	NL	Netherlands	VN	Viet Nam
CG	Congo	KE	Kenya	NO	Norway	YU	Yugoslavia
CH	Switzerland	KG	Kyrgyzstan	NZ	New Zealand	ZW	Zimbabwe
CI	Côte d'Ivoire	KP	Democratic People's Republic of Korea	PL	Poland		
CM	Cameroon	KR	Republic of Korea	PT	Portugal		
CN	China	KZ	Kazakhstan	RO	Romania		
CU	Cuba	LC	Saint Lucia	RU	Russian Federation		
CZ	Czech Republic	LI	Liechtenstein	SD	Sudan		
DE	Germany	LK	Sri Lanka	SE	Sweden		
DK	Denmark	LR	Liberia	SG	Singapore		

PROCESS FOR THE SOLID PHASE SYNTHESIS OF ALDEHYDES,
KETONES, OXIMES, AMINES AND HYDROXAMIC ACID COMPOUNDS

FIELD OF THE INVENTION

5

This invention is directed processes for the solid-phase synthesis of aldehydes, ketones, oximes, amines and hydroxamic acid compounds and to polymeric hydroxylamine resin compounds useful therefor.

10 BACKGROUND OF THE INVENTION

Solid-phase synthetic techniques, in which a reagent is immobilized on a polymeric material which is inert to the reagents and reaction conditions employed, as well as being insoluble in the media used, are important tools for preparing amides, peptides and hydroxamic acids. For solid phase peptide synthesis, a summary of the many techniques may be found in J.M. Stewart and J.D. Young, *Solid Phase Peptide Synthesis*, 2nd. Ed., Pierce Chemical Co. (Chicago, IL, 1984); J. Meienhofer, *Hormonal Proteins and Peptides*, vol. 2, p. 46, Academic Press (New York), 1973; and E. Atherton and R.C. Sheppard, *Solid Phase Peptide Synthesis: A Practical Approach*, IRL Press at Oxford University Press (Oxford, 1989). For the use of solid phase methodology in the preparation of non-peptide molecules see Leznoff, C.C., *Acc. Chem. Res.*, 11, 327-333 (1978).

A number of polymeric reagents have found synthetic use in simple functional group transformations. See A. Akelah and D.C. Sherrington, Application of Functionalized Polymers in Organic Synthesis, *Chem Rev.*, 81, 557-587 (1981) and W. T. Ford and E. C. Blossey, *Polymer Supported Reagents, Polymer supported Catalysts, and Polymer Supported Coupling Reactions, in Preparative Chemistry using Supported Reagents*, Pierre Laszlo, ed., Academic Press, Inc, 193-212 (1987). For the use of polymeric reagents in oxidation reactions see J. M. J. Frechet et al., *J. Org. Chem.*, 43, 2618 (1978) and G. Cainelli et al., *J. Am. Chem. Soc.*, 98, 6737 (1976). For the use of polymeric reagents in halogenation reactions see J. M. J. Frechet et al., *J. Macromol. Sci. Chem.*, A-11, 507 (1977) and D. C. Sherrington et al., *Eur. Polym. J.*, 13, 73, (1977). For the use of polymeric reagents in epoxidation reactions see J. M. J. Frechet et al., *Macromolecules*, 8, 130 (1975) and C. R. Harrison et al., *J. Chem. Soc. Chem. Commun.*, 1009 (1974). For the use of polymeric reagents in acylation reactions see M. B. Shambhu et al., *Tet. Lett.*, 1627 (1973) and M. B. Shambhu et al., *J. Chem. Soc. Chem. Commun.*, 619 (1974). For the use of polymeric reagents in Wittig reactions see S. V. McKinley et al., *J. Chem. Soc. Chem. Commun.*, 134 (1972).

35 Polymeric reagents have also found widespread use in combinatorial synthesis and for preparing combinatorial libraries. See F. Balkenhol et al., *Angew. Chem. Int. Ed. Engl.*, 35, 2288-2337 (1996) and L.A. Thompson et al., *Chem Rev.*, 96, 555-600 (1996).

A polymeric reagent has the advantage of ease of separation from low molecular weight reactants or products by filtration or selective precipitation. The polymeric reagent can also be used in excess to effect fast and quantitative reactions such as in the case of acylations, or a large excess of reactants may be used to drive the equilibrium of the reaction towards product formation to provide essentially

quantitative conversion to product, as seen in solid phase peptide synthesis. A further advantage of supported reagents and catalysts is the fact that they are recyclable and that they lend easily to automated processes. In addition, supported analogs of toxic and odorous reagents are safer to use.

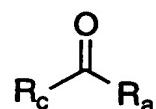
PCT application publication no. WO96/26223 discloses the synthesis of hydroxamic acid compounds using a solid phase hydroxylamine substrate.

Prasad et al. disclose a O-methylhydroxylamine-polystyrene resin compound in *J. Steroid Biochem.*, 18, 257-261 (1983).

SUMMARY OF THE INVENTION

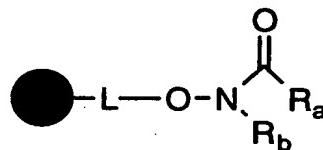
10

This invention is directed to a process for the preparation of a ketone compound of formula



15 wherein R_c and R_a are independently aliphatic or aromatic, comprising

(a) reacting an N-alkylated polymeric hydroxamic acid resin compound of formula



20

wherein \bullet is a solid support, L is absent or a linking group and R_b is aliphatic or aryl

with an organometallic reagent of formula R_cM wherein R_c is an aliphatic or aryl anion and M is a metal cation; and

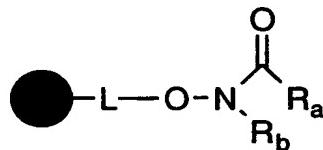
25

(b) liberating the ketone compound from the resin.

In another aspect, this invention is directed to a process for the preparation of an aldehyde compound of formula R_aCHO wherein R_a is defined above, comprising

30

(a) reacting an N-alkylated polymeric hydroxamic acid resin compound of formula

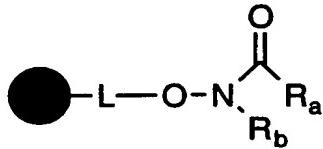


wherein [REDACTED], L and R_a and R_b are defined above;

5 with a reducing agent; and

(b) liberating the aldehyde compound from the resin.

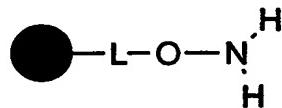
In another aspect, this invention is directed to a process for the preparation of a N-alkylated
10 polymeric hydroxamic acid resin compound of formula



wherein [REDACTED], L and R_a and R_b are defined above, comprising

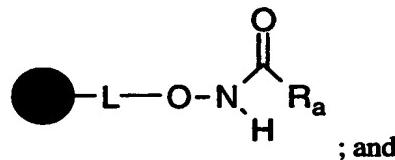
15

(a) coupling a carboxylic acid compound of formula R_aCO₂H with a polymeric hydroxylamine resin compound of formula



20

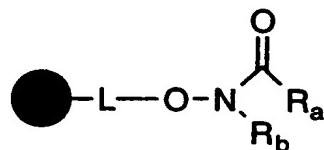
to form a polymeric hydroxamic acid resin compound of formula



; and

25 (b) reacting the polymeric hydroxamic acid resin compound with an alkylating agent of formula R_bLG wherein LG is a leaving group.

In another aspect, this invention is directed to a process for the preparation of a N-alkylated polymeric hydroxamic acid resin compound of formula

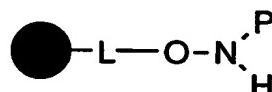


5

wherein , L and R_a and R_b are defined above, comprising

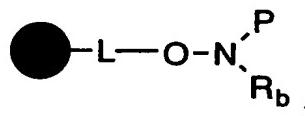
- (a) reacting a N-protected polymeric hydroxamic acid resin compound of formula

10



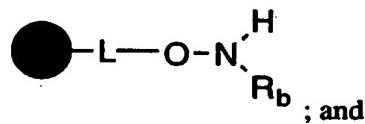
wherein P is an amine protecting group, with an alkylating agent of formula R_aLG wherein LG is defined above, to form a polymeric N-protected N-alkylated hydroxylamine resin compound of formula

15



- (b) removing the amine protecting group to form a polymeric N-alkylated hydroxylamine resin compound of formula

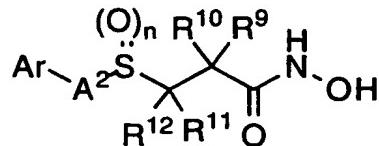
20



- (c) coupling the polymeric N-alkylated hydroxylamine resin compound with a carboxylic acid compound of formula R_aCO₂H.

25

In another aspect, this invention is directed to a process for preparing a hydroxamic acid compound of formula



wherein

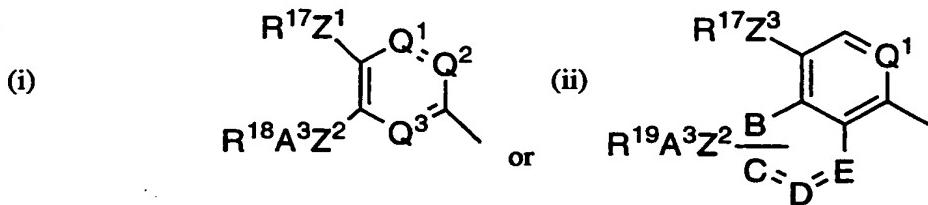
5 A^2 is a direct bond or an alkylene, or NR^{13} wherein R^{13} is hydrogen or alkyl;

R^9 is a group of formula $-\text{L}^1-\text{R}^{14}$, where L^1 represents a direct bond or a straight- or branched C_{1-6} alkylene chain optionally substituted by alkoxy, aryl, carboxy, cyano, cycloalkyl, halogen, heteroaryl, hydroxyl, or oxo, and R^{14} is hydrogen, aryl, carboxy, cyano, cycloalkyl, cycloalkenyl, 10 cyclocarbamoyl, cycloimidyl, heterocycloalkyl, heteroaryl, $-\text{NH}-\text{C}(=\text{O})-\text{NH}_2$, (N-carbamoyl)cyclic amine, $-\text{C}=\text{N}-\text{O}-\text{C}(=\text{O})-\text{NH}_2$, $-\text{C}(=\text{O})-\text{N}\text{Y}^1\text{Y}^2$ [where Y^1 and Y^2 are independently hydrogen, alkyl, arylalkyl, and aryl, or the substituent $\text{Y}^1\text{Y}^2\text{N}-$ forms a 4-6 membered cyclic amine which optionally contains an additional heteroatom selected from O, S, NH or NR^{13}], $-\text{N}\text{Y}^1\text{SO}_2\text{aryl}$, $-\text{NHR}^{13}$, $-\text{SR}^{13}$ or $-\text{OR}^{13}$; or a group L^2-R^{15} where L^2 represents a straight- or branched-carbon chain comprising from 2 15 to about 6 carbon atoms, optionally substituted with carboxy or cyano, which contains a double or triple carbon-carbon bond, or is interrupted by an oxygen or sulfur atom, a phenylene, imino (-NH-) or alkylimino linkage, or a sulfinyl or sulfonyl group, and R^{15} is hydrogen, aryl, carboxy, cyano, cycloalkyl, cycloalkenyl, heterocycloalkyl or heteroaryl; or R^9 and R^{10} taken together with the atom to which they are attached form a ring; or R^9 and R^{11} taken together with the atoms through which they are attached 20 form a ring;

R^{10} and R^{12} are independently hydrogen or alkyl; or R^{10} and R^{12} together form a bond;

R^{11} represents a group $-\text{L}^3-\text{R}^{16}$ where L^3 represents a direct bond or a straight- or branched C_{1-6} alkylene chain optionally substituted by alkoxy, aryl, carboxy, cyano, cycloalkyl, halogen, heteroaryl, hydroxyl, or oxo; or L^3 represents a straight- or branched-carbon chain comprising from 2 to 25 about 6 carbon atoms which contains a double or triple carbon-carbon bond, or is interrupted by an oxygen or sulfur atom, a phenylene, imino (-NH-) or alkylimino linkage, or a sulfinyl or sulfonyl group; and R^{16} is hydrogen, aryl, cycloalkyl, cycloalkenyl, cyclocarbamoyl, cycloimidyl, heterocycloalkyl, heteroaryl, $-\text{NH}-\text{C}(=\text{O})-\text{NH}_2$, (N-carbamoyl)cyclic amine, $-\text{C}=\text{N}-\text{O}-\text{C}(=\text{O})-\text{NH}_2$, $-\text{C}(=\text{O})-\text{N}\text{Y}^1\text{Y}^2$ [where Y^1 and Y^2 are independently hydrogen, alkyl, arylalkyl, and aryl, or the substituent $\text{Y}^1\text{Y}^2\text{N}-$ forms a 4-6 membered cyclic amine which optionally contains an additional heteroatom selected from O, S, NH or NR^{13}], $-\text{N}\text{Y}^1\text{SO}_2\text{aryl}$, or R^{11} and R^9 together with the atoms to which they are attached form a ring; or R^{11} and R^{12} together with the atom to which they are attached form a ring;

Ar is a group chosen from:



where R^{17} is a straight- or branched-chain alkyl group of 1 to about 6 carbon atoms, optionally substituted by one or more halogen atoms, or when Z^3 is a direct bond R^{17} may also represent a hydrogen atom, alkenyl or alkynyl group;

R^{18} represents an optionally substituted cycloalkyl, cycloalkenyl, heterocycloalkyl, aryl, partially saturated bicycloaryl or heteroaryl group;

R^{19} represents R^{20} , $-OR^{20}$, $-SR^{20}$, $-SOR^{20}$, $-SO_2R^{20}$, $-SO_2NR^{20}R^{21}$, $-NR^{20}SO_2R^{21}$, $-NR^{20}R^{21}$, $-O(C=O)NR^{20}R^{21}$, $-NR^{20}C(=O)R^{21}$, $-N(OH)C(=O)R^{20}$, or $-C(=O)N(OH)R^{21}$, where R^{20} and R^{21} , which may be the same or different, each represent a hydrogen atom, or an alkyl, alkenyl, heterocycloalkyl, cycloalkyl, cycloalkenyl, aryl, heteroaryl, arylalkyl or heteroarylalkyl group, or the group $NR^{20}R^{21}$ represents a 5 to 7 membered cyclic amine optionally containing one or more additional heteroatom selected from O, N, or S), wherein where R^{18} represents a substituted cycloalkyl group, the cycloalkyl group is substituted by one or more (e.g. 1, 2 or 3) substituents chosen from OR^{23} , SR^{24} , SOR^{24} , SO_2R^{24} , NH_2 , $NR^{13}R^{24}$, $=NOR^{24}$, $=NOH$, $=NNHR^{24}$, $=NO\bar{C}ONHR^{24}$, $=NCO_2R^{24}$, SOR^{24} , $NHCOR^{24}$, $NHSO_2R^{24}$, $SO_2NR^{13}R^{24}$, R^{23} , $CONHR^{24}$, $CONHCH_2CO_2R^{13}$, $CONR^{24}R^{13}$, or N_3 ; wherein R^{23} is hydrogen, alkyl, cycloalkyl, aryl, arylalkyl, heteroaryl or heteroarylalkyl; R^{24} is alkyl, cycloalkyl, cycloalkenyl, heterocycloalkyl, aryl, arylalkyl, heteroaryl or heteroarylalkyl; or the substituent $NR^{13}R^{24}$ forms a 4-7 membered cyclic amine which optionally contains an additional heteroatom selected from O, S, NH or NR^{13} , and wherein R^{18} represents a substituted heterocycloalkyl group containing a nitrogen atom the ring is substituted on one or more (e.g. 1, 2 or 3) of the ring carbon atoms and the substituents are chosen from oxo, cyano, CO_2R^{13} , $CONHCH_2CO_2R^{13}$, aryl, arylalkyl, alkyl or hydroxyalkyl, and/or is substituted on the ring nitrogen atom and the substituent is chosen from R^{13} , $(CH_2)_nCO_2H$, $(CH_2)_nCO_2R^{24}$, $(CH_2)_nCONR^{13}R^{24}$, $(CH_2)_nCOR^{24}$, $CONH_2$, $CONHR^{24}$, COR^{24} , SO_2R^{24} , or OR^{24} ;

A^3 represents a direct bond, a straight- or branched C_{1-6} alkylene chain optionally substituted by halogen, hydroxyl, alkoxy, oxo, cycloalkyl, aryl or heteroaryl; or A^3 represents a straight- or branched-carbon chain comprising from 2 to about 6 carbon atoms which contains a double or triple carbon-carbon

bond, or is interrupted by an oxygen or sulfur atom, a phenylene, imino (-NH-) or alkylimino linkage, or a sulfinyl or sulfonyl group,

5 Z^1 and Z^3 each represents an oxygen or sulfur atom, a direct bond or NH;

Z^2 represents an oxygen or sulfur atom, or a direct bond;

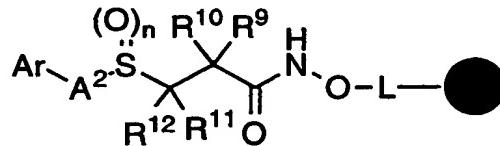
10 B, C, D , and E independently represent a carbon or heteroatom selected from O, S, N, NOR²² or NR²² where R²² is hydrogen or a C₁₋₄ straight- or branched-chain alkyl, aryl, arylC₁₋₄alkyl, heteroaryl or heteroarylC₁₋₄alkyl group, or three of B, C, D or E represent a carbon or heteroatom selected from O, N, NR²², or S and the other represents a direct bond; but excluding compounds where two O or S atoms are in adjacent positions, and the bonds joining B, C, D and E may be single or double bonds;

15 Q^1, Q^2 and Q^3 , which may be the same or different, each represents a CH or CX¹ linkage or a nitrogen atom; and X¹ represents a halogen atom; and

n is 0, 1 or 2; or

20 an N-oxide thereof, prodrug thereof, acid isostere thereof, pharmaceutically acceptable salt thereof, or solvate thereof,

comprising treating a polymeric hydroxamic acid resin compound of formula

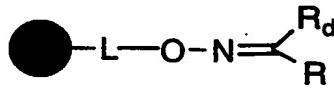


25

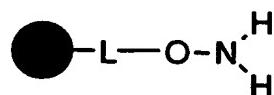
with acid.

In another aspect, this invention is directed to a process for the preparation of a polymeric oxime ether resin compound of formula

30

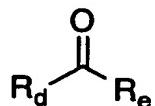


wherein and L are as defined herein is and R_d and R_e are independently H, aliphatic or aromatic, comprising reacting a polymeric hydroxylamine resin compound of formula

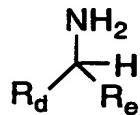


5

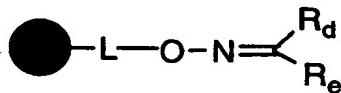
with a carbonyl compound of formula



10 In another aspect, this invention is directed to a process for the preparation of an α -amine compound of formula

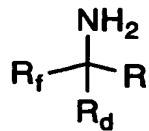


15 wherein R_d and R_e are independently H, aliphatic or aryl, provided that R_d and R_e are not both H, comprising reductively cleaving a polymeric oxime ether resin compound of formula



20 wherein and L are as defined herein.

In another aspect, this invention is directed to a process for the preparation of a substituted α -amine compound of formula

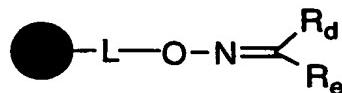


25

wherein R_d and R_e are independently H, aliphatic or aromatic, provided that R_d and R_e are not both H, and R_f is aliphatic or aromatic, comprising

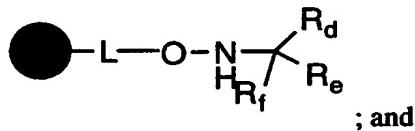
- (a) reacting a polymeric oxime ether compound of formula

5



wherein L and L are as defined herein, with an organometallic reagent of formula R_fM wherein R_f is an aliphatic or aromatic anion and M is a metal cation, to form a polymeric α -substituted hydroxylamine resin compound of formula

10

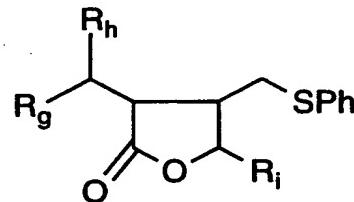


; and

- (b) reductively cleaving the α -substituted hydroxylamine resin compound.

15

In another aspect, this invention is directed to a process for the preparation of a lactone compound of formula

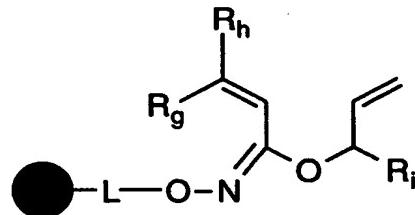


20

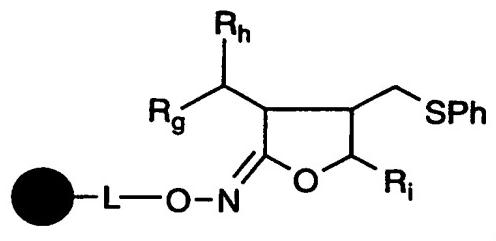
wherein R_g , R_h and R_i are aliphatic or aromatic and Ph is phenyl, comprising

- (a) treating an α,β -unsaturated polymeric hydroxamic acid ester resin compound of formula

25



wherein \bullet and L are as defined herein, with thiophenol and a radical initiator to form a polymeric oximyl lactone compound of formula

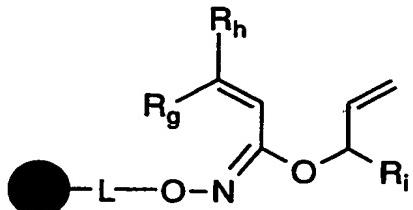


5

; and

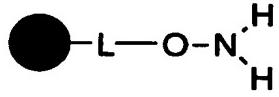
- (b) treating the polymeric oximyl lactone compound with aqueous acid.

In another aspect, this invention is directed to a process for the preparation of an α,β -unsaturated polymeric hydroxamic acid ester resin compound of formula



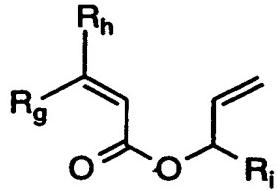
wherein \bullet , L and R_g and R_h and R_i are as defined herein, comprising reacting a polymeric hydroxylamine resin compound of formula

15

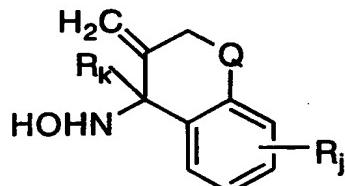


with an α,β -unsaturated carboxylic acid ester compound of formula

20



In another aspect, this invention is directed to a process for the preparation of an α -cyclic hydroxylamine compound of formula

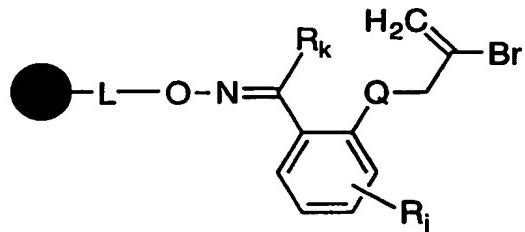


5

wherein R_j and R_k are aliphatic or aromatic and Q is -O- or -CH₂-, comprising

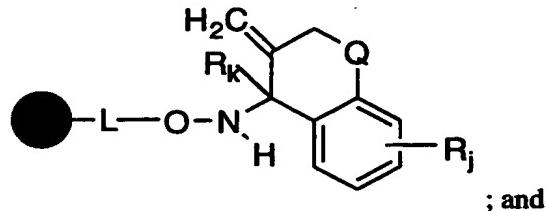
- (a) treating a polymeric acetophenone oxime compound of formula

10



wherein and L are as defined herein, with trialkyltin hydride and a radical initiator to form a polymeric α -cyclic hydroxylamine resin compound of formula

15



; and

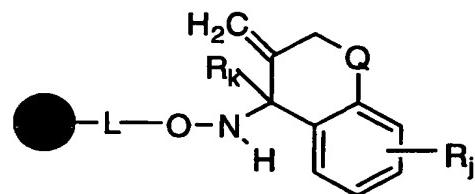
- (b) treating the polymeric α -cyclic hydroxylamine resin compound with aqueous acid.

20 In another aspect, this invention is directed to a process for the preparation of a α -cyclic amino compound of formula



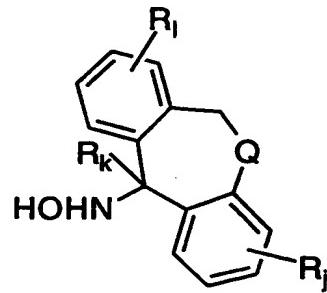
wherein R_j and R_k are aliphatic or aromatic and Q is $-O-$ or $-CH_2-$, comprising
reductively cleaving a polymeric α -cyclic hydroxylamine resin compound of formula

5



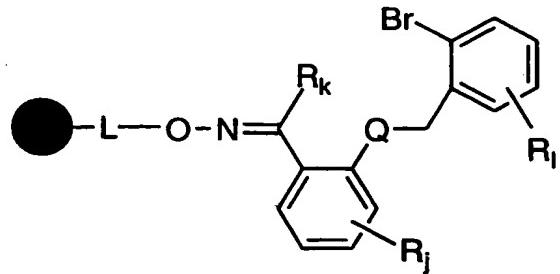
wherein \bullet and L are as defined herein.

10 In another aspect, this invention is directed to a process for the preparation of a α -cyclic hydroxylamine compound of formula



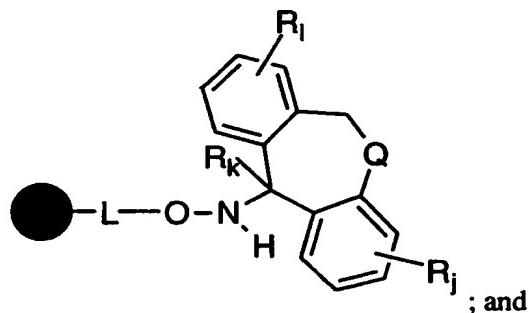
15 wherein R_j , R_k and R_i are aliphatic or aromatic and Q is $-O-$ or $-CH_2-$, comprising

(a) treating a polymeric acetophenone oxime compound of formula



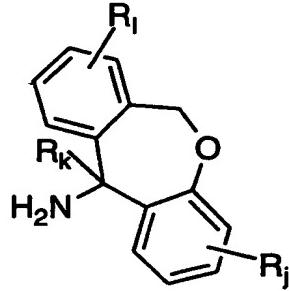
wherein \bullet and L are as defined herein, with trialkyltin hydride and a radical initiator to form a polymeric α -cyclic hydroxylamine resin compound of formula

5



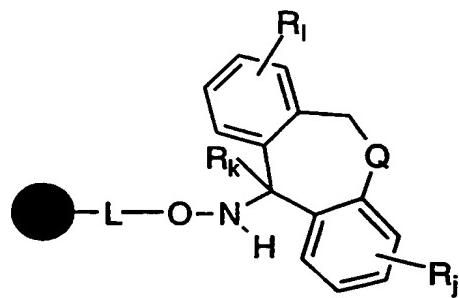
(b) treating the polymeric α -cyclic hydroxylamine resin compound with aqueous acid.

10 In another aspect, this invention is directed to a process for the preparation of a α -cyclic amino compound of formula



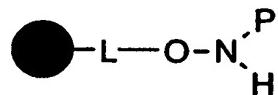
15

wherein R_j, R_k and R_l are aliphatic or aromatic and Q is -O- or -CH₂-, comprising reductively cleaving a polymeric α -cyclic hydroxylamine resin compound of formula



wherein [REDACTED] and L are as defined herein.

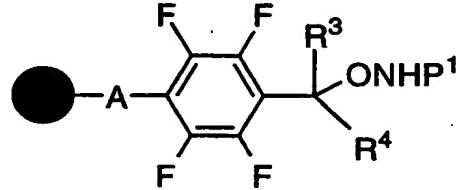
5 In another aspect, this invention is directed to a N-protected hydroxylamine resin compound of formula



10 wherein [REDACTED]

[REDACTED] and L are as defined herein and P is an amine protecting group, provided that P is other than 4-methoxybenzyl or 2,4-dimethoxybenzyl.

15 In another aspect, this invention is directed to a polymeric tetrafluorophenyl hydroxylamine resin compound of formula



wherein [REDACTED], A, R^3 and R^4 are as defined herein and P^1 is an amine protecting group.

20

DETAILED DESCRIPTION OF THE INVENTION

Definitions of Terms

As used above, and throughout the description of the invention, the following terms, unless otherwise indicated, shall be understood to have the following meanings.

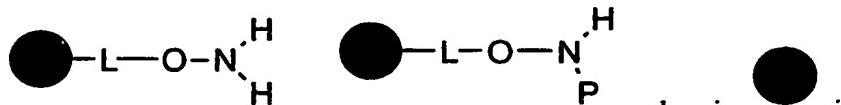
"Solid support" means a substrate which is inert to the reagents and reaction conditions described

- 5 herein, as well as being substantially insoluble in the media used. Representative solid supports include inorganic substrates such as kieselguhr, silica gel, and controlled pore glass; organic polymers including polystyrene, including 1-2% copolystyrene divinyl benzene (gel form) and 20-40% copolystyrene divinyl benzene (macro porous form), polypropylene, polyethylene glycol, polyacrylamide, cellulose, and the like; and composite inorganic/polymeric compositions such as polyacrylamide supported within a matrix 10 of kieselguhr particles. See J.M. Stewart and J.D. Young, *Solid Phase Peptide Synthesis*, 2nd. Ed., Pierce Chemical Co. (Chicago, IL, 1984).

In addition, "solid support" includes a solid support as described above which is affixed to a second inert support such as the pins described in Technical Manual, Multipin™ SPOC, Chiron Technologies (1995) and references therein which comprise a detachable polyethylene- or polypropylene-based head grafted with an amino functionalized methacrylate copolymer and an inert stem.

15 In addition, "solid support" includes polymeric supports such as the polyethylene glycol supports described by Janda et al., *Proc. Natl. Acad. Sci. USA*, 92, 6419-6423 (1995) and S. Brenner, WO 95/16918, which are soluble in many solvents but can be precipitated by the addition of a precipitating solvent.

20 "Polymeric hydroxylamine resin compound" means a solid support as defined above which is chemically modified as is known in the art to incorporate a plurality of hydroxylamine (-ONH₂) or protected hydroxylamine (-ONHP) groups. The hydroxylamine or protected hydroxylamine groups are covalently bound directly to the solid support or attached to the solid support by covalent bonds through a linking group. The polymeric hydroxylamine resin compounds according to the process aspect of this



- 25 invention are designated herein as a solid support as defined herein, L is absent or a linking group and P is an amine protecting group.

"Linking group" and "linker" mean a group through which the amino or aminomethyl functionality may be covalently linked to the solid support. The linking group is generally inert to the reagents and reaction conditions described herein.

30 "Amine protecting group" means an easily removable group which is known in the art to protect an amino group against undesirable reaction during synthetic procedures and to be selectively removable. The use of amine protecting groups is well known in the art for protecting against undesirable reactions during a synthetic procedure and many such protecting groups are known, cf, for example, T.H. Greene and P.G.M. Wuts, *Protective Groups in Organic Synthesis*, 2nd edition, John Wiley & Sons, New York 35 (1991), incorporated herein by reference. Representative amine protecting groups include formyl, acetyl, chloroacetyl, trichloroacetyl, o-nitrophenylacetyl, o-nitrophenoxyacetyl, trifluoroacetyl, acetoacetyl, 4-chlorobutyryl, isobutyryl, o-nitrocinnamoyl, picolinoyl, acylisothiocyanate, aminocaproyl, benzoyl, methoxycarbonyl, 9-fluorenylmethoxycarbonyl (Fmoc), 2,2,2-trifluoroethoxycarbonyl, 2-trimethylsilylethoxycarbonyl (Teoc), vinyloxycarbonyl, allyloxycarbonyl, t-butyloxycarbonyl (BOC),

1,1-dimethylpropynloxy carbonyl, benzyloxycarbonyl (Cbz), p-nitrobenzyloxycarbonyl, 2,4-dichlorobenzyloxycarbonyl, allyloxycarbonyl (Aloc), 2-(p-biphenyl)isopropylloxycarbonyl (Bpoc), adamantlyloxycarbonyl (Adoc), 2-(3,5-dimethoxyphenyl)-propyl-2-oxycarbonyl (Ddz), t-butyl (t-Bu), p-methoxybenzyloxycarbonyl (Moz), p-nitrobenzyloxycarbonyl (4-NO₂-Z), 2-(phenylsulfonyl)ethoxycarbonyl, 2,4-dimethoxybenzyloxycarbonyl, o-nitrobenzyloxycarbonyl, 1-(2-oxo-1,2-diphenylethyl)methyloxycarbonyl, (1,3-dithione-2-yl)methoxycarbonyl (Dmoc), pyridylethyl (Pyoc), 4-nitrophenylallyloxycarbonyl (Noc), 2-nitro-4,5-dimethoxybenzyloxycarbonyl, dimethyl-t-butyl silyl, o-nitrobenzylsulfonyl (o-Nbs), p-nitrobenzylsulfonyl (p-Nbs), 2-nitro-4-trifluoromethylbenzenesulfonyl, and the like.

10 "Natural amino acid" means a carboxylic acid compound having an amino group α to the carboxylate group, i.e., a compound of formula H₂N-CHR-CO₂H wherein R is aliphatic or aromatic as defined herein. Preferred amino acids have L stereochemistry at the α -carbon. The most preferred natural amino acids are the so-called natural α amino acids, ie alanine, valine, leucine, isoleucine, proline, phenylalanine, tryptophan, methionine, glycine, serine, threonine, cysteine, tyrosine, asparagine, 15 glutamine, aspartic acid, glutamic acid, lysine, arginine and histidine.

"Peptide" and "polypeptide" mean a polymer in which the monomers are natural or unnatural amino acid residues joined together through amide bonds. The term "peptide backbone" means the series of amide bonds through which the amino acid residues are joined. The term "amino acid residue" means the individual amino acid units incorporated into the peptides or polypeptides.

20 "Unnatural amino acid" means a carboxylic acid compound having an amino group therein in a position other than α to the carboxylate group. Representative unnatural amino acids include β -alanine and γ -aminobutyric acid.

"Aliphatic" means a compound or radical which does not contain an aromatic ring. Representative aliphatic groups include alkyl, alkenyl, alkynyl, cycloalkyl, cycloalkenyl, and the like.

25 "Aromatic" means a compound or radical which contains at least one aromatic ring. The term "Aromatic ring" includes both aryl and heteroaryl rings as defined herein. Representative aromatic groups include aryl, arylalkenyl, arylalkyl, arylalkynyl, benzyl, heteroaryl, heteroarylalkenyl, heteroarylalkyl, heteroarylalkynyl, and the like.

"Acid bioisostere" means a group which has chemical and physical similarities producing broadly similar biological properties (see Lipinski, Annual Reports in Medicinal Chemistry, 1986,21,p283 "Bioisosterism In Drug Design"; Yun, Hwahak Sekye, 1993,33,p576-579 "Application Of Bioisosterism To New Drug Design"; Zhao, Huaxue Tongbao, 1995,p34-38 "Bioisosteric Replacement And Development Of Lead Compounds In Drug Design"; Graham, Theochem, 1995,343,p105-109 "Theoretical Studies Applied To Drug Design:ab initio Electronic Distributions In Bioisosteres").

35 Examples of suitable acid bioisosteres include: -C(=O)-NH-OH, -C(=O)-CH₂OH, -C(=O)-CH₂SH, -C(=O)-NH-CN, sulfo, phosphono, alkylsulfonylcarbamoyl, tetrazolyl, arylsulfonylcarbamoyl, heteroarylsulfonylcarbamoyl, N-methoxycarbamoyl, 3-hydroxy-3-cyclobutene-1,2-dione, 3,5-dioxo-1,2,4-oxadiazolidinyl or heterocyclic phenols such as 3-hydroxyisoxazolyl and 3-hydroxy-1-methylpyrazolyl.

"Acyl" means an H-CO- or alkyl-CO- group in which the alkyl group is as defined herein. Preferred acyls contain a lower alkyl. Exemplary acyl groups include formyl, acetyl, propanoyl, 2-methylpropanoyl, butanoyl and palmitoyl.

"Acylamino" is an acyl-NH- group wherein acyl is as defined herein.

5 "Alkenyl" means an aliphatic hydrocarbon group containing a carbon-carbon double bond and which may be straight or branched having about 2 to about 15 carbon atoms in the chain. Preferred alkenyl groups have 2 to about 12 carbon atoms in the chain; and more preferably about 2 to about 4 carbon atoms in the chain. Branched means that one or more lower alkyl groups such as methyl, ethyl or propyl are attached to a linear alkenyl chain. "Lower alkenyl" means about 2 to about 4 carbon atoms in
10 the chain which may be straight or branched. The alkenyl group may be substituted by one or more halo or cycloalkyl. Exemplary alkenyl groups include ethenyl, propenyl, *n*-butenyl, *i*-butenyl, 3-methylbut-2-enyl, *n*-pentenyl, heptenyl, octenyl, cyclohexylbutenyl and decenyl.

"Alkoxy" means an alkyl-O- group in which the alkyl group is as defined herein. Exemplary alkoxy groups include methoxy, ethoxy, *n*-propoxy, *i*-propoxy, *n*-butoxy and heptoxy.

15 "Alkoxyalkyl" means an alkyl-O-alkyl- group in which the alkyl groups are independently as defined herein. Exemplary alkoxy groups include methoxyethyl, ethoxymethyl, *n*-butoxymethyl and cyclopentylmethoxyethyl.

"Alkoxy carbonyl" means an alkyl-O-CO- group in which the alkyl group is as defined herein. Exemplary alkoxy carbonyl groups include methoxy- and ethoxycarbonyl.

20 "Alkyl" means an aliphatic hydrocarbon group which may be straight or branched having about 1 to about 15 carbon atoms in the chain. Preferred alkyl groups have 1 to about 12 carbon atoms in the chain. Branched means that one or more lower alkyl groups such as methyl, ethyl or propyl are attached to a linear alkyl chain. "Lower alkyl" means about 1 to about 4 carbon atoms in the chain which may be straight or branched. The alkyl group may be substituted by one or more halo, cycloalkyl or
25 cycloalkenyl. Exemplary alkyl groups include methyl, fluoromethyl, difluoromethyl, trifluoromethyl, cyclopropylmethyl, cyclopentylmethyl, ethyl, *n*-propyl, *i*-propyl, *n*-butyl, *t*-butyl, *n*-pentyl, 3-pentyl, heptyl, octyl, nonyl, decyl and dodecyl. Preferred alkyl groups for R⁹ include methyl, fluoromethyl, difluoromethyl, trifluoromethyl, and ethyl.

"Alkylsulfinyl" means an alkyl-SO- group in which the alkyl group is as defined above.

30 Preferred groups are those in which the alkyl group is lower alkyl.

"Alkylsulfonyl" means an alkyl-SO₂- group in which the alkyl group is as defined above.

Preferred groups are those in which the alkyl group is lower alkyl.

"Alkylthio" means an alkyl-S- group in which the alkyl group is as previously described.

Exemplary alkylthio groups include methylthio, ethylthio, *i*-propylthio and heptylthio.

35 "Alkynyl" means an aliphatic hydrocarbon group containing a carbon-carbon triple bond and which may be straight or branched having about 2 to about 15 carbon atoms in the chain. Preferred alkynyl groups have 2 to about 12 carbon atoms in the chain; and more preferably about 2 to about 4 carbon atoms in the chain. Branched means that one or more lower alkyl groups such as methyl, ethyl or propyl are attached to a linear alkenyl chain. Exemplary alkynyl groups include ethynyl, propynyl, *n*-butynyl, *i*-butynyl, 3-methylbut-2-ynyl, and *n*-pentynyl.

40

"Aroyl" means an aryl-CO- group in which the aryl group is as defined herein. Exemplary groups include benzoyl and 1- and 2-naphthoyl.

"Aroylamino" is an aroyl-NH- group wherein aroyl is as defined herein.

"Aryl" as a group or part of a group denotes an optionally substituted monocyclic or multicyclic

- 5 aromatic carbocyclic moiety of about 6 to about 10 carbon atoms. Exemplary aryl include phenyl or naphthyl, or phenyl or naphthyl substituted with one or more aryl group substituents which may be the same or different, where "aryl group substituent" includes acyl, acylamino, alkoxy, alkoxycarbonyl, alkyl, alkylsulfinyl, alkylsulfonyl, alkylthio, aroyl, aroylamino, aryl, arylalkoxy, arylalkoxycarbonyl, arylalkyl, arylalkylthio, aryloxy, aryloxycarbonyl, arylsulfinyl, arylsulfonyl, arylthio, carboxy, cyano, halo,
- 10 heteroaroyl, heteroaryl, heteroarylalkyl, heteroarylarnino, heteroaryloxy, hydrogen, hydroxy, hydroxyalkyl, nitro, Y^1Y^2N -, Y^1Y^2NCO - or $Y^1Y^2NSO_2$ -, where Y^1 and Y^2 are independently hydrogen, alkyl, arylalkyl, and aryl, or Y^1 and Y^2 taken together with the N atom through which Y^1 and Y^2 are linked form a 4-7 membered heterocyclic which optionally contains an additional heteroatom selected from O, S, NH or NR¹³. Preferred aryl group substituents include acyl, acylamino,
- 15 alkoxycarbonyl, alkyl, alkylthio, aroyl, cyano, halo, hydrogen, hydroxy, nitro, Y^1Y^2N -, Y^1Y^2NCO - or $Y^1Y^2NSO_2$ -, where Y^1 and Y^2 are independently hydrogen and alkyl.

"Arylalkenyl" means an aryl-alkenyl- group in which the aryl and alkenyl are as previously described. Preferred arylalkenyls contain a lower alkenyl moiety. Exemplary arylalkenyl groups include styryl and phenylallyl.

- 20 "Arylalkyl" means an aryl-alkyl- group in which the aryl and alkyl are as previously described. Preferred arylalkyls contain a lower alkyl moiety. Exemplary arylalkyl groups include benzyl, 2-phenethyl and naphthlenemethyl.

"Arylalkyloxy" means an arylalkyl-O- group in which the arylalkyl group is as previously described. Exemplary arylalkyloxy groups include benzyloxy and 1- or 2-naphthalenemethoxy.

- 25 "Arylalkyloxyalkenyl" means an arylalkyl-O-alkenyl group in which the arylalkyl and alkenyl groups are as previously described. An exemplary arylalkyloxyalkenyl group is 3-benzyloxyallyl.

"Arylalkyloxyalkyl" means an arylalkyl-O-alkyl group in which the arylalkyl and alkyl groups are as previously described. An exemplary arylalkyloxyalkyl group is benzyloxyethyl.

- 30 "Arylalkoxycarbonyl" means an arylalkyl-O-CO- group. An exemplary arylalkoxycarbonyl group is benzyloxycarbonyl.

"Arylalkylthio" means an arylalkyl-S- group in which the arylalkyl group is as previously described. An exemplary arylalkylthio group is benzylthio.

- 35 "Arylalkynyl" means an aryl-alkynyl- group in which the aryl and alkynyl are as previously described. Preferred arylalkynyls contain a lower alkynyl moiety. An exemplary arylalkynyl group is phenylacetylenyl.

"Aryloxy" means an aryl-O- group in which the aryl group is as previously described. Exemplary aryloxy groups include phenoxy and naphthoxy.

- "Aryloxyalkenyl" means an aryl-O-alkenyl- group in which the aryl or alkenyl groups are as previously described. An exemplary aryloxyalkenyl group is phenoxyallyl.

"Aryloxyalkyl" means an aryl-O-alkyl- group in which the aryl or alkyl groups are as previously described. An exemplary aryloxyalkyl groups is phenoxypropyl.

"Aryloxycarbonyl" means an aryl-O-CO- group in which the aryl group is as previously described. Exemplary aryloxycarbonyl groups include phenoxy- and naphthoxycarbonyl.

5 "Arylsulfinyl" means an aryl-SO- group in which the aryl group is as previously described.

"Arylsulfonyl" means an aryl-SO₂- group in which the aryl group is as previously described.

"Arylthio" means an aryl-S- group in which the aryl group is as previously described. Exemplary arylthio groups include phenylthio and naphthylthio.

10 "(N-carbamoyl)cyclic amine" means a 5 to 7 membered cycloalkyl ring system where one of the ring carbon atoms is replaced by the group N-C(=O)-NH₂. An exemplary (N-carbamoyl)cyclic amine is N-carbamoylpiperidinyl.

"Benzyl" means a Phenyl-CH₂- group in which the phenyl ring is unsubstituted or substituted with one or more substituents independently selected from alkyl, alkoxy, halogen, and haloalkyl.

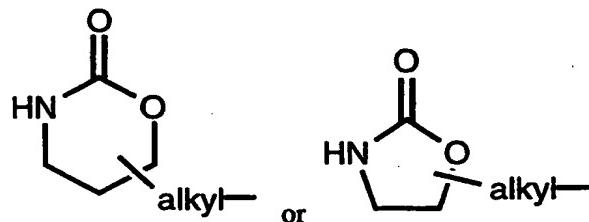
15 "Cycloalkenyl" means a non-aromatic monocyclic or multicyclic ring system containing a carbon-carbon double bond and having about 3 to about 10 carbon atoms. Preferred monocyclic cycloalkenyl rings include cyclopentenyl, cyclohexenyl or cycloheptenyl; more preferred is cyclopentenyl. A preferred multicyclic cycloalkenyl ring is norbornenyl. The cycloalkenyl group may be substituted by one or more halo, methylene (H₂C=) or alkyl.

20 "Cycloalkyl" means a non-aromatic mono- or multicyclic ring system of about 3 to about 10 carbon atoms. Exemplary monocyclic cycloalkyl rings include cyclopropyl, cyclopentyl, cyclohexyl and cycloheptyl. Preferred monocyclic cycloalkyl rings for R¹⁸ include cyclopentyl and cyclohexyl. A preferred monocyclic cycloalkyl rings for R¹⁹ is cyclopropyl. Exemplary multicyclic cycloalkyl rings include perhydronaphthyl, adamant-(1- or 2-)yl and norbornyl and spirobicyclic groups, e.g. spiro[4,4]non-2-yl. The cycloalkyl group may be substituted by one or more halo, methylene (H₂C=) or 25 alkyl groups. Preferred monocyclic cycloalkyl rings for R¹⁸ include cyclopentyl and cyclohexyl. Preferred cycloalkyl groups for R¹⁹ include cyclopropyl.

"Cycloalkyoxy" means an cycloalkyl-O- group in which the cycloalkyl group is as previously described. Exemplary cycloalkoxy groups include cyclopentyloxy and cyclohexyloxy.

"Cyclocarbamoylalkyl" means a compound of formula

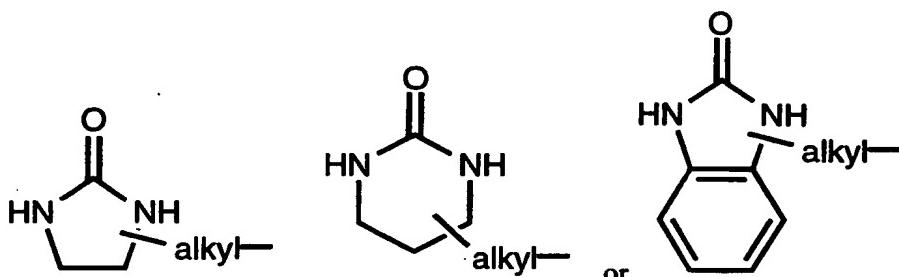
30



in which the cyclocarbamoyl group consists of the oxooazaheterocycl ring moiety, and the alkyl group is as previously described. The alkyl moiety may be attached to the carbamoyl through either a carbon atom or the nitrogen atom of the carbamoyl moiety. An exemplary cyclocarbamoylalkyl group is

N-oxazolidinylpropyl.

"Cycloimidyl" means a compound of formula



5

in which the imide group consists of the oxodiazaheterocycl ring moiety, and the alkyl group is as previously described. The alkyl moiety may be attached to the carbamoyl through either a carbon atom or nitrogen atom of the carbamoyl moiety. An exemplary imidealkyl group is N-phthalimidepropyl.

10 "Halo" and "halogen" mean fluoro, chloro, bromo, or iodo. Preferred are fluoro, chloro or bromo, and more preferred are fluoro or chloro.

"Haloalkyl" means an alkyl group as defined herein substituted with one or more halogen atoms. Representative haloalkyl groups include chloromethyl, bromoethyl, trifluoromethyl, and the like.

"Heteroaroyl" means a heteroaryl-CO- group in which the heteroaryl group is as defined herein. An exemplary heteroaroyl group is pyridylcarbonyl.

15 "Heteroaryl" as a group or part of a group denotes an optionally substituted aromatic monocyclic or multicyclic hydrocarbon ring system of about 5 to about 10 atoms in which one or more of the ring members is/are element(s) other than carbon, for example nitrogen, oxygen or sulphur. The "heteroaryl" may also be substituted by one or more aryl group substituents. Examples of suitable optionally substituted heteroaryl groups include furyl, isoxazolyl, isoquinolinyl, isothiazolyl, 1,2,3-oxadiazole, 20 1,2,4-oxadiazole, 1,2,5-oxadiazole, 1,3,4-oxadiazole, pyrazinyl, pyridazinyl, pyridyl, pyrimidinyl, quinolinyl, 1,3,4-thiadiazolyl, thiazolyl, thienyl, and 1,2,3- and 1,2,4-triazolyl groups, optionally substituted by one or more aryl group substituents as defined above.

When R¹⁸ or R¹⁹ contains an optionally substituted heteroaryl group this may particularly represent an optionally substituted "azaheteroaryl" group (where the term "azaheteroaryl" means a heteroaryl group of about 5 to about 10 ring members in which one or more of the ring members is/are nitrogen). Optional substituents for the heteroaryl group within R¹⁸ or R¹⁹ include, for example, halogen atoms and alkyl, aryl, arylalkyl, hydroxy, oxo, hydroxyalkyl, haloalkyl (for example trifluoromethyl), alkoxy, haloalkoxy (for example trifluoromethoxy), aryloxy, and arylalkyloxy groups. Preferred heteroaryl groups within R¹⁸ include optionally substituted thienyl, thiazolyl, pyridyl, 1,2,4-oxadiazole or 1,3,4-oxadiazole. A 30 preferred heteroaryl groups within R¹⁹ is optionally substituted pyridyl.

"Heteroarylalkenyl" means an heteroaryl-alkenyl- group in which the heteroaryl and alkenyl are as previously described. Preferred heteroarylalkenyls contain a lower alkenyl moiety. An exemplary heteroarylalkenyl group is 4-pyridylvinyl.

"Heteroarylalkyl" means an heteroaryl-alkyl- group in which the heteroaryl and alkyl are as previously described. Preferred heteroarylalkyls contain a lower alkyl moiety. An exemplary heteroarylalkyl group is 4-pyridylmethyl.

5 "Heteroarylalkyloxy" means an heteroarylalkyl-O- group in which the heteroarylalkyl group is as previously described. An exemplary heteroarylalkyloxy group is 4-pyridylmethoxyloxy.

"Heteroarylalkyloxyalkenyl" means an heteroarylalkyl-O-alkenyl group in which the heteroarylalkyl and alkenyl groups are as previously described. An exemplary heteroarylalkyloxyalkenyl group is 4-pyridylmethoxyallyl.

10 "Heteroarylalkyloxyalkyl" means an heteroarylalkyl-O-alkyl group in which the heteroarylalkyl and alkyl groups are as previously described. An exemplary heteroarylalkyloxy group is 4-pyridylmethoxyethyl.

"Heteroarylalkynyl" means an heteroaryl-alkynyl- group in which the heteroaryl and alkynyl are as previously described. Preferred heteroarylalkynyls contain a lower alkynyl moiety. An exemplary heteroarylalkynyl group is 4-pyridylethynyl.

15 "Heterocyclyl" means an about 4 to about 10 member monocyclic or multicyclic ring system wherein one or more of the atoms in the ring system is an element other than carbon chosen amongst nitrogen, oxygen or sulfur. The heterocyclyl may be optionally substituted by one or more alkyl group substituents. Exemplary heterocyclyl moieties include quinuclidine, pentamethylenesulfide, tetrahydropyranyl, tetrahydrothiophenyl, pyrrolidinyl, piperidinyl or tetrahydrofuranyl.

20 "Heterocyclylalkyl" means an heterocyclyl-alkyl- group in which the heterocyclyl and alkyl are as previously described. Preferred heterocyclylalkyls contain a lower alkyl moiety. An exemplary heteroarylalkyl group is tetrahydropyranylmethyl.

25 "Heterocyclylalkyloxyalkyl" means an heterocyclyl-alkyl-O-alkyl- group in which the heterocyclyl and alkyls groups independently are as previously described. An exemplary heteroarylalkyl group is tetrahydropyranyl-methyloxymethyl.

"Hydroxyalkyl" means a HO-alkyl- group in which alkyl is as previously defined. Preferred hydroxyalkyls contain lower alkyl. Exemplary hydroxyalkyl groups include hydroxymethyl and 2-hydroxyethyl.

30 "Partially saturated bicycloaryl" means a group in which an aryl and a cycloalkyl group are fused together to form a bicyclic structure. Exemplary arylalkyl groups include indanyl and tetrahydronaphthyl, especially indanyl.

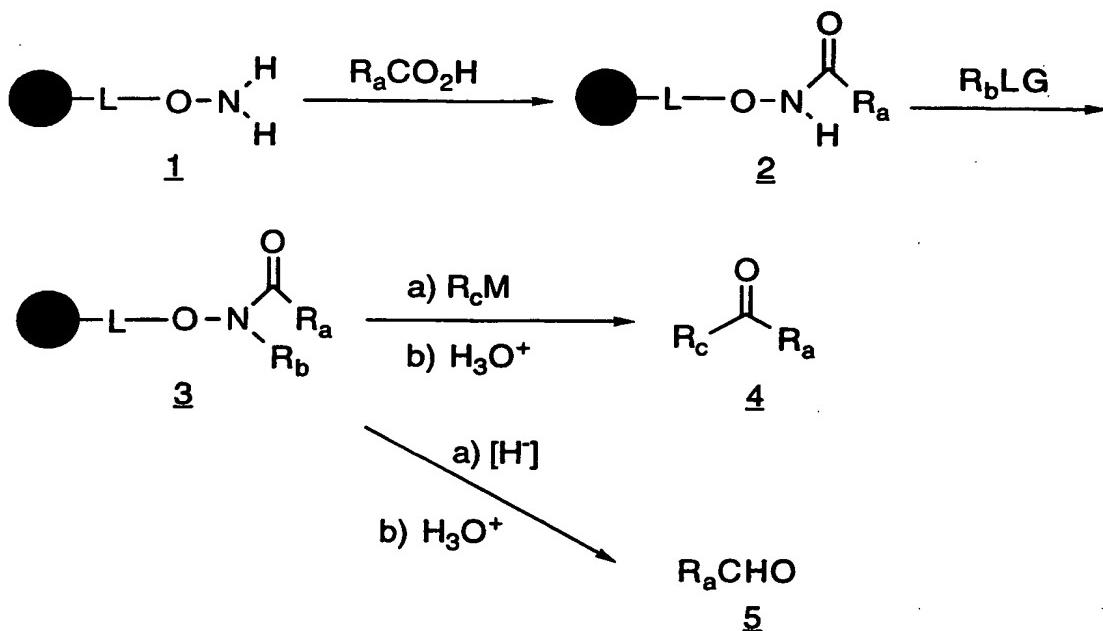
Preferred Embodiments

35 A process for the preparation of aldehydes and ketones according to this invention is outlined in Scheme 1 wherein R_a and R_b independently represent any aliphatic or aromatic group amenable to the solvents and reagents utilized in the processes described herein. The groups R_a and R_b may be further substituted and may contain functional groups suitable for further chemical transformations while attached to the hydroxylamine resin. It is understood that when these functional groups possess reactivity 40 such that they could potentially interfere with the reactions described below, such functional groups should be suitably protected. For a comprehensive treatise on the protection and deprotection of common

functional groups see T.H. Greene and P.G.M. Wuts, Protective Groups in Organic Synthesis, 2nd edition, John Wiley & Sons, New York (1991), incorporated herein by reference. R_c represents any aliphatic or aromatic group amenable for use as an organometallic reagent.

5

Scheme 1



According to the foregoing Scheme 1, a polymeric hydroxylamine resin compound 1 is coupled with a carboxylic acid derivative of formula R_aCO₂H to form the polymeric hydroxamic acid resin compound 2. The coupling reaction is accomplished in the presence of an activating agent as is known in the art of peptide synthesis. Representative activating agents include isopropyl chloroformate, diisopropylcarbodiimide (DIC), 1-(3-dimethylaminopropyl)-3-ethylcarbodiimide (EDC), 1-hydroxybenzotriazole (HOBT), bis(2-oxo-3-oxazolidinyl)-phosphonic chloride (BOP-Cl), benzotriazole-1-yloxy-tris((dimethylamino)phosphonium)hexafluorophosphate (BOP), benzotriazole-1-yloxy-tris-pyrrolidino-phosphonium hexafluorophosphate (PyBROP), bromo-tris-pyrrolidino-phosphonium hexafluorophosphate (PyBOP), 2-(1H-benzotriazole-1-yl)-1.1.3.3-tetramethyluronium tetrafluoroborate (TBTU), 2-(1H-benzotriazole-1-yl)-1.1.3.3-tetramethyluronium hexafluoroborate (HBTU), 2-[2-oxo-1-(2H)-pyridyl]-1.1.3.3-bis(pentamethyleneurenonium)tetrafluoroborate (TOPPipU), N,N'-dicyclohexylcarbodiimide (DCC), and the like. Suitable solvents for the coupling reaction include dichloromethane, DMF, DMSO, THF, and the like. Coupling times range from about 2 to about 24 hours, depending upon the resin and carboxylic acid derivative to be coupled, activating agent, solvent and temperature. The coupling is accomplished at from about -10 °C to about 50 °C, preferably at about ambient temperature.

The coupling reaction is preferably accomplished at ambient temperature in DMF using 1-(3-dimethylaminopropyl)-3-ethylcarbodiimide hydrochloride over about 12 hours.

The polymeric hydroxamic acid resin compound 2 is then alkylated with an alkylating agent of formula R_bLG, where LG is a leaving group, in the presence of a non-nucleophilic base such as 1,8-diazabicyclo[5.4.0]undec-7-ene (DBU) in an inert organic solvent such as toluene to form the N-alkylated polymeric hydroxamic acid resin compound 3. The alkylating agent RbLG may be added in an equimolar amount to an excess of to about 25 molar equivalents. About 15 molar equivalents is preferred. The non-nucleophilic base may be added in an equimolar amount to an excess of to about 10 molar equivalents. About 5 molar equivalents is preferred. The leaving group LG is any group amendable to nucleophilic displacement by the nitrogen atom of the polymeric hydroxamic acid resin compound 2 under the reaction conditions described above. A preferred leaving group is halogen. A sample of the the N-alkylated polymeric hydroxamic acid resin compound 3 may be subjected to acidolysis to cleave the substituted hydroxamic acid to confirm that the reaction proceeded satisfactorily.

Reaction of the polymeric N-alkylated hydroxamic acid resin compound 3 with an organometallic reagent of formula R_cM, wherein R_c is an aliphatic or aromatic anion and M is a metal cation, followed by acid hydrolysis provides the ketone 4. Preferred organometallic reagents are organolithium reagents of formula R_cLi and Grignard reagents of formula R_cMgX wherein X is halogen. In a preferred preparation of ketones according to this aspect of the invention, the polymeric N-alkylated hydroxamic acid resin compound 3 is treated with R_cMgX in diethyl ether at ambient temperature over about 18 hours, and the reaction mixture is then quenched by addition of aqueous HCl or aqueous KHSO₄ to liberate the ketone 4.

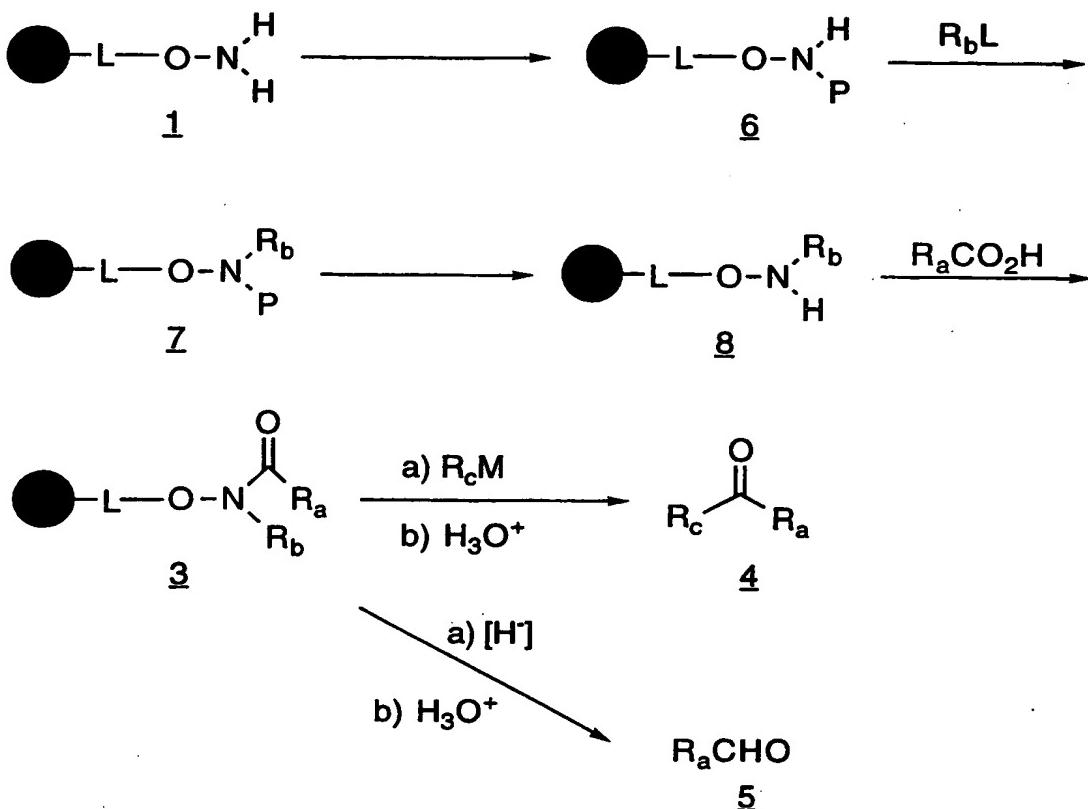
Aldehydes are prepared by treatment of the the polymeric N-alkylated hydroxamic acid resin compound 3 with a hydride reducing agent, followed by acid hydrolysis as shown in Scheme 1 above. Representative hydride reducing agents include LiAlH₄, (iso-Bu)₂AlH, LiAlH(O-t-Bu)₃, LiAlH₄-EtOH, LiAlH₄-MeOH, and the like. Preferred reducing agents are LiAlH₄ and LiAlH₄-MeOH. The acid hydrolysis is preferably accomplished aqueous KHSO₄.

As shown in Scheme 1, the N-alkylated polymeric hydroxamic acid resin compound 3 is a Weinreb-like amide useful for the synthesis of aldehydes and ketones (S. Nahm and S. Weinreb, *Tet Lett.* 1981, 22, 3815-3818). This N-alkylated polymeric hydroxamic acid resin compound has advantages over the previous examples of resin bound Weinreb-like amides (J.-A. Fehrentz, M. Paris, A. Heitz, J. Velek, C.-F. Liu, F. Winternitz, and J. Martinez. *Tet. Lett.*, 1995, 36, 7871-7874. b) T. Q. Dinh and R. W. Armstrong, *Tet. Lett.*, 1996, 37, 1161-1164) in that it can be N-alkylated with bulky lipophilic groups such as benzyl, substituted benzyl, naphthyl or any alkyl group necessary to optimize the reaction on the solid phase. The N-benzyl-O-methylpolystyrenyl moiety, for example, is well suited to form a stable metal chelated intermediate. The lipophilic benzyl group is believed to help shield the chelate adding to its stability.

A preferred process for the preparation of aldehydes and ketones is outlined in Scheme 2. In Scheme 2, "P" designates an amine protecting group as defined herein.

Scheme 2

5



As shown in Scheme 2 above, the polymeric hydroxylamine resin compound is protected with an amine protecting group to form the N-protected polymeric hydroxylamine resin compound 6. The N-protected polymeric hydroxylamine resin compound 6 is then alkylated as described in Scheme 1 above to form the N-alkylated N-protected polymeric hydroxylamine resin compound 7. Removal of the amine protecting group provides the mono N-alkylated polymeric hydroxylamine resin compound 8. Coupling of 8 with a carboxylic acid compound of formula R_aCO_2H as described above provides the polymeric N-alkylated hydroxamic acid resin compound 3, which is converted to ketone 4 or aldehyde 5 as described in Scheme 1 above.

Preferred amine protecting groups include allyloxycarbonyl (Aloc), benzyloxycarbonyl (Cbz), p-methoxybenzyloxycarbonyl (Moz), p-nitrobenzyloxycarbonyl (4-NO₂-Z), trimethylsilylethoxycarbonyl (Teoc), 2,4-dimethoxybenzyloxycarbonyl, o-nitrobenzyloxycarbonyl, o-nitrobenzylsulfonyl (o-Nbs), p-nitrobenzylsulfonyl (p-Nbs), and 2-nitro-4-trifluoromethylbenzenesulfonyl.

20

The most preferred amine protecting group is allyloxycarbonyl.

Preferred polymeric N-protected hydroxylamine resin compounds include

- N-allyloxycarbonyl-4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin,
- 5 N-allyloxycarbonyl-4-[4-(O-methylhydroxylamine)-3-methoxyphenoxy]-(N-4-methylbenzhydryl)-butyramide-copoly(styrene-1%-divinylbenzene)-resin,
- N-allyloxycarbonyl-4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-phenoxyethyl-copoly(styrene-1% divinylbenzene) resin,
- 10 N-allyloxycarbonyl-4-[4-(1-aminoxyethyl)-2-methoxy-5-nitrophenoxy]-(N-4-methylbenzhydryl)-butyramide-copoly(styrene-1% divinylbenzene) resin,
- N-allyloxycarbonyl-O-hydroxylamine-2'-chlorotrityl-copolystyrene-1%-divinylbenzene-resin,
- N-allyloxycarbonyl-O-hydroxylamine-trityl-copolystyrene-1%-divinylbenzene-resin,
- N-allyloxycarbonyl-5-(4-O-methylhydroxylamine -3,5-dimethoxyphenoxy)-valeric acid-copolystyrene-1%-divinyl benzene resin,
- N-allyloxycarbonyl-4-O-methylhydroxylamine-3-methoxyphenoxy-copolystyrene-1%-divinyl benzene resin,
- 15 N-allyloxycarbonyl-4-(O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-1% divinylbenzene) resin,
- N-allyloxycarbonyl-4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-1% divinylbenzene) resin and
- 20 N-allyloxycarbonyl-3-hydroxy-xanthidrolamine-copolystyrene-1%-divinylbenzene resin.

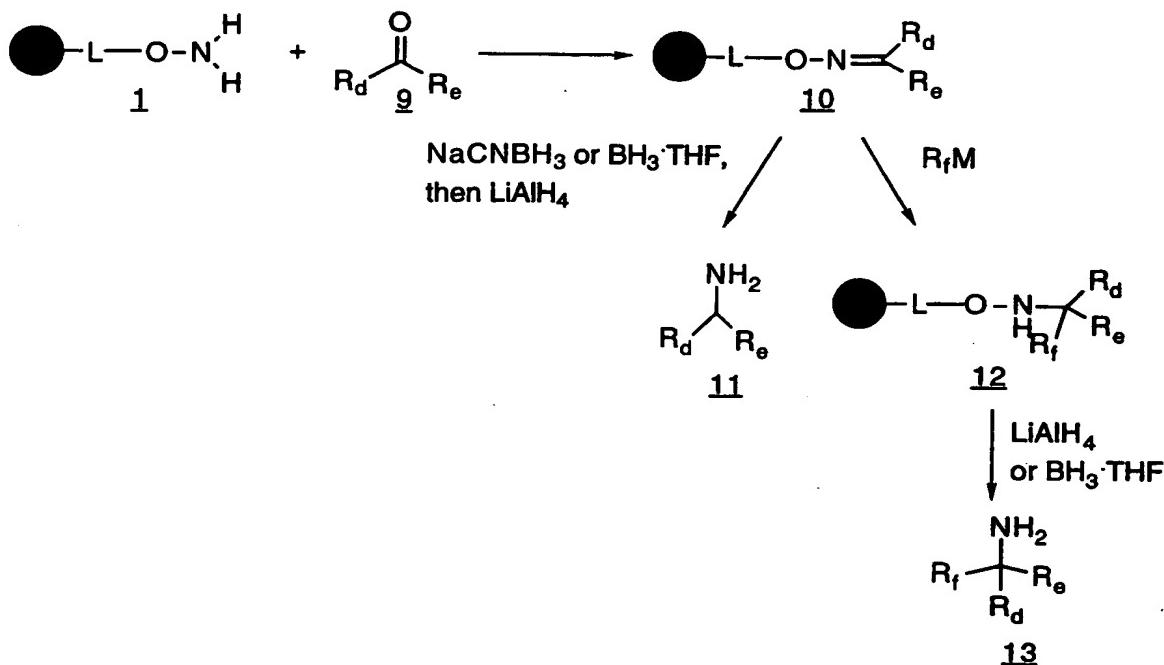
The most preferred polymeric N-protected hydroxylamine resin compound is

N-allyloxycarbonyl-4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin.

25 When the carboxylic acid compound R_aCO_2H represents a natural or unnatural amino acid or peptide, the procedures described in Schemes 1 and 2 above present a facile route to the heretofore difficult to obtain amino acid or peptide aldehyde compounds.

30 A process for the preparation of amines according to this invention is outlined in Scheme 3. In Scheme 3, R_a and R_c independently represent H or any aliphatic or aromatic group amenable to the solvents and reagents utilized in the processes described herein, provided that R_a and R_c are not both H. The groups R_a , R_b and R_c may be further substituted and may contain functional groups suitable for further chemical transformations while attached to the hydroxylamine resin. It is understood that when these 35 functional groups possess reactivity such that they could potentially interfere with the reactions described below, such functional groups should be suitably protected. For a comprehensive treatise on the protection and deprotection of common functional groups see T.H. Greene and P.G.M. Wuts, Protective Groups in Organic Synthesis, 2nd edition, John Wiley & Sons, New York (1991), incorporated herein by reference. R_f represents any aliphatic or aromatic group which is amenable for use as an organometallic 40 reagent.

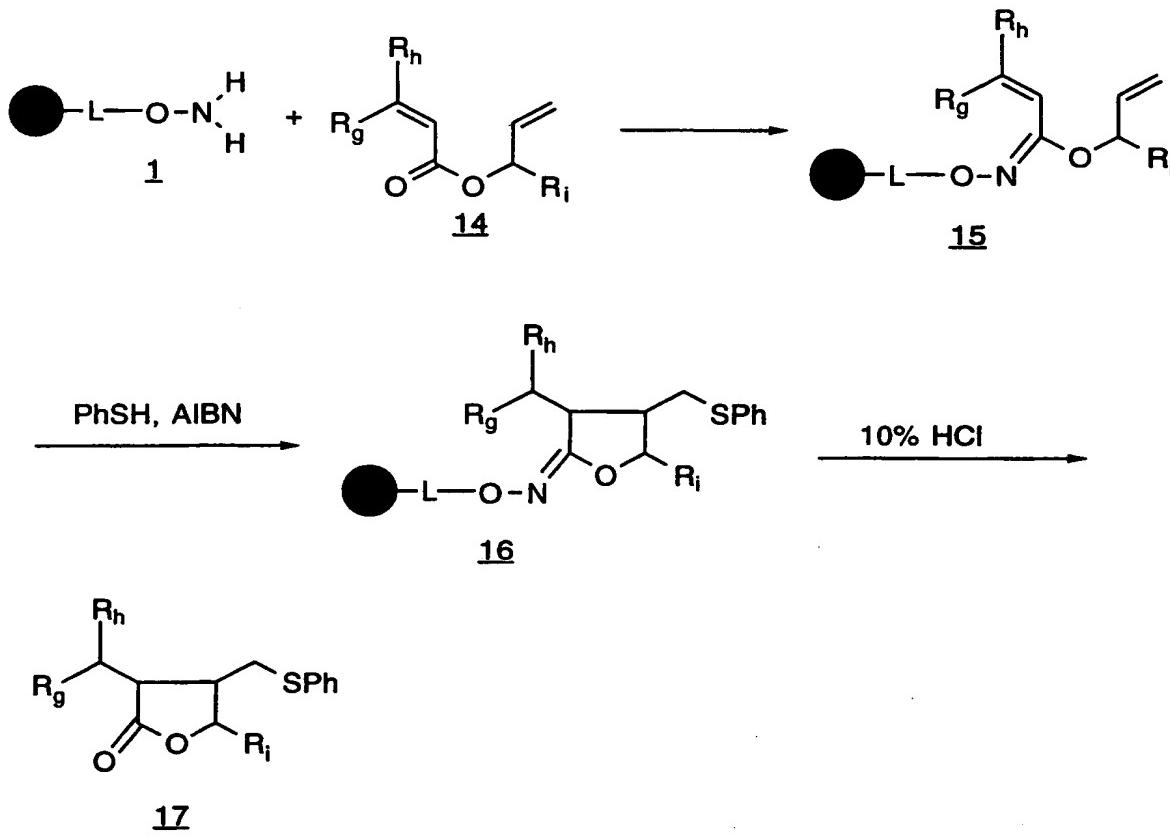
Scheme 3



5 According to the foregoing Scheme 3, reaction of the polymeric hydroxylamine resin compound 1 with an aldehyde or ketone 9 provides the polymeric oxime ether resin compound 10. Oxime formation is preferably accomplished at about ambient temperature by swelling the polymeric hydroxylamine resin compound 1 in a suitable inert organic solvent such as dichloromethane, followed by addition of an excess of aldehyde or ketone. Reductive cleavage of the resin, for example by reaction with NaCNBH₃, 10 or BH₃·THF, followed by LiAlH₄ provides the amine 11. Reaction of the polymeric oxime ether resin compound 10 with an organometallic reagent of formula R_fM, wherein R_f is an aliphatic or aromatic anion and M is a metal cation as defined herein, provides the polymeric α-substituted hydroxylamine resin compound 12. Cleavage of the α-amine 13 from the resin, is accomplished, for example, using BH₃·THF or LiAlH₄. See Y. Ukaji et al., *Chem. Lett.*, 173, (1991) and R. P. Dieter et al., *Can. J. Chem.* 15 71, 814 (1993). Preferred metal cations are Li and MgX wherein X is halogen. With the aid of a chiral auxiliary such as a chiral benzyl hydroxyl amine linker, chiral α-substituted amines will result.

A process for the preparation of lactones via radical cyclization is shown in Scheme 4. In Scheme 4, R_g, R_h and R_i are aliphatic or aryl as defined herein.

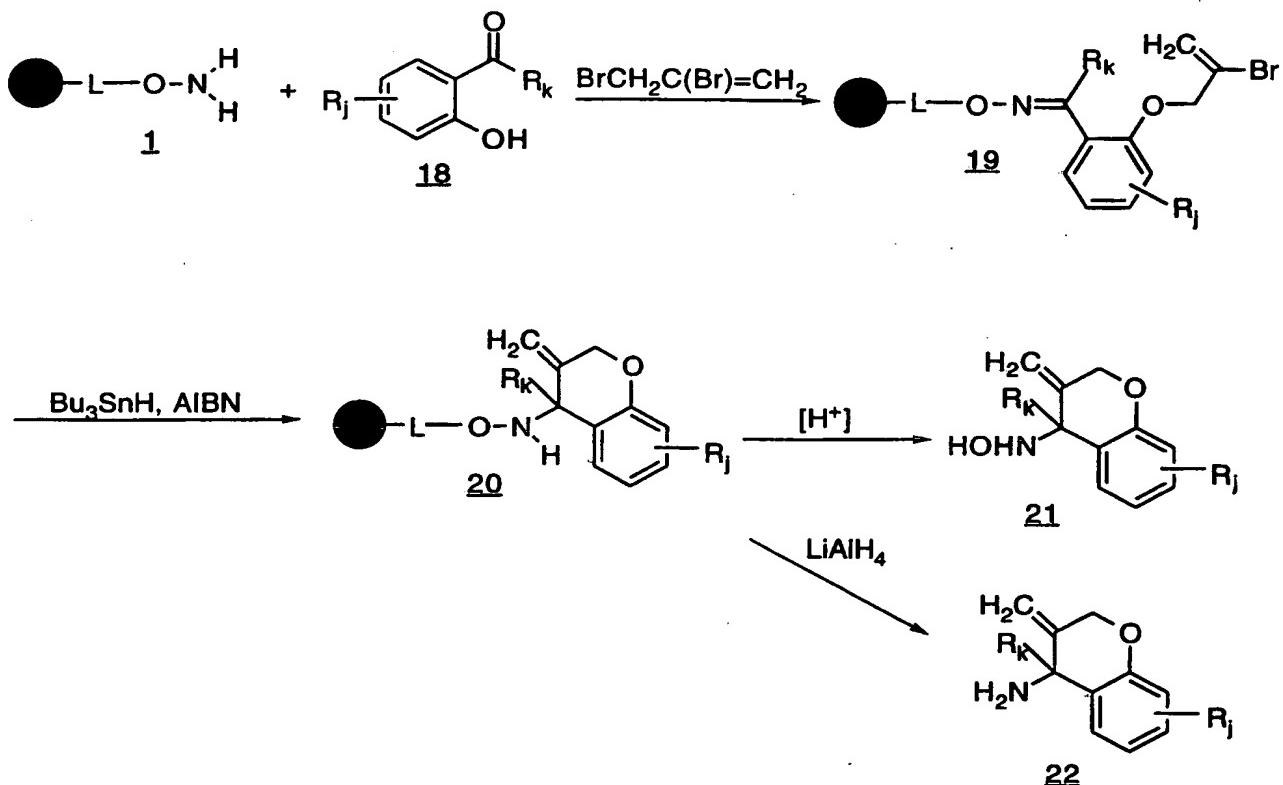
Scheme 4



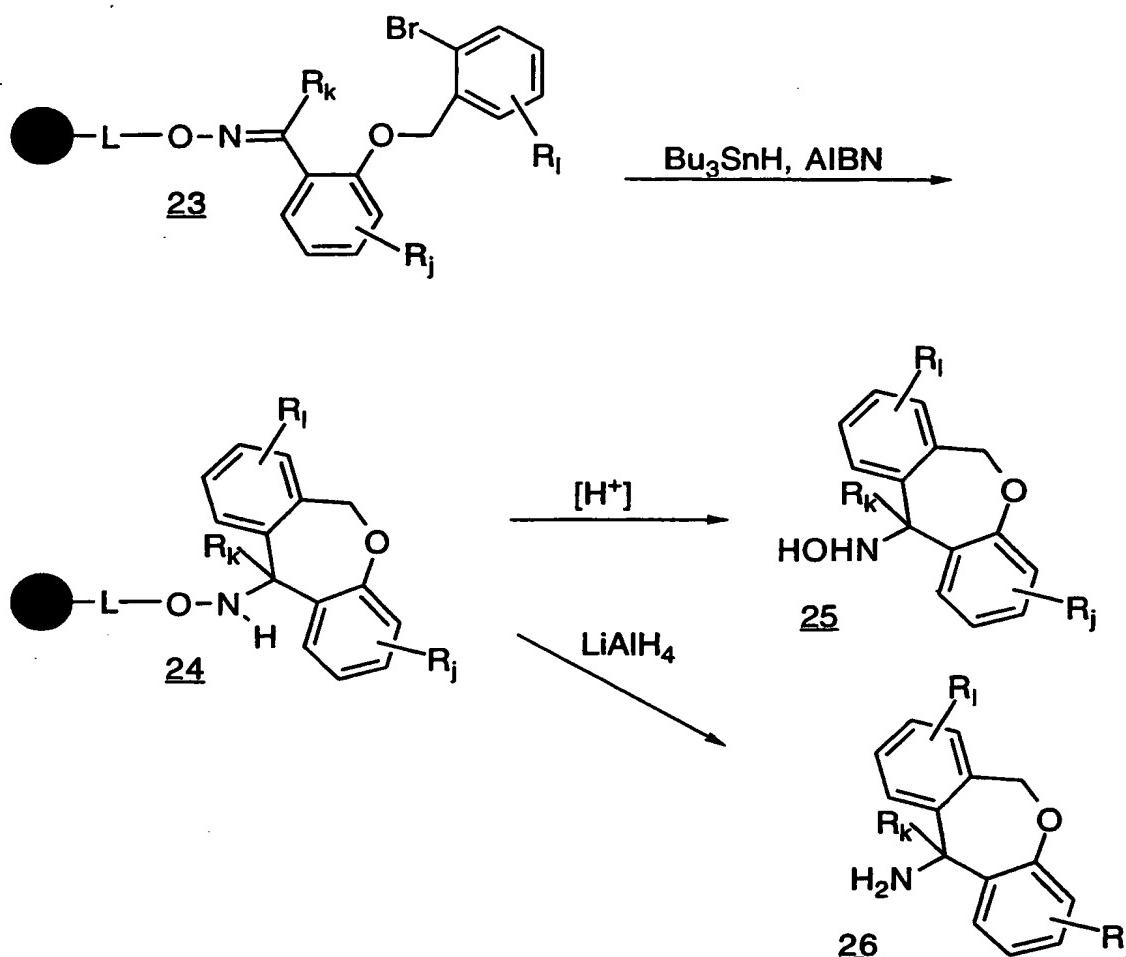
O. As shown in the foregoing Scheme 4, the polymeric hydroxylamine resin compound **1** is reacted with the α,β unsaturated carboxylic acid ester compound **14** to form the polymeric oximyl resin compound **15**. Radical cyclization of **15**, for example by heating in the presence of 2,2'-azobisisobutyronitrile (AIBN) and thiophenol in an inert organic solvent such as benzene results in formation of the polymeric γ -lactone resin compound **16**. Acid hydrolysis of **16**, using, for example 10% aqueous HCl, provides the lactone **17**. See O. Miyata et al., *Tet. Lett.*, **37**, 229-232, (1996).

10 A process for the preparation of carbocyclic or heterocyclic compounds by radical cyclization is shown in Scheme 5. In Scheme 5, R_j , R_k and R_i are aliphatic or aryl as defined herein. The methodology described in Scheme 1 is applicable to the preparation of 5-, 6- or 7-membered rings. Carbocycles result when the phenolic oxygen atom is replaced with a carbon atom.

Scheme 5



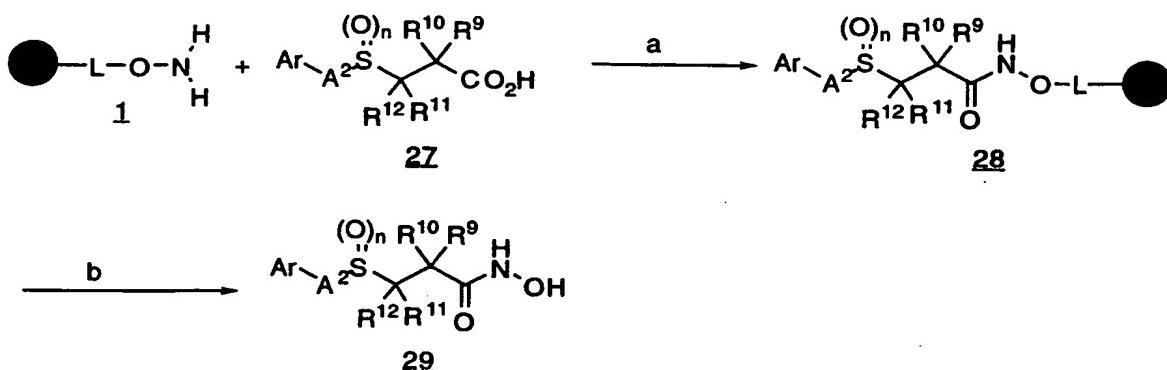
Scheme 5, cont.



According to the foregoing Scheme 5, the polymeric hydroxylamine resin compound 1 is reacted with the acetophenone compound 18 and a bromoalkene compound or o-bromobenzyl compound to form the polymeric acetophenone oxime compounds 19 or 23. Radical cyclization of 19 or 23, for example by heating in the presence of AIBN and tri-n-butyltin hydride in an inert organic solvent such as benzene results in formation of the polymeric N-cyclyl hydroxylamine resin compounds 20 or 24. Treatment of 20 or 24 with acid, preferably trifluoroacetic acid, results in formation of the cyclic hydroxamic acid compounds 21 or 25. Reductive cleavage of 20 or 24, for example using LiAlH₄ as described in Scheme 3 above, results in formation of the cyclic amine compounds 22 or 26. See S.E. Booth et al., *J. Chem. Soc. Commun.*, 1248-1249, (1991).

A process for the preparation of a hydroxamic acid compound of formula 29, wherein n and the groups Ar, A², R⁹, R¹⁰, R¹¹ and R¹² are as defined above is shown in Scheme 6.

Scheme 6

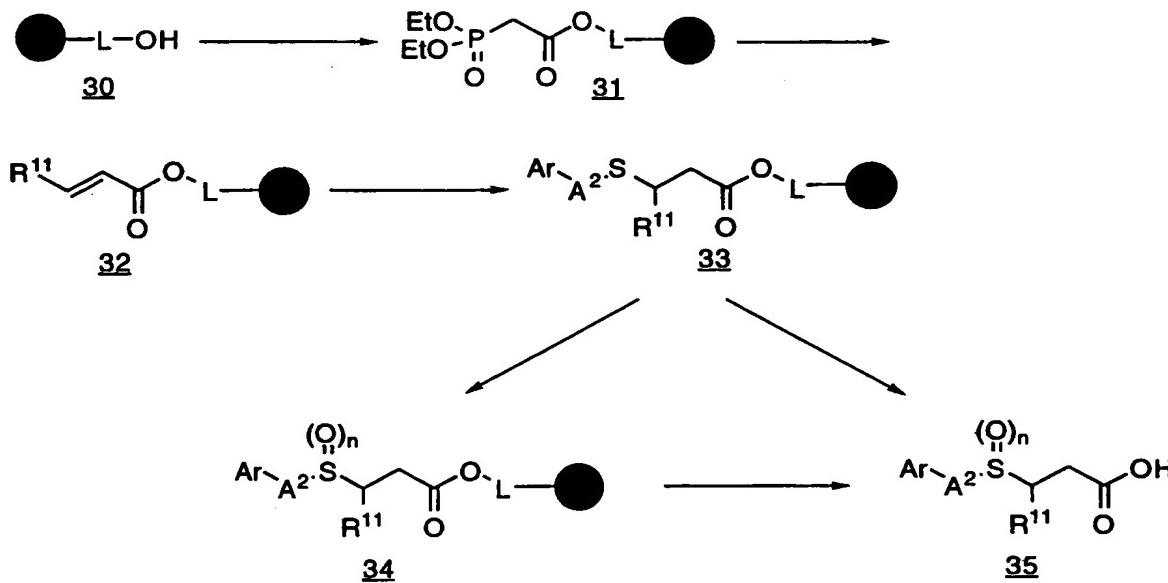


- 5 a) 3-(4-methoxyphenylsulfonyl) propionic acid (5 equiv); 1-(3-dimethylaminopropyl)-3-ethyl carbodiimide hydrochloride (EDCI 5 equiv.); DMF; 25°C; 12 hours. b) 50% TFA in CH_2Cl_2 (100 equiv.); 30 minutes.

According to the foregoing Scheme 6, the carboxylic acid compound 27 is coupled to the polymeric hydroxylamine resin compound 1 as described in Scheme 1 above to form the polymeric hydroxamic acid resin compound 28. The polymeric hydroxamic acid resin compound 28 is then be treated with an acid such as trifluoroacetic acid (TFA) in an inert solvent such as dichloromethane to liberate the hydroxamic acid compound 29. A higher percentage of TFA (trifluoroacetic acid) and longer reaction times are needed to cleave the hydroxamic acid from the Wang version compared to the Rink version of the resin. During the evaporation of the TFA in the work-up to isolate the hydroxamic acid, it is found that heating the sample during concentration would generate a significant amount of the N,O-diacylated dimer of the parent hydroxamic acid as a side-product. To minimize this side reaction the reaction mixture is concentrated at or below room temperature with toluene used as an azeotrope.

A process for the solid phase synthesis of the carboxylic acid compound 27 is shown in Scheme 7. In scheme 7, Ar, A^2 , n, R^9 , R^{10} , R^{11} and R^{12} are as hereinbefore defined..

Scheme 7



5 For example, the polymeric hydroxy resin compound 30 is treated with diethyl phosphonoacetic acid in an inert solvent such as dimethylformamide in the presence of 2,6-dichlorobenzoyl chloride and pyridine at a temperature at about room temperature to give the polymeric diethylphosphonoacetoxy resin compound 31.

10 The polymeric diethylphosphonoacetoxy-resin compound 31 is treated with a base such as potassium bis (trimethylsilyl) amide in an inert solvent such as toluene, at a temperature of about 0°C, followed by an aldehyde of formula $R^{11}CHO$ wherein R^{11} is as defined above, at about ambient temperature to give the polymeric alkenoate resin compound 32.

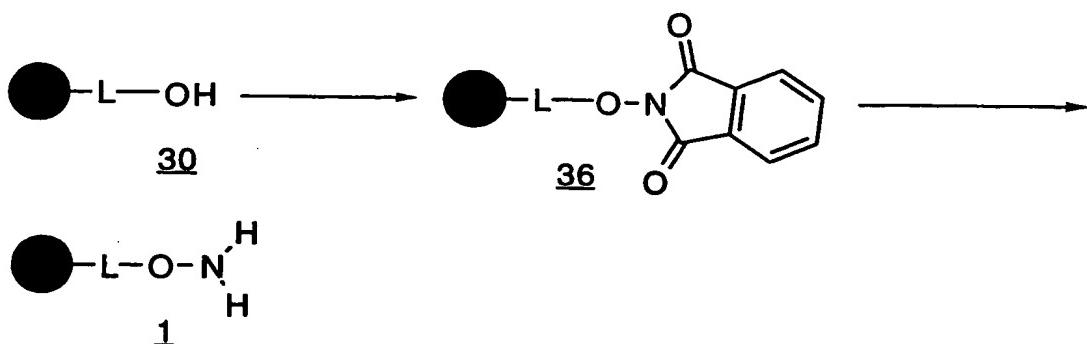
15 The polymeric alkenoate resin compound 32 is then reacted with a thiol of formula $Ar - A^2 - SH$ wherein Ar and A^2 are as defined above, to give the polymeric alkanoate resin compound 33. The addition may be conveniently carried out under mild basic conditions, for example in the presence of lithium hydroxide at about ambient temperature.

The polymeric alkanoate resin compound 33 may then be hydrolyzed by treatment with an acid such as trifluoroacetic acid in an inert solvent such as dichloromethane to prepare the acid 35 wherein n is 0.

20 Alternatively, the polymeric alkanoate resin compound 33 may be treated with an oxidizing agent such as *m*-chloro-perbenzoic acid in an inert solvent, such as dioxane at about ambient temperature to give the polymeric sulfoxide (n = 1) or sulfone (n = 2) resin compound 34. Hydrolysis of 34 as described above provides the carboxylic acid compound 35.

25 The preparation of the polymeric hydroxylamine resin compound 1 is outlined in Scheme 8.

Scheme 8



According to the foregoing Scheme 8, a polymeric hydroxy resin compound 30 is converted to

5 the polymeric N-hydroxylphthalimido resin compound 36 by coupling with N-hydroxypthalimide under Mitsunobu conditions (Mitsunobu, O., *Synthesis* 1981, 1), by conversion of the hydroxy group to a leaving group such as the mesylate followed by nucleophilic displacement, or by reaction of the polymeric hydroxy resin compound with N-hydroxypthalimide in the presence of an acid such as benzenesulfonic acid. Removal of the phthalimido group provides the polymeric hydroxylamine resin compound 1.

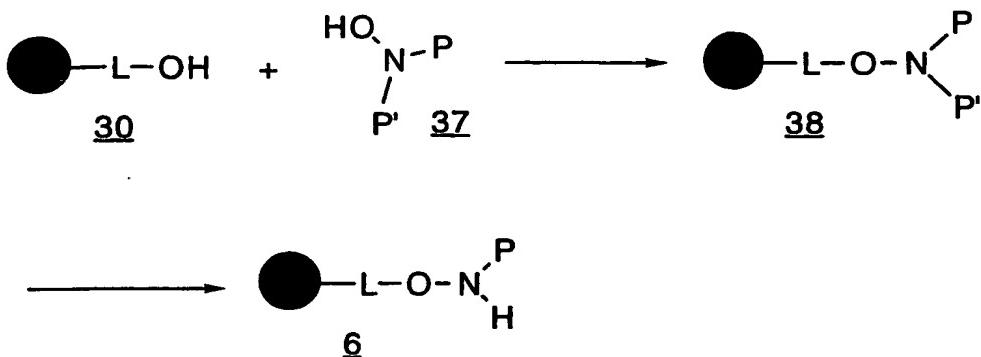
10 For example, when 30 is 4-(hydroxymethyl)phenoxy methyl-copoly(styrene-1%-divinylbenzene)-resin (Wang resin), N-hydroxypthalimide is coupled to the resin in the presence of diisopropylazodicarboxylate and triphenylphosphine in DMF. The phthalimido protection is removed by methylaminolysis in THF at 40 °C. The reaction is complete in about 2 hours. The use of the methylamine to cleave the phthalimide protection offers a significant advantage over the commonly used

15 hydrazinolysis procedure (Wolf et al., *Can. J. Chem.*, 48, 3572, (1970)).

When 4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-phenoxy methyl-copoly(styrene-1%-divinylbenzene)-resin (Rink resin) is utilized, 1 is preferably prepared by reaction of the polymeric hydroxy resin compound with N-Hydroxy phthalimide in DMF in the presence of catalytic benzene sulfonic acid to form the polymeric N-hydroxypthalimido resin compound 36. The phthalimido 20 protecting group is then removed by reaction with hydrazine hydrate in tert-butanol at about 60°C to give the corresponding polymeric hydroxylamine resin compound.

An alternative route to the polymeric N-protected hydroxylamine resin 6 is outlined in Scheme 9.

Scheme 9



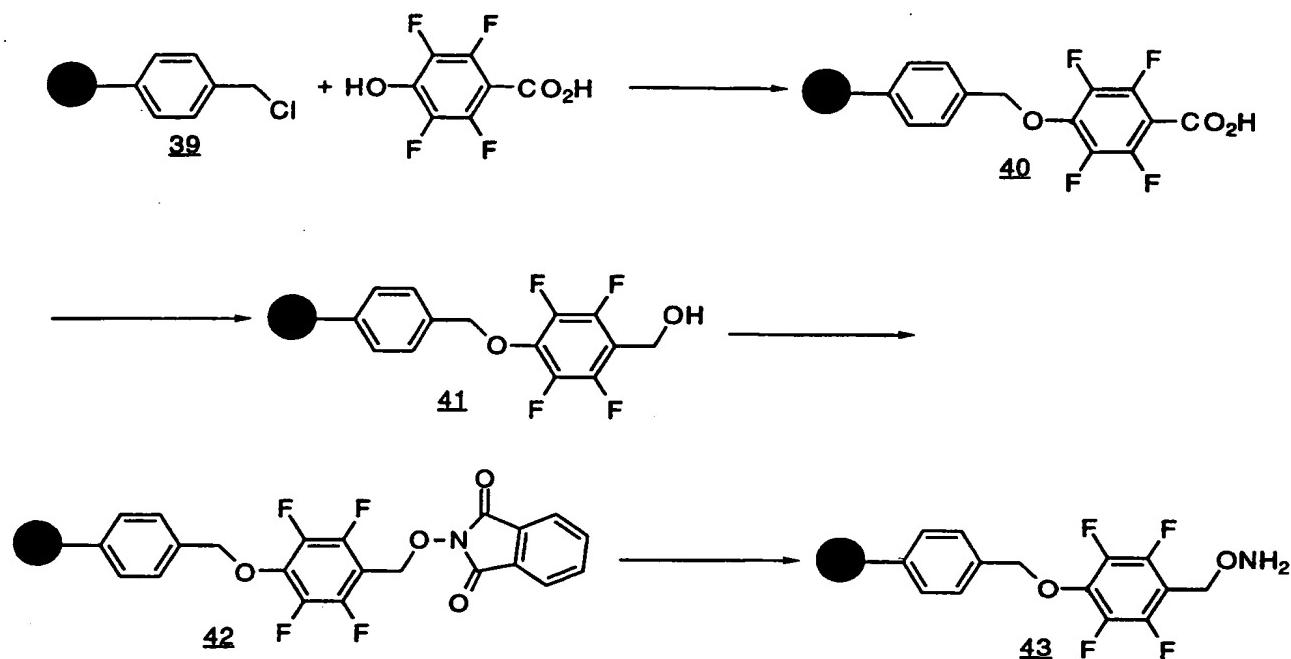
5 According to the foregoing Scheme 9, a polymeric hydroxy resin compound 30 is coupled with a N,N-diprotected hydroxylamine compound 37, wherein P and P' are amine protecting groups as described in Scheme 8 above to form the polymeric N,N-diprotected hydroxylamine resin compound 38. The amine protecting group P' is then selectively removed to form the polymeric N-protected hydroxylamine resin compound 6.

10 In a preferred embodiment of the synthesis described in Scheme 9, P is benzyl and P' is allyloxycarbonyl. Selective removal of the allyloxycarbonyl protecting group is effected by treatment with tetrakis(triphenylphosphine)Palladium(0).

15 The N,N-diprotected hydroxylamine compound 37 is prepared by sequential introduction of the protecting groups P and P' to an O-protected hydroxylamine compound of formula H₂NOP² wherein P² is a hydroxy protecting group. A preferred hydroxy protecting group is alkyl. The amine protecting groups P and P' are then introduced using reagents and reaction conditions well known in the art of organic synthesis. For Example, reaction of O-*tert*-butylhydroxylamine with allyloxylchloroformate results in formation of N-allyloxycarbonyl-O-*tert*-butylhydroxylamine, which is then reacted with benzyl bromide to form N-benzyl-N-allyloxycarbonyl-O-*tert*-butylhydroxylamine. Treatment of N-benzyl-N-allyloxycarbonyl-O-*tert*-butylhydroxylamine with trifluoroacetic acid gives N-benzyl-N-allyloxycarbonylhydroxylamine.

20 The preparation of a polymeric 4-(O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxyethyl resin compound is shown in Scheme 10.

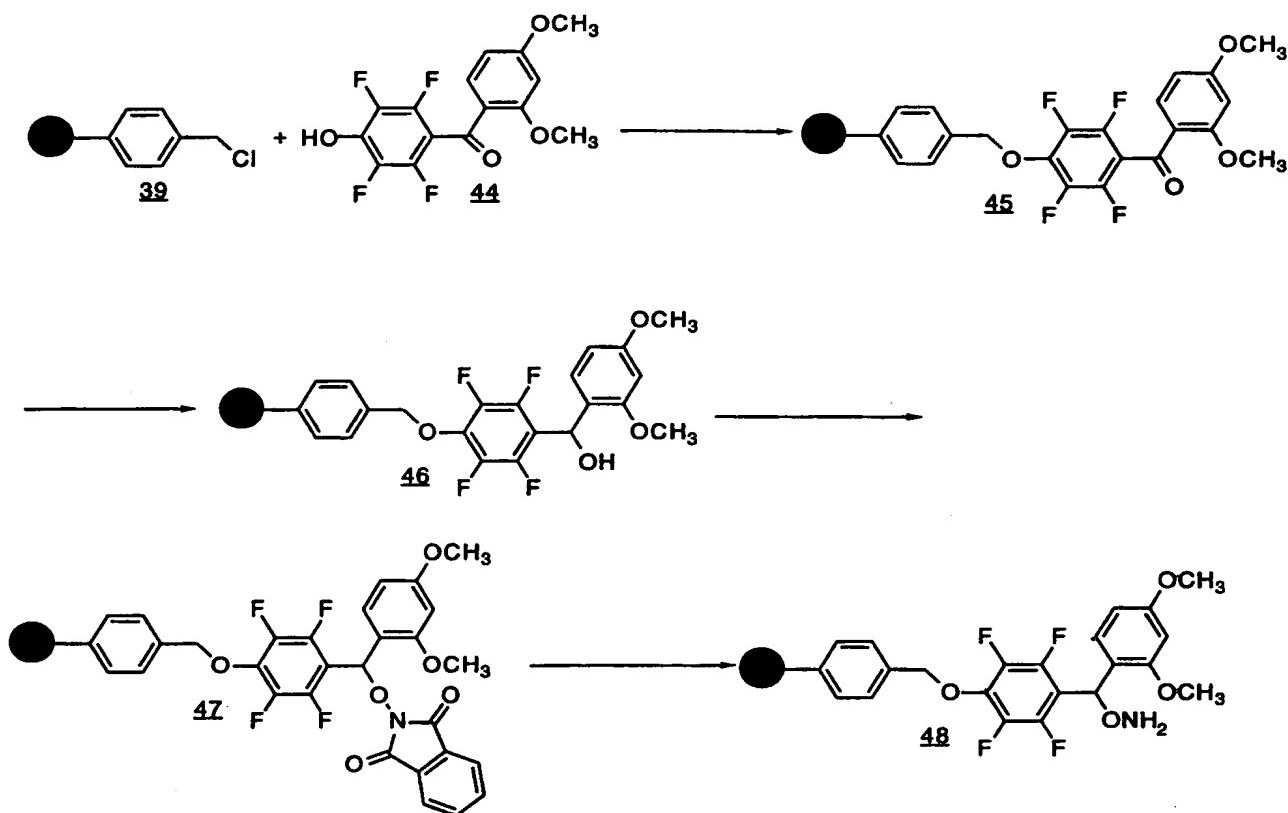
Scheme 10



5 According to the foregoing Scheme 10, a polymeric chloromethyl resin compound such as chloromethylpolystyrene (39, Merrifield resin) is reacted with 4-hydroxy-2,3,5,6-benzoic acid in the presence of base to form the 4-carboxy-2,3,5,6-tetrafluorophenoxy methyl resin compound 40. Reduction of the carboxylic acid group, for example using LiAlH₄, diisobutylaluminum hydride, or BH₃-THF provides the 4-hydroxymethyl-2,3,5,6-tetrafluorophenoxy methyl resin compound 41. Conversion of 41
10 to the hydroxyphthalimido resin compound 42, followed by removal of the phthalimido group as described in Scheme 8 above provides the 4-(O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxy methyl-copoly(styrene-1% divinylbenzene) resin compound 43.

15 The preparation of a polymeric 4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxy methyl resin compound is shown in Scheme 11.

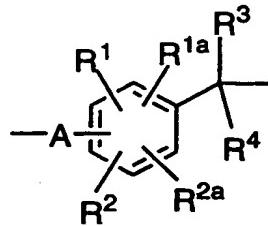
Scheme 11



- 5 According to the foregoing Scheme 11, a polymeric chloromethyl resin compound is reacted with 4-phenoxy-2,3,5,6-tetrafluorophenyl 2,4-dimethoxyphenyl ketone 44 in the presence of base as described in Scheme 10 above to form the 4-(2',4'-dimethoxyphenylcarbonyl)-2,3,5,6-tetrafluorophenoxy methyl-resin compound 45. Reduction of the carbonyl, for example using LiBH₄, provides the 4-(hydroxymethyl-2',4'-dimethoxyphenyl)-2,3,5,6-tetrafluorophenoxy methyl resin compound 46.
- 10 Conversion of 46 to the hydroxyphthalimido resin compound 47, followed by removal of the phthalimido group as described in Scheme 8 above provides the 4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxy methyl- resin compound 48.

Preferred polymeric hydroxylamine resin compounds have formula 1 wherein L is a linking group.

Preferred linking groups L have the formula



5 wherein

A is absent or a group of formula -X¹-Z- wherein

X¹ is -CHR- or -CHR-Y-CO-(CH₂)_n- wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or -NO₂,

Y is -O- or -NH-,

10 n is an integer from 1 to 6, and

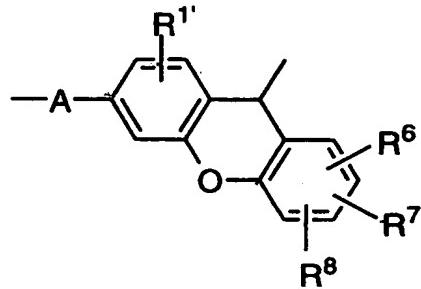
Z is -O- or -NH-;

R¹, R^{1a}, R², and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

15 R³ and R⁴ are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and -NO₂;

or one of R¹ and R² taken together with one of R³ and R⁴ and the carbon atoms to which they are attached define a linking group of formula

20

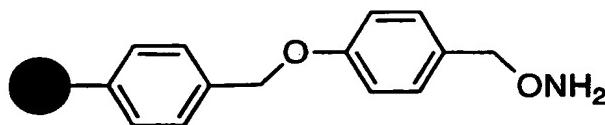


wherein

R^{1'} is -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

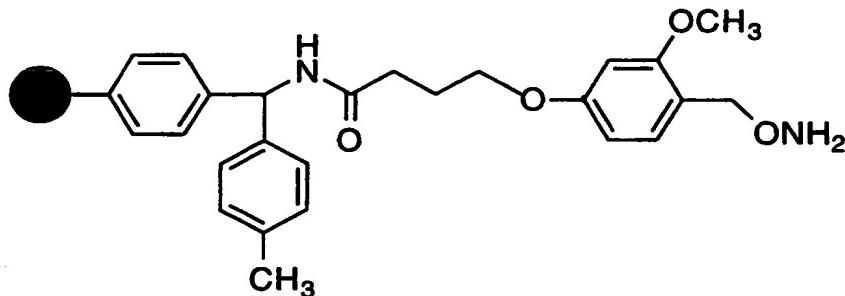
25 R⁶, R⁷ and R⁸ are independently selected from -H, alkyl, alkoxy, halogen, nitrile or -NO₂.

Representative preferred polymeric hydroxylamine resin compounds include
4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin, designated herein as

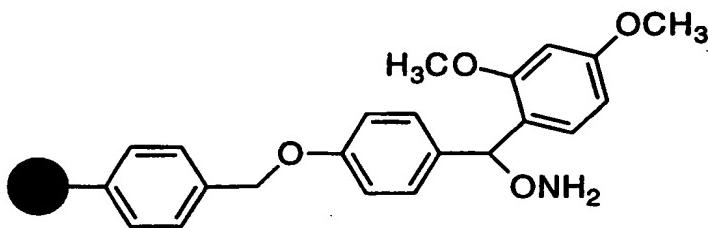


5

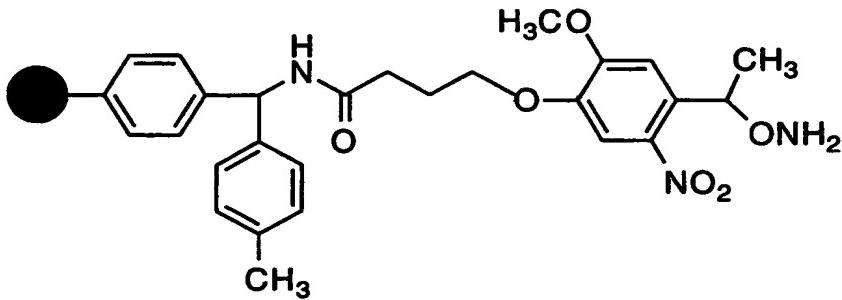
4-[4-(O-methylhydroxylamine)-3-methoxyphenoxy]-(N-4-methylbenzhydryl)-butyramide-copoly(styrene-1%-divinylbenzene)-resin, designated herein as



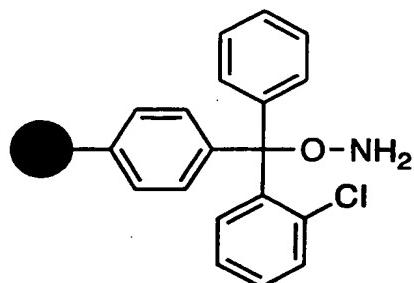
10 **4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-phenoxyethyl-copoly(styrene-1% divinylbenzene) resin, designated herein as**



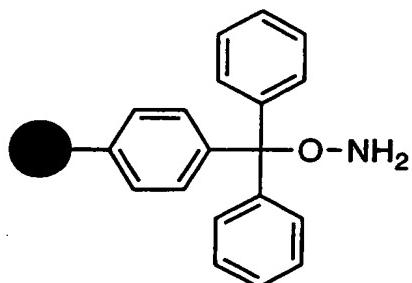
15 **4-[4-(1-aminoxyethyl)-2-methoxy-5-nitrophenoxy]-(N-4-methylbenzhydryl)-butyramide-copoly(styrene-1% divinylbenzene) resin, designated herein as**



O-hydroxylamine-2'-chlorotriyl-copolystyrene-1%-divinylbenzene-resin, designated herein as

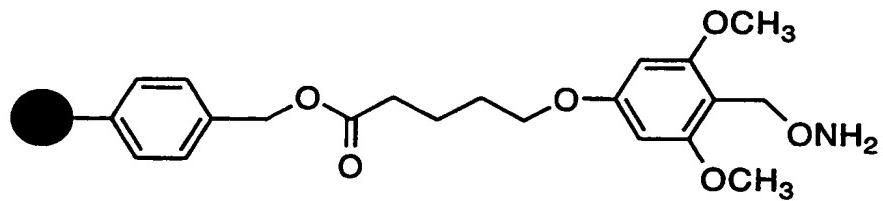


O-hydroxylamine-trityl-copolystyrene-1%-divinylbenzene-resin, designated herein as



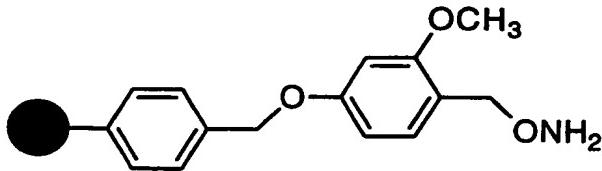
5

5-(4-O-methylhydroxylamine -3,5-dimethoxyphenoxy)-valeric acid-copolystyrene-1%-divinyl benzene resin, designated herein as

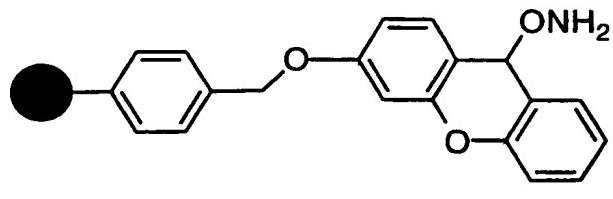


10

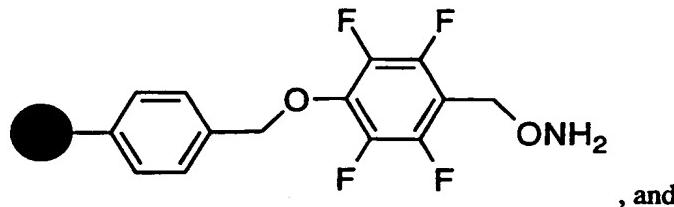
4-O-methylhydroxylamine-3-methoxyphenoxy-copolystyrene-1%-divinyl benzene resin, designated herein as



3-hydroxy-xanthydroxylamine-copolystyrene-1%-divinylbenzene resin, designated herein as

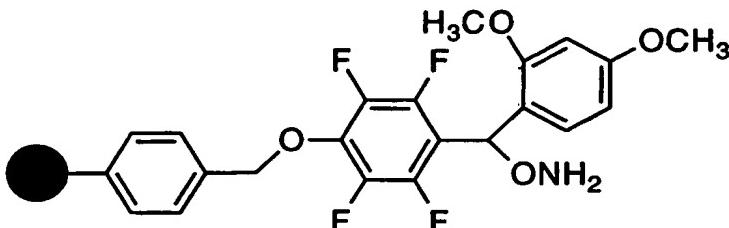


5 4-(O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-1% divinylbenzene) resin, designated herein as



, and

4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-1% divinylbenzene) resin, designated herein as



10

The most preferred polymeric hydroxylamine resin compounds are

4-(O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-1% divinylbenzene) resin,

4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-1% divinylbenzene) resin,

15 4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin, and

4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-phenoxyethyl-copoly(styrene-1% divinylbenzene) resin.

20 The Rink handle (H. Rink, *Tet. Lett.*, 28, 3787-3790, 1987) has the advantage of being cleaved under mild acidolysis for short periods of time (i.e. 10% TFA in DCM for 10-15 minutes.). However, due to the cost of the resin it is desirable to synthesize the corresponding functional resin on the Wang solid support ((a) S. S. Wang, *J. Am. Chem. Soc.*, (1973), 95, 1328. b) G. Lu, S. Mojsov, J. P. Tam, and R. B. Merrifield, *J. Org. Chem.*, (1981), 46, 3433).

25

The tetrafluorophenylphenyl handle is especially useful as it lends itself to ready quantification of resin loading and monitoring of reactions conducted on the resin using fluorine NMR.

The methods described herein are also useful for the preparation of peptide aldehydes, ketones and hydroxamic acids. In general, this method involves coupling the carboxyl group of a suitably N-protected first amino acid to the resin to form the polymeric N-protected amino acid hydroxamic acid 5 resin compound. The amino acid N-protecting group is then removed and the unprotected polymeric amino acid hydroxamic acid resin compound is coupled with a second suitably N-protected amino acid. This process is then repeated until the desired amino acid residues have been incorporated in the peptide.

Alternatively, peptides comprising multiple amino acids are prepared by coupling a suitably N-protected peptide subunit comprising two or more amino acids to form the polymeric N-protected peptide 10 hydroxamic acid resin compound. The amino acid N-protecting group is then removed and the unprotected polymeric peptide hydroxamic acid resin compound is coupled with a second suitably N-protected amino acid or peptide. Thus, in addition to the sequential addition of individual amino acid subunits described above, a polypeptide may be prepared by coupling of peptide subunits.

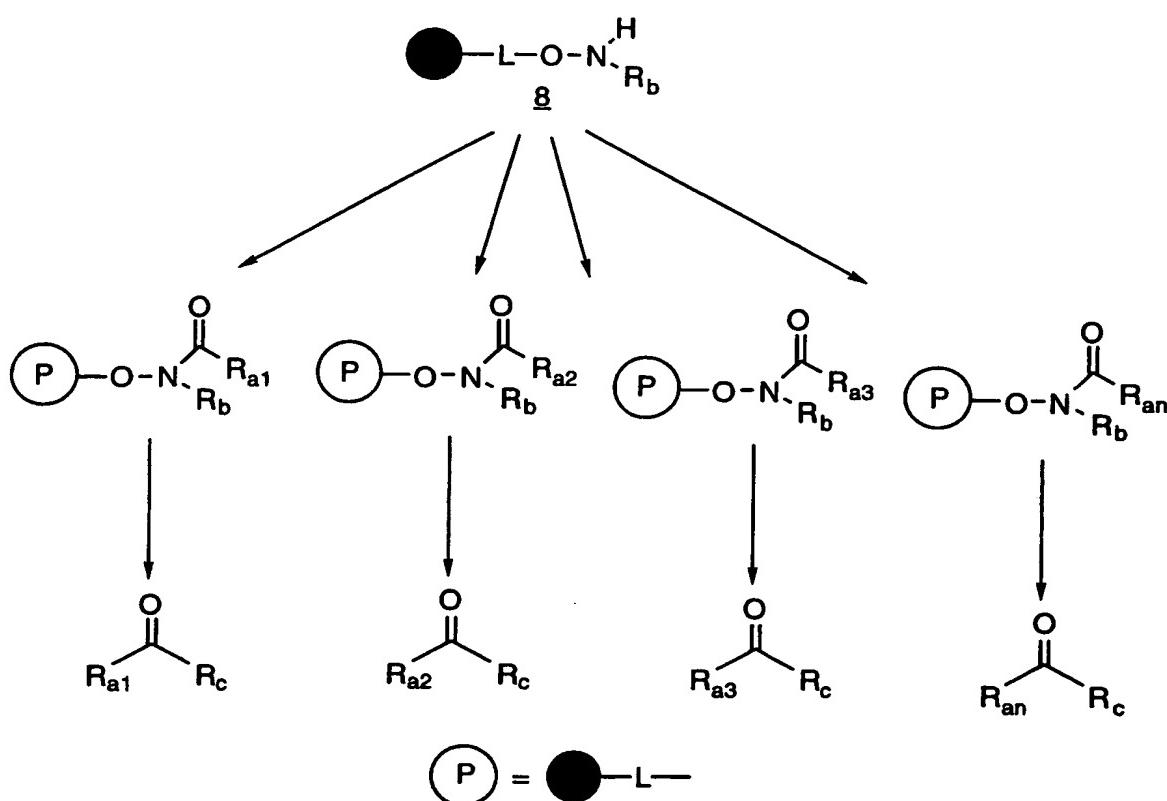
Once the desired amino acids have been incorporated into the peptide, the polymeric peptide 15 hydroxamic acid compound is reacted with an organometallic reagent followed by acid hydrolysis to form the peptide ketone compound; reductively cleaved to form the peptide aldehyde compound; or cleaved with acid to form the peptide hydroxamic acid compound. Any remaining protecting groups may be removed prior to or subsequently to cleavage of the peptide from the resin.

N-protecting groups suitable for use in peptide synthesis as described herein should have the 20 properties of being stable to the conditions of coupling to the polymeric hydroxylamine resin compound while being readily removable without destruction of the growing peptide chain or racemization of any of the chiral centers contained therein. Suitable protecting groups are 9-fluorenylmethyloxycarbonyl (Fmoc), *t*-butyloxycarbonyl (Boc), benzyloxycarbonyl (Cbz), biphenylisopropylloxycarbonyl, *t*-amyloxycarbonyl, isobornyloxycarbonyl, (a,a)dimethyl-3,5-dimethoxybenzyloxycarbonyl, *o*-nitrophenylsulfonyl, 2-cyano-*t*-butyloxycarbonyl, and the like.

Additionally, this resin is useful for constructing arrays of aldehyde, ketone or amine 30 combinatorial libraries or arrays of aldehydes and ketones as reagents in combinatorial library synthesis, for example reagents for the Ugi 4-component condensation (Ivar Ugi, in Isonitrile Chemistry, 1971, p. 145, Academic Press). The hydroxylamine bound resin may be used not only for single functional group transformations, but also multiple step solid phase synthesis to generate combinatorial libraries.

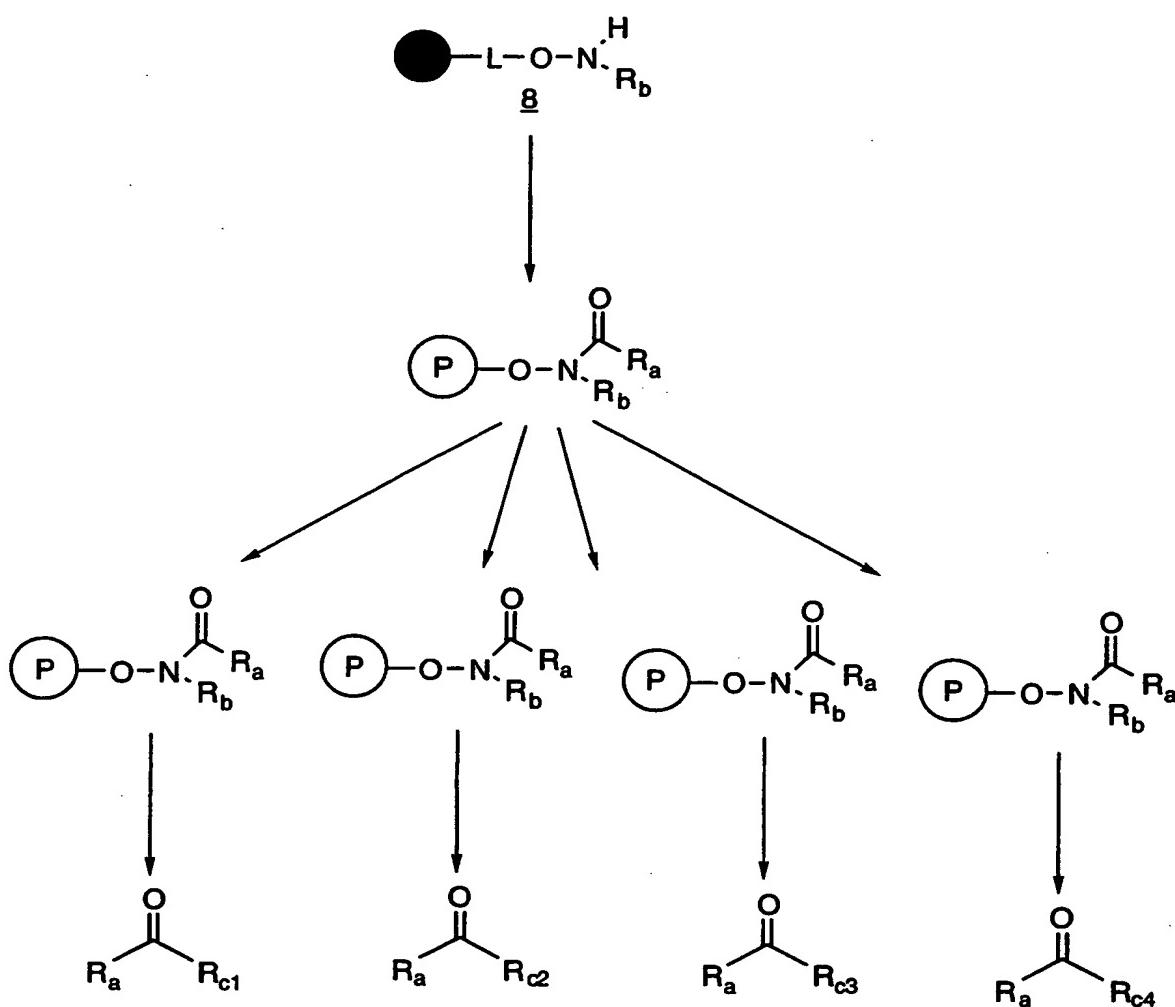
The functionalized resin of this invention is also useful for the parallel synthesis of a multiplicity 35 of different aldehyde, ketone or amine end products as outlined for ketone compounds in Schemes 12a and 12b. In Schemes 12a and 12b, R_a and R_c are as defined above. n is an integer which represents the total number of different aldehyde, ketone or amine products which are to be prepared. R_a-R_m represent, independently, an aliphatic or aromatic group as defined herein.

Scheme 12a



5 The parallel synthesis of a multiplicity of ketone compounds using a multiplicity of carboxylic acid compound $R_{a1}CO_2H - R_{an}CO_2H$ and a single organometallic compounds R_cMgX is shown in Scheme 12a. According to Scheme 12a, the N-alkylated hydroxylamine resin compound 8, prepared as described in Scheme 2, is divided into n portions. Each portion of resin is then coupled with a different carboxylic acid compound to give n portions of polymeric N-alkylated hydroxamic acid resin compound. Each 10 portion of polymeric N-alkylated hydroxamic acid resin compound is then reacted with a Grignard reagent of formula R_cX and subjected to acid hydrolysis to give n portions of ketone derived from a single organometallic reagent.

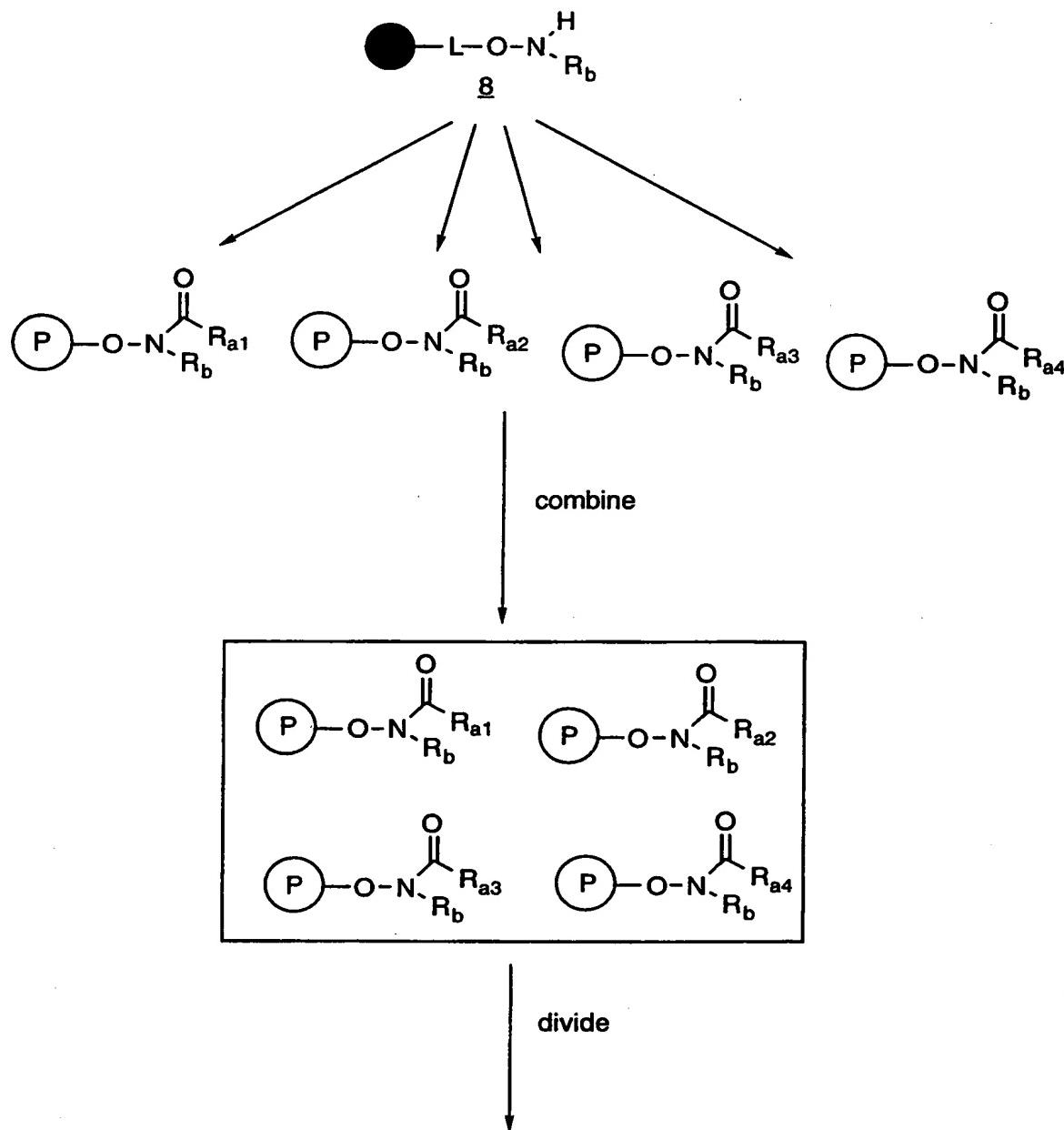
Scheme 12b



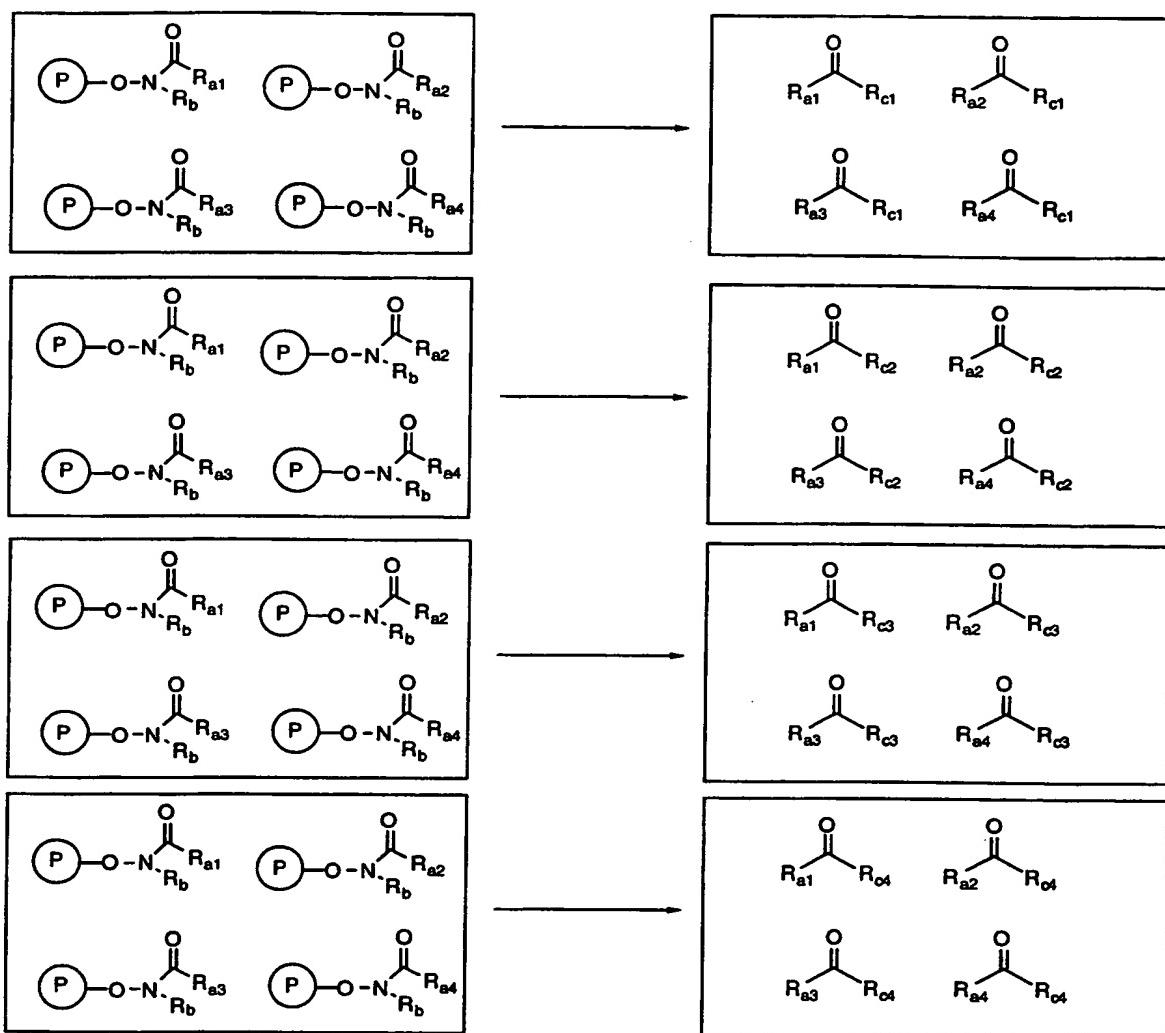
5 The parallel synthesis of n different ketone compounds derived from a single carboxylic acid compound $\text{R}_a\text{CO}_2\text{H}$ and n different organometallic compounds R_{c1}MgBr to R_{cn}MgBr is outlined in Scheme 12b above. According to Scheme 12b, the polymeric N-alkylated hydroxylamine resin compound is coupled with a carboxylic acid of formula $\text{R}_a\text{CO}_2\text{H}$. The resulting polymeric N-alkylated hydroxamic acid resin compound is then divided into n portions, and each portion of polymeric N-
10 alkylated hydroxamic acid resin compound is then reacted with a different Grignard reagent $\text{R}_{c1}-\text{R}_{cn}\text{MgBr}$ and subjected to acid hydrolysis to give n different ketone compounds derived from a single carboxylic acid compound.

15 The functionalized resins of this invention are also useful for constructing a combinatorial library of ketones or amines as illustrated for the ketone library derived from 4 carboxylic acid compounds and 4 Grignard reagents as outlined in Scheme 13.

Scheme 13



Scheme 13, cont.



According to the foregoing Scheme 13, the polymeric N-alkylated hydroxylamine resin

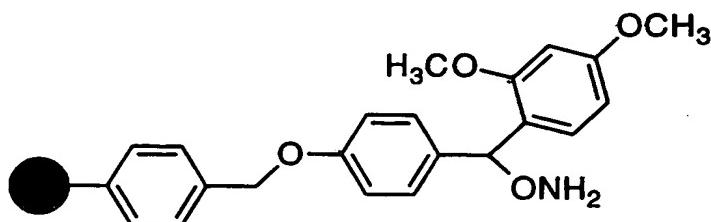
- 5 compound 8 is divided in 4-portions, and each portion is coupled with a different carboxylic acid compound to prepare 4 different polymeric N-alkylated hydroxamic acid resin compounds. The 4 portions of polymeric N-alkylated hydroxamic acid resin compounds are then mixed together to form a single portion which is then divided into 4 portions of polymeric N-alkylated hydroxamic acid resin compounds, in which each portion contains approximately equal amounts of each individual polymeric
- 10 N-alkylated hydroxamic acid resin compound. Each of the 4 portions is then reacted with a different Grignard reagent $R_{c1}-R_{c4}MgBr$ and subjected to acid hydrolysis to give 4 portions of ketone compound, each of which contains 4 compounds representing the products of reaction of each of the 4 different polymeric N-alkylated hydroxamic acid resin compounds with a single Grignard reagent. In this manner a combinatorial library containing a multiplicity of ketone compounds may be quickly constructed.

15 In a similar manner, a combinatorial library of peptides may be assembled by repeating the dividing-recombinining sequence for each amino acid or peptide building block.

The foregoing may be better understood by reference to the following Examples, which are presented for illustration and not intended to limit the scope of the invention.

Example 1

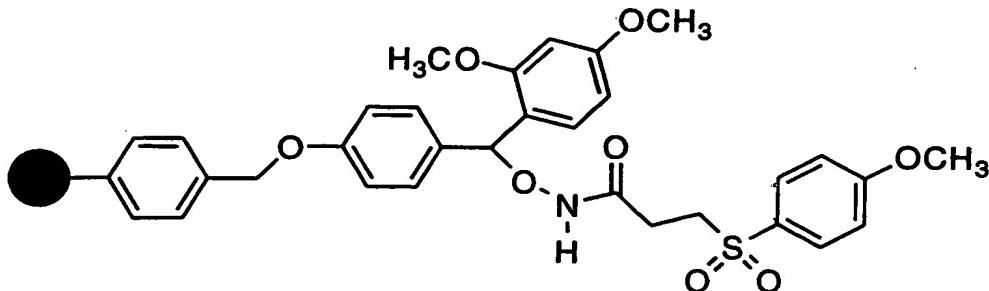
- 5 Preparation of 4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-phenoxyethyl-copoly(styrene-1% divinylbenzene) resin.



- 10 Rink acid resin (1 g; 0.63 mmol) is swelled in DMF (10 mL) for 15 minutes at ambient temperature. N-Hydroxyphthalimide (514 mg; 3.15 mmol) is added to the resin suspension followed by benzene sulfonic acid (19 mg; 0.13 mmol). The mixture is stirred by means of a mechanical stirrer and heated to 50 °C for five hours. The mixture is then cooled to ambient temperature and stirred for an additional 12 hours, after which the resin is filtered and washed extensively with DMF (5 x 25 mL);
15 DMF:H₂O (70:30; 5 x 25 mL); THF (10 x 25 mL); and diethyl ether (10 x 25 mL). The resin is then dried overnight under high vacuum at 40 °C. The IR spectrum shows a carbonyl absorbance at 1733 cm⁻¹ corresponding to the phthalimido carbonyl stretch. Elemental analysis: calcd.: 0.28% N. Found: 0.26% N. Loading = 0.18 mmol/g.
- 20 The resin is swelled in 20 mL of tert-butanol for ten minutes. Hydrazine hydrate (10 mL) is added to the mixture and the reaction is warmed to 60 °C with mechanical stirring for 12 hours. After which the reaction is cooled to ambient temperature. The resin is filtered and washed extensively with DMF (10 x 25 mL), THF (10 x 25 mL), and diethyl ether (10 x 25 mL), then dried under high vacuum at 40 °C overnight. The IR spectrum of resin III showed the loss of the carbonyl stretch at 1733 cm⁻¹ which
25 is present in the starting material. Elemental Analysis: %N found = 0.43; 0.42 (coresponding to a loading level of 0.3 mmol/g).

Example 2

Preparation of N-[3-((4-methoxyphenyl)sulfonyl)prop-1-ylcarbonyl]4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-phenoxyethyl-copoly(styrene-1% divinylbenzene) resin.



4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-phenoxyethyl-copoly(styrene-1% divinylbenzene) resin (200 mg) is swelled in DMF (3 mL). To this suspension is added 3-(4-methoxyphenylsulfonyl)propionic acid (610 mg; 2.5 mmol) and 1-(3-dimethylaminopropyl)-3-ethyl carbodiimide hydrochloride (EDCI; 477 mg; 2.5 mmol) at ambient temperature. The reaction mixture is shaken at ambient temperature using a vortex shaker for 12 h, after which the resin is filtered and washed extensively with DMF:H₂O (80:20; 5 x 5 mL), DMF (5 x 5 mL), THF (5 x 5 mL), and diethyl ether (5 x 5 mL). The resin IV is dried under high vacuum at 40 °C for 12 hours. The IR spectrum shows a carbonyl absorbance at 1675 cm⁻¹ corresponding to the bound hydroxamate.

15

Example 3

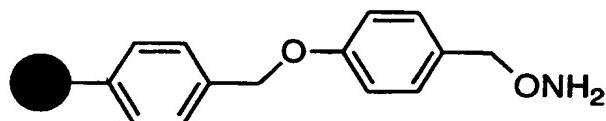
Preparation of N-hydroxy-3-(4-methoxyphenylsulfonyl)propionamide.

20 Dry N-[3-((4-methoxyphenyl)sulfonyl)prop-1-ylcarbonyl]4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-phenoxyethyl-copoly(styrene-1% divinylbenzene) resin (200 mg), prepared as in Example 2, is swelled in 3 mL of methylene chloride for 10 minutes. Trifluoroacetic acid (TFA; 0.3 mL) is added to the mixture dropwise at ambient temperature and the resulting mixture is vortexed for 30 minutes. The resin turned a dark blue upon addition of the TFA. The mixture is then filtered and washed with two 5 mL portions of methylene chloride. The filtrate is evaporated by rotary evaporation to yield 20 mg of crude product. An LC/MS trace of the crude reaction mixture showed it to contain better than 75 area % of the desired product, 3-(4-methoxyphenylsulfonyl)propionic acid is present in 6 area %). ¹H NMR (MeOH-*d*₄) δ 2.45 (t, 2H); 3.45 (t, 2H); 3.90 (s, 3H), 7.15 (d, 2H); 7.85 (d, 2H).

30

Example 4

Preparation of 4-O-Methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (100-200 mesh).



5

A 1-L jacketed reactor with a bottom valve and overhead stirrer (Ace catalog #8090) is charged with Wang resin (18.35 g, 20 meq) and anhydrous tetrahydrofuran (THF, 450 mL). This mixture is stirred gently for about 15 minutes, then as much solvent as possible is removed through a tube fitted with a porous glass frit *via* vacuum aspiration. Fresh THF is added, followed by triphenylphosphine (15.74 g, 60 mmol) and N-Hydroxyphthalimide (16.31 g, 100 mmol). The resulting mixture is stirred and cooled to -5–0 °C. Diisopropyl azodicarboxylate (11.8 mL, 60 mmol) is added slowly so as to maintain the temperature at <5 °C. When the addition is complete, the stirred mixture is allowed to warm slowly to room temperature and stirred overnight. As much of the reaction liquors as possible is removed by aspiration through the dip tube as above. The resin is washed by charging N,N-dimethylformamide (DMF, 200 mL), stirring the mixture for 3–5 minutes, and then removing by aspiration as much of the wash solution as possible. Similarly, the resin is washed sequentially with an additional portion of DMF and portions of methanol (twice), THF (twice), and methanol (once). A portion of the resin may be removed for analysis: IR 1734 cm⁻¹ (C=O).

20

To the resin remaining in the reactor is added THF (400 mL) and 200 mL of a 40% aqueous solution of methylamine (2.31 mol). This reaction mixture is stirred gently at 40 °C for 2 hours, then cooled to room temperature (the mixture may be held overnight at this temperature). As much of the reaction liquor as possible is removed by aspiration, and the resin is washed with the solvent array as above. Following the final methanol wash, additional methanol is used to flush the resin out of the bottom of the reactor and isolate it by filtration. The filtered resin is dried at 40 °C under vacuum. Yield 18–18.5 g resin: amine load 1.02 meq/g (based on potentiometric titration of a THF suspension with p-toluenesulfonic acid); IR (microscopy) 3316 cm⁻¹ (w, -NH₂). Analysis found C, 87.07%; H, 7.77%; N, 1.58%, which corresponds to 1.13 nitrogen atoms/g resin.

30

Assay: preparation of 4-nitrophenylethanehydroxamic acid.

A 200 mg sample of the dried resin (ca. 0.2 mmol) is charged to a 5- or 10-mL resin reactor (a polypropylene syringe barrel fitted with a polypropylene frit). The resin is swelled for about 15 minutes in dry DMF, and then 115 mg 1-(3-dimethylaminopropyl)-3-ethylcarbodiimide hydrochloride (EDCI, 0.6 mmol) is added. To this mixture is then added 4-nitrophenylacetic acid (115 mg, 0.6 mmol). The reactor is capped and the mixture is agitated slowly overnight (a rocker bed apparatus is used). The reaction liquors are removed by vacuum filtration (the resin reactor is inserted through a small rubber vacuum flask adapter), and the resin is washed by several small (2–3 mL) portions of the following solvents:

DMF (4–5 portions), MeOH or 50% aq. DMF (3–4 portions), THF (3–4 portions), and MeOH (2–3 portions). The resin (still in the syringe reactor) is dried for at least 4 hours under vacuum at 40 °C.

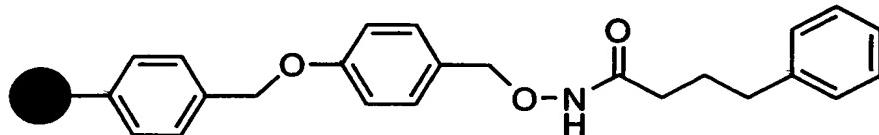
To this dried resin is added 2 mL dichloromethane followed by 2 mL trifluoroacetic acid (TFA). Additionally, 20 mL water is added (believed to reduce “anhydride” formation from hydroxamic acid product). The mixture is allowed to react for about 1 hr, and the reaction liquors are drained into a tared collector. The resin is washed with 1–2 1-mL portions of dichloromethane followed by 1–2 1-mL portions of toluene. The combined filtrates are concentrated to about 2 mL at 30 °C, 2 mL additional toluene is added, and the resulting solution is concentrated to dryness under vacuum (rotary evaporator followed by vacuum oven at 30 °C; note that heating in the presence of TFA promotes formation of the “anhydride” impurity). The residue is weighed and analyzed for weight % purity (HPLC, using the carboxylic acid as a response factor standard). Typical results for 4-nitrophenylethanehydroxamic acid: 29–30 mg solids at 60–70 wt% purity, 90–97 A% purity (261 nm); ¹H NMR (CD₃OD) δ 8.13 (d, 2H), 7.25 (d, 2H), 4.85 (bs, OH, NH), 3.55 (s, 2H); ¹³C NMR δ 169.4, 144.3, 131.3, 124.6, 40.2. This reflects a load/clip chemical yield of 50–55% from resin at 1 meq/g.

15

Example 5

Preparation of N-4-phenylbut-1-oyl-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.

20

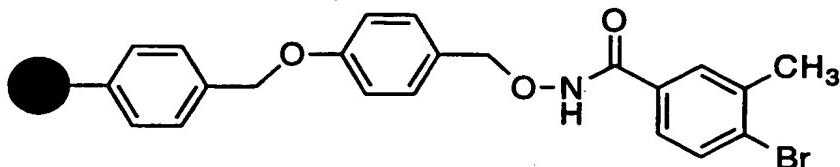


Dry 4-O-Methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (2 g, 1.5 mmol), prepared as in Example 4, is allowed to swell in DMF (8 mL) for 10 minutes and then is treated with 4-phenyl butyric acid and EDC (0.86 g, 4.5 mmol). The mixture is shaken for 24 hours and filtered. The resin is washed with DMF, DMF/H₂O, DMF, THF and Et₂O and dried under vacuum at 40°C to give N-4-phenylbut-1-oyl- 4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (2.2 g). IR: C=O 1670 cm⁻¹. Elemental analysis: calcd; N, 1.05%. Found: N, 1.07%.

30

Example 6

Preparation of N-(4-bromo-3-methylbenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.



5

Dry 4-O-Methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (4 g, 3 mmol), prepared as in Example 4, is allowed to swell in DMF (32 mL) for 10 minutes, then is treated with 4-bromo-3-methylbenzoic acid and EDC (1.725g, 9 mmol). The mixture is shaken for 24 hours and 10 filtered. The resin is washed with DMF, DMF/H₂O, DMF, THF and Et₂O and dried under vacuum at 40°C to give N-(4-bromo-3-methylbenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (4.5 g). IR: C=O 1677.5cm⁻¹. Elemental analysis: calcd: Br, 5.2%; N, 1.05%. Found: Br, 5.3%; N, 0.91%.

15

Example 7

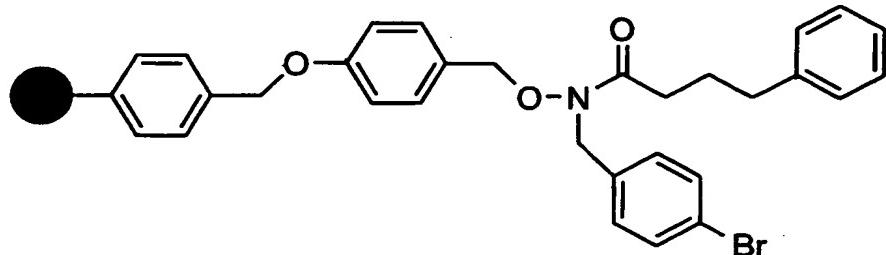
Preparation of N-Hydroxy-4-bromo-3-methyl benzamide.

N-(4-bromo-3-methylbenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin, prepared as in Example 6, is suspended in 50% TFA/CH₂Cl₂ for 2 hours. The resin is filtered and washed three times with CH₂Cl₂ to give N-Hydroxy-4-bromo-3-methyl benzamide. LC MS: m/z 230/232 (Br)[M+H]⁺ Area = 78%; ¹H NMR (300 Mhz, CDCl₃) δ: 2.42 (s, 3H), 7.4 (bd J = 7.89, 1H) 7.58 (bd J = 7.89 1H), 7.62 (bs, 1H).

25

Example 8

Preparation of N-4-bromobenzyl-N-4-phenylbut-1-ylcarbonyl- 4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.



5

N-4-phenylbut-1-oyl-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (1.46 g, 1.095 mmol), prepared as in Example 5, is suspended in toluene (26 mL) for 10 minutes. DBU (0.83 mL; 5.5 mmol) is added and the mixture is agitated for 2 hours on a wrist shaker. Bromobenzyl bromide (4.1 g, 16.425 mmol) is added and the reaction mixture is vigorously agitated for 4 days. The resin is filtered and washed with DMF, DMF/H₂O, DMF, THF and Et₂O and dried under vacuum at 40°C to give N-4-bromobenzyl-N-4-phenylbut-1-ylcarbonyl- 4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (1.4 g). IR C=O 1668 cm⁻¹. Elemental Analysis: calcd: Br, 5.3%; N, 0.94%. Found: Br, 5.4%; N, 0.85%.

15

Example 9

Preparation of 4-Phenyl butyraldehyde.

N-4-bromobenzyl-N-4-phenylbut-1-oyl-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (0.2 g, 0.6 mmol/g 0.12 mmol) is suspended in diethyl ether for 10 minutes and then cooled to 5 °C in an orbital shaker. The suspension is treated with LiAlH₄OMe (0.46 M in diethyl ether, 0.22 mL, 0.1 mmol) and agitated for 30 minutes at this temperature. The reaction mixture is quenched by the addition of 2 M HCl (aq) and vortexed for 30 minutes. Sodium potassium tartrate is added and the mixture vortexed for a further 10 minutes. Sodium sulfate is added and the mixture is filtered through a plug of silica gel, washing thoroughly with dichloromethane. The filtrate is concentrated to give 4-phenyl butyraldehyde. GC: Area = 91%; ¹H NMR (CDCl₃) δ 9.75 (1H,s), 7.05-7.30 (5H,m), 2.58-2.68 (2H,m), 2.41-2.50 (2H,t), 1.91-2.02 (2H,m); MS (EI): m/z = 149 [M+H⁺].

30

Example 10

Preparation of 6-Phenylhexan-3-one.

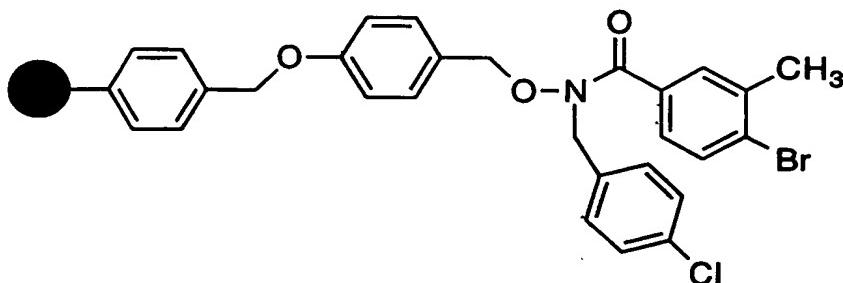
N-4-bromobenzyl-N-4-phenylbut-1-oyl-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (0.15 g, approx. 0.75 mmol/g 0.11 mmol) is suspended in

diethyl ether (1 mL) and treated with 1 M solution of ethyl magnesium bromide in tetrahydrofuran (0.34 mL, 0.34 mmol). The reaction mixture is agitated for 18 hours, and then quenched by the addition of 2 M HCl (aq) (approx pH 3 is obtained). The mixture is agitated for 30 minutes. Sodium sulfate is added and the mixture is filtered through a plug of silica gel, washed thoroughly with dichloromethane and

5 concentrated to give of 6-phenylhexan-3-one. GC MS (EI) Area = 97.1%, m/z 176.2 (M)⁺; MS (EI-LRP) m/z 176 (M)⁺; NMR (300 Mhz, CDCl₃) δ 1.02 (t, 3H), 1.9 (m, 2H), 2.4 (m, 4H) 2.6 (m, 2H), 7.2-7.3 (m, 5H).

10 Example 11

Preparation of N-4-chlorobenzyl-N-(4-bromo-3-methylbenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.



15

N-(4-bromo-3-methylbenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (2.8 g, 2.1 mmol), prepared as in Example 6, is suspended in toluene (27 mL) and the mixture is stirred for 10 minutes. DBU (1.6 g, 10.5 mmol) is added and the mixture is agitated for 2 hours on a wrist shaker. Chlorobenzyl bromide (6.47 g, 31.5 mmol) is added and the reaction mixture is 20 vigorously agitated for 3 days. The resin is filtered and washed with DMF, DMF/H₂O, DMF, THF and Et₂O, and dried under vacuum at 40°C to give N-4-chlorobenzyl-N-(4-bromo-3-methylbenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (3 g). IR C=O 1644 cm⁻¹; Elemental Analysis: calcd: Br, 4.2%; Cl, 1.9%; N, 0.8%. Found: Br, 3.8%; Cl, 2.0%; N, 0.9%.

25

Example 12

Preparation of N-(4-Chlorobenzyl)-N-hydroxy-3-methyl-4-bromobenzamide.

30 N-4-chlorobenzyl-N-(4-bromo-3-methylbenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin, prepared as in Example 11, is suspended in 50% TFA/CH₂Cl₂ for 2 hours. The resin is filtered and washed three times with CH₂Cl₂ to give N-(4-Chlorobenzyl)-N-hydroxy-3-methyl-4-bromobenzamide. LC MS (H-ISP) m/z 354/356 (Cl/Br) [M+H]⁺ Area 64%; ¹H NMR (300 Mhz, CDCl₃) δ 2.3 (bs, 3H), 4.65 (bs, 2H), 7.2-7.6 (m, 7H).

Example 13**Preparation of 4-Bromo-3-methyl benzaldehyde.**

5 N-4-chlorobenzyl-N-(4-bromo-3-methylbenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (0.2 g, 0.5 mmol/g 0.1 mmol), prepared as in Example 11, is suspended in diethyl ether for 10 minutes and then cooled to 5 °C in an orbital shaker. The suspension is treated with LiAlH₄OMe (0.46 M in diethyl ether, 0.2 mL, 0.092 mmol) and agitated for 30 minutes at this temperature. The reaction mixture is quenched by the addition of aqueous 2 M HCl and vortexed
10 for 30 minutes. Sodium potassium tartrate is added and the mixture is vortexed for a further 10 minutes. Sodium sulfate is added and the mixture is filtered through a plug of silica gel, washing thoroughly with dichloromethane. The filtrate is concentrated to give 4-bromo-3-methyl benzaldehyde. GC MS: EI Area = 99.5%, m/z 179/199 (Br)[M]⁺; ¹H NMR (CDCl₃) δ 9.94 (1H,s), 7.70 (2H,d), 7.52 (1H,d), 2.45 (3H,s); MS (EI): m/z=199 [M+H⁺].

15

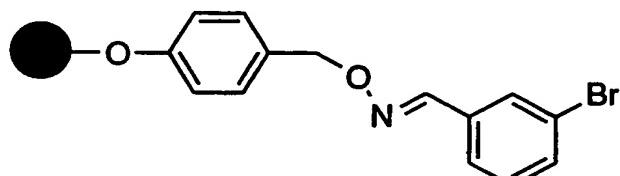
Example 14**Preparation of 1-(4-Bromo-3-methyl phenyl) propan-1-one.**

20 N-4-chlorobenzyl-N-(4-bromo-3-methylbenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (0.23 g, 0.5 mmol/g 0.115 mmol), prepared as in Example 11, is suspended in diethyl ether (1 mL) and treated with ethyl magnesium bromide (1.0 M in THF, 0.23 mL, 0.23 mmol). The reaction mixture is agitated for 18 hours, and then quenched by the addition of aqueous 2 M HCl (approx pH 3 is obtained). The mixture is agitated for 30 minutes. Sodium sulfate is added
25 and the mixture is filtered through a plug of silica gel, washing thoroughly with dichloromethane. The residue is concentrated to give 1-(4-Bromo-3-methyl phenyl) propan-1-one. GC Area = 78.7%; MS (EI) m/z 226 Br [M⁺-H]; NMR (300 Mhz, CDCl₃) δ 1.22 (t J = 7.89, 3H), 2.96 (q J = 7.89, 2H), 7.6 (bs, 2H), 7.8 (s, 1H).

30

Example 15

Preparation of N-3-bromobenzaldehyde oxime-4-O-Methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.

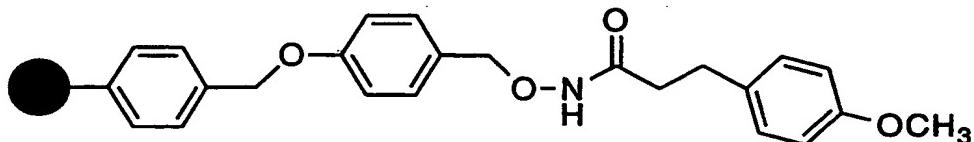


5

4-O-Methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (105 mg; 0.08 mmol) is swelled in dichloromethane (DCM)(@ mL) for 10 minutes. Trimethylorthoformate (1 mL) and 3-bromo-benzaldehyde (500 mg; 2.7 mmol; 34 equiv.) is added to the resin and the mixture is shaken 10 overnight. The slurry is then filtered, rinsed with dichloromethane (5 mL), DMF (5 mL x 3), H₂O (5 mL x 4), THF (5 mL x 10, and Et₂O (5 mL x 10). The resin is dried *in vacuo* at 40 °C for 12 hours. IR oxime stretch 1602 cm⁻¹. Elemental Analysis: calcd: Br, 5.52%; N, 1.04%. Found: Br, 5.76%; N, 1.08%.

15 Example 16

Preparation of N-3-(4-methoxyphenyl)propan-1-oyl-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.



20

4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (1 g, 0.73 mmol) is allowed to swell in DMF for 10 minutes and then is treated with 3-(4-methoxyphenyl)propionic acid (0.658 g, 3.65 mmol) and DIC (0.46 g, 3.65 mmol). The mixture is shaken for 24 hours, then filtered and the residue is washed with DMF, DMF/H₂O, DMF, THF and ET₂O, and dried under vacuum at 40 °C 25 to give N-3-(4-methoxyphenyl)propan-1-oyl-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin. IR: C=O 1698 cm⁻¹. Elemental Analysis: calcd: N, 1.02%. Found: N, 1.21%.

Example 17

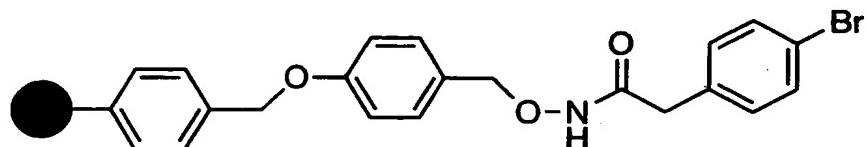
30 Preparation of N-hydroxy-3-(4-methoxyphenyl)propionamide.

N-hydroxy-3-(4-methoxyphenyl)propionamide is prepared by reaction of N-3-(4-methoxyphenyl)propan-1-oyl-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-

divinylbenzene)-resin with TFA using the procedure of Example 7. ^1H NMR 300MHz ($\text{CDCl}_3,\text{CD}_3\text{OD}$) δ 2.25 (t, 2H), 2.78 (t, 2H), 3.68 (s, 3H), 6.72 (d, 2H), 7.04 (d, 2H).

5 **Example 18**

Preparation of N-2-(4-bromophenyl)ethan-1-oyl-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.



10

The title resin is prepared using the method of Example 16, except substituting 4-bromophenylacetic acid for 3-(4-methoxyphenyl)propionic acid. IR C=O 1713.9 cm^{-1} . Elemental analysis: calcd: Br, 5.8%; N, 1.02%. Found: Br, 8.29%, 8.18%; N, 0.97%, 0.96%.

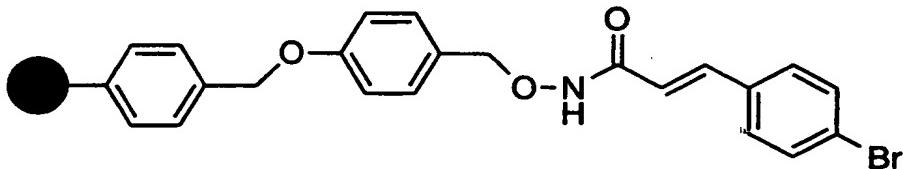
EDS: Net X-ray Counts

	K line	L line	M line
O:	969	1024	
C:	2662	3003	
Br:			12855 10436

20

Example 19

Preparation of N-4-bromocinnamoyl-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.



25

The title resin is prepared using the method of Example 16, except substituting 4-bromocinnamic acid for 3-(4-methoxyphenyl)propionic acid. IR:C=O 1671.7 cm^{-1} (broad). Elemental analysis: Calcd: Br, 5.8%; N, 1.02%. Found: Br, 4.45%, 4.54%.

30 **EDS: Net X-ray Count**

	K line	L line	M line
O:	818	1365	
C:	4549	5059	
Br:			6384 5271

Example 20

Preparation of N-hydroxy-4-bromocinnamamide.

5

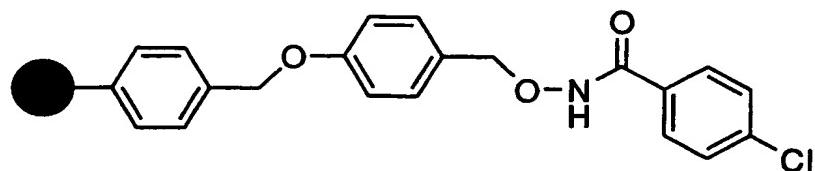
N-hydroxy-4-bromocinnamamide is prepared by treating N-4-bromocinnamoyl-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin with TFA using the procedure of Example 7. LC MS (H-ISP) m/z 241/243 Br [M⁺], Area = 84%; ¹H NMR (300 Mhz, CDCl₃/CD₃OD) δ: 3.23 (s, 1H), 6.35 (d, J= 15.8), 7.3 (d, J= 7.9), 7.4 (d, J= 7.9), 7.6 (d, J= 15.8).

10

Example 21

Preparation of N-(4-chlorobenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.

15



The title resin is prepared using the method of Example 16, except substituting 4-chlorobenzoic acid for 3-(4-methoxyphenyl)propionic acid. IR: C=O 1678 cm⁻¹. Elemental Analysis: calcd: Cl, 2.66%; N, 1.05%. Found: Cl, 2.39%; N, 1.02%.

Example 22

Preparation of N-Hydroxy-4-chlorobenzamide.

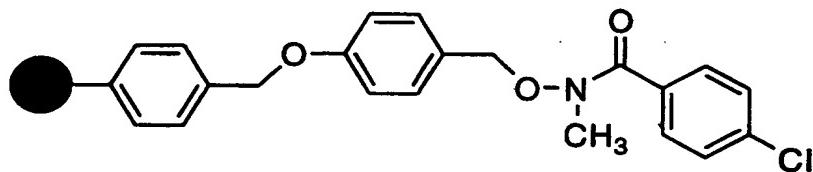
25

N-Hydroxy-4-chlorobenzamide is prepared by treating N-(4-chlorobenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin with TFA using the procedure of Example 7. LC MS (H-ISP) m/z 172,174 (Cl) [M+H]⁺, Area = 96%; ¹H NMR (300 Mhz, DMSO-d₆) δ 7.48 (d J = 9.42, 2H), 7.69 (d J = 9.42, 2H), 8.9-9.2 (broad, 1H), 11.28 (s, 1H).

30

Example 23

Preparation of N-methyl-N-(4-chlorobenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.



5

N-(4-chlorobenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin (0.1 g, 0.075 mmol, 0.75 mmol/g) is suspended in toluene (2 mL) and cooled to 5°C. The mixture is treated with methyl iodide (1.5 mmol, 0.21 g, 93µl) followed by DBU (0.22 mL, 0.228 g, 1.5 mmol). The reaction mixture is placed in a vortexer and allowed to warm to ambient temperature. Within a few minutes a copious white precipitate forms and the mixture is diluted further with toluene (2 mL). Agitation of the reaction mixture is continued for 18 hours. The N-methyl-N-(4-chlorobenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin is filtered and washed with DMF, DMF/H₂O, DMF, THF, Et₂O and dried *in vacuo* at 40°C.

15

Example 24

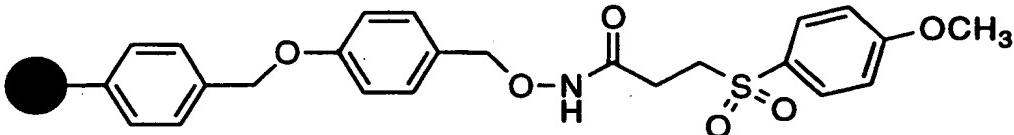
Preparation of 1-(4-chlorophenyl)propan-1-one.

N-methyl-N-(4-chlorobenzoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin is suspended in diethyl ether (0.7 mL) and treated with ethyl magnesium bromide (1.0 M in THF, 0.225 mL, 0.225 mmol). The reaction mixture is agitated for 18 hours on a wrist shaker and then quenched by the addition of 5% HCl in ethanol. Agitation is maintained for a further 30 minutes and the mixture is then filtered through a small plug of silica to remove the inorganic material. The filtrate is concentrated to afford 1-(4-chlorophenyl)propan-1-one. MS (EI-LRP) m/z 168/170 Cl [M⁺], 169/171 Cl [M+H]⁺; ¹H NMR (300Mhz, CDCl₃) δ 1.22 (t, 3H), 2.98 (q, 2H), 7.42 (d, 2H), 7.9 (d, 2H).

Example 25

Preparation of N-[3-((4-methoxyphenyl)sulfonyl)propan-1-oylcarbonyl]- 4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.

5



N-[3-((4-methoxyphenyl)sulfonyl)propan-1-oylcarbonyl]- 4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin is prepared using the method of Example 16, except substituting added 3-(4-methoxyphenylsulfonyl)propionic acid for 3-(4-methoxyphenyl)propionic acid. IR C=O 1691.6 cm⁻¹ (broad). Elemental Analysis: calcd: N, 1.02%; S, 2.34%. Found: N, 1.03%; S, 2.5%.

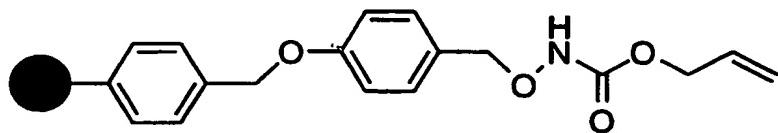
Example 26

15 Preparation of N-hydroxy-3-(4-methoxyphenylsulfonyl)propionamide.

N-hydroxy-3-(4-methoxyphenylsulfonyl)propionamide is prepared by treating N-[3-((4-methoxyphenyl)sulfonyl)propan-1-oylcarbonyl]- 4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin with TFA using the procedure of Example 7. ¹H NMR (300Mhz, DMSO-d₆) δ 2.25 (t, 2H), 3.42 (t, 2H) 3.85 (s, 3H), 7.13 (d, 2H), 7.79 (d, 2H); LC MS (Ion Spray) m/z 259 [M⁺], Area = 44%

Example 27

25 Preparation of N-allyloxycarbonyl-4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin.



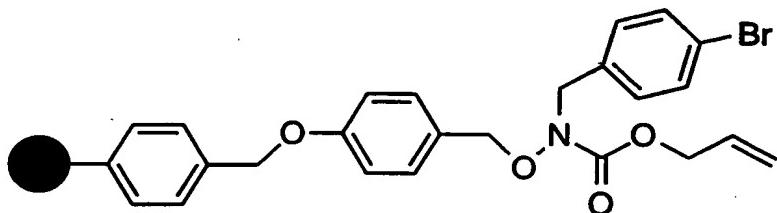
30 4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin (2 g, 2 mmoles) is suspended in 15 ml of dichloromethane and shaken on a wrist shaker for 10 minutes and 284 mg (383 ul, 2.2 mmoles) of diisopropylethyl amine is added. The mixture is shaken for 30 minutes. Allyl chloroformate (265 mg, 233ul, 2.2 mmoles) is added and the mixture is shaken overnight. The N-allyloxycarbonyl-4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin is washed with 15 ml of dichloromethane, THF (3x) and dichloromethane (3x) and dried *in vacuo*.

35

Example 28

Preparation of N-4-bromobenzyl-N-allyloxycarbonyl-4-(O-methylhydroxylamine)phenoxy methyl-copoly(styrene-1% divinylbenzene) resin.

5



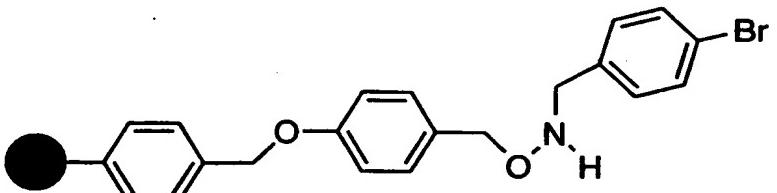
The N-allyloxycarbonyl-4-(O-methylhydroxylamine)phenoxy methyl-copoly(styrene-1% divinylbenzene) resin prepared in Example 27 is suspended in 15 mL of toluene. DBU (1,522 g, 1.5 mL, 10 mmoles) and 4-bromobenzyl bromide (2.5 g, 10 mmoles) are added and the mixture is shaken for 70 hours. The N-4-bromobenzyl-N-allyloxycarbonyl-4-(O-methylhydroxylamine)phenoxy methyl-copoly(styrene-1% divinylbenzene) resin is washed with 15 mL of DMF (3x), THF (3x) and dichloromethane (3x) and dried *in vacuo*.

15

Example 29

Preparation of N-4-bromobenzyl-4-(O-methylhydroxylamine)phenoxy methyl-copoly(styrene-1% divinylbenzene) resin.

20

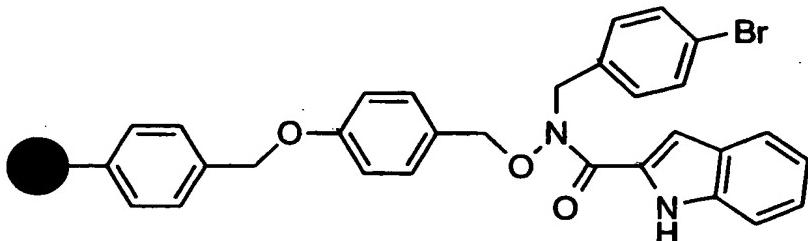


30

N-4-bromobenzyl, N-allyloxycarbonyl-4-(O-methylhydroxylamine)phenoxy methyl-copoly(styrene-1% divinylbenzene) resin, prepared as in Example 28, is swelled in 6 mL of THF, 6 mL of DMSO, 3 mL of 0.5 n HCl. Pd(PPh₃)₄ (347 mg, 15 weight %) is added and the mixture is shaken for 5 minutes. Morpholine (4.3 mL) is added and the mixture is shaken overnight. The reagents are drained off and the N-4-bromobenzyl-4-(O-methylhydroxylamine)phenoxy methyl-copoly(styrene-1% divinylbenzene) resin is washed with DMF (2x), THF (2x), dichloromethane (2x), 0.5 % diisopropylethyl amine in dichloromethane (3x), 0.5 % sodium diethyldithiocarbamate in DMF (3x), DMF (3x), THF (3x) and dichloromethane (3x) and dried *in vacuo* overnight.

Example 30

Preparation of N-(indol-2-ylcarbonyl)-N-4-bromobenzyl-4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin.



5

N-4-bromobenzyl-4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin (1.17 g, 1 mmole), prepared as in Example 29, is suspended in 15 ml of DMF. Indole-2-carboxylic acid (483 mg, 3 mmoles) and 575.1 mg (3 mmoles) of 1(3-dimethylaminopropyl)-3-diethylcarbodiimide hydrochloride are added and the mixture is shaken for 16 hours. The N-(indol-2-ylcarbonyl)-N-4-bromobenzyl-4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin is drained and washed with 15 ml of DMF (3x), THF/20% H₂O (3x), THF (3x), and dichloromethane (3x) and dried *in vacuo*.

15

Example 31

Preparation of Indole-2-carboxaldehyde.

Dry N-(indol-2-ylcarbonyl)-N-4-bromobenzyl-4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin is swelled in 12 mL of THF, shaken and cooled at 0°C for 30 minutes. LiAlH₄ (0.62 ml, 3 eq) is added and the mixture is shaken at 0°C for 30 minutes. Saturated KHSO₄ solution (0.5 mL) and 0.3 mL of potassium, sodium tartrate solution are added and the mixture is shaken for 30 minutes while warming to room temperature. Excess H₂O is dried by adding dry Na₂SO₄ and shaking for 15 minutes more. The mixture is filtered under low nitrogen pressure and washed 3 more times with 8 mL of dichloromethane followed by filtration. The filtrate is dried with Na₂SO₄ and filtered twice through a short bed (1 inch) of silica gel 60 for column chromatography (particle size 0.040-0.063 mm) and the solvent is removed *in vacuo* to give indole-2-carboxaldehyde. ¹H NMR (CDCl₃) δ 9.84 (1H,s), 9.22 (1H,brs), 7.75 (1H,d), 7.14-7.48 (4H,m); MS (EI): m/z = 146 [M+H⁺].

30

Example 32

Preparation of N-(*tert*-butoxycarbonyl)phenylalanine aldehyde.

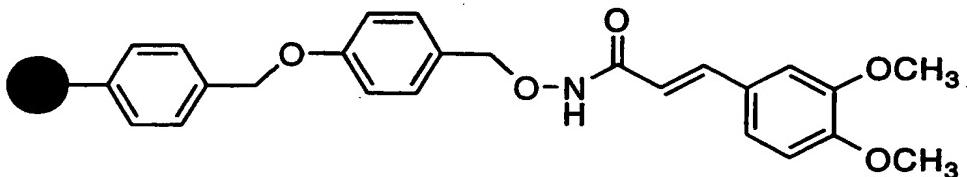
The desired compound is prepared according to the method of Examples 30 and 31, except substituting N-(*tert*-butoxycarbonyl)phenylalanine for indole-2-carboxaldehyde.

35

Example 33

Preparation of N-(3,4-dimethoxycinnamoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.

5



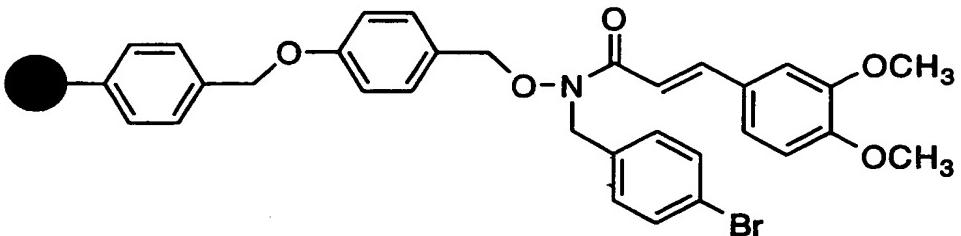
10 **4-O-Methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin resin (1g, 1 mmole) is washed with DMF (15 mL), then suspended in 15 mL of DMF and 624.6 mg (3 mmole, 3 x excess) of 3,4-dimethoxy cinnamic acid and 575.1 mg (3 mmoles, 3 x excess) of 1-(3-dimethylaminopropyl)-3-ethylcarbodiimide hydrochloride are added and the mixture is shaken for 16 hours. The resin is drained and washed with 15 mL of DMF (1x), THF/20% H₂O (3x), THF (3x), dichloromethane (3x) and dried under vacuum overnight.**

15

Example 34

Preparation of N-4-bromobenzyl-N-(3,4-dimethoxycinnamoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin.

20



25 **Dry N-(3,4-dimethoxycinnamoyl)-4-O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1%-divinylbenzene)-resin is shaken in 15 mL of toluene for 10 minutes, then 0.9 mL (6 mmoles, 6 x excess) of DBU is added and the mixture is shaken for 2 hours. p-Bromo benzyl bromide (1.5 g, 6 mmoles, 6 x excess) is added and the mixture is shaken for 3 days. The resin is dried overnight *in vacuo*.**

Example 35

Preparation of 3,4-dimethoxycinnamaldehyde.

Dry N-4-bromobenzyl-N-(3,4-dimethoxycinnamoyl)-4-O-methylhydroxylamine)phenoxyethyl-
5 copoly(styrene-1%-divinylbenzene)-resin is swelled in 12 mL of dry THF, shaken and cooled to 0°C for
30 minutes. LiAlH₄ in THF (0.5 mL, 2 equivalents) is added and the mixture is shaken at 0 °C for 30
minutes. Saturated aqueous KHSO₄ solution (0.5 mL) and potassium, sodium tartrate solution (0.3 mL)
are added and the mixture is shaken for 30 minutes while warming to ambient temperature. Excess H₂O
was dried by adding dry Na₂SO₄ and shaking for 15 minutes. The mixture is filtered under low nitrogen
10 pressure, washed 3 times with 8 mL of dichloromethane and filtered. The filtrate is further dried with
Na₂SO₄ and filtered through a short (1 inch) bed of silica gel 60 for column chromatography (particle size
0.040-0.063 mm) and the solvent is removed *in vacuo* to give 3,4-dimethoxycinnamaldehyde. ¹H NMR
(CDCl₃) δ 9.65 (1H,d), 7.40 (1H,d), 7.12 (1H,d), 7.06 (1H,s), 6.87 (1H,d), 6.60 (1H,dd), 3.90 (6H,s); MS
(EI): m/z = 193 [M+H⁺].

15

Examples 36-43

The compounds of Examples 36-43 are prepared from the desired carboxylic acid starting material using the procedures of Examples 33-35.

20

Example 36

Preparation of anthranilic aldehyde.

25 ¹H NMR (CDCl₃) δ 9.88 (1H,s), 7.52-7.58 (1H,d), 7.11-7.38 (7H,m), 6.81 (1H,t); MS (EI): m/z =
198 [M+H⁺].

Example 37

30 Preparation of 2-bibenzylid aldehyde.

¹H NMR (CDCl₃) δ 10.18 (1H,s), 7.83 (1H,d), 7.14-7.52 (8H,m), 3.30 (2H,t), 2.87 (2H,t); MS
(EI): m/z = 211 [M+H⁺].

35

Example 38

Preparation of 4-methoxy-2-quinoline aldehyde.

¹H NMR (CDCl₃) δ 10.17 (1H,s), 8.27 (1H,d), 8.18 (1H,d), 7.78 (1H,t), 7.62 (1H,t), 7.38 (1H,s),
40 4.12 (3H,s); MS (EI): m/z = 188 [M+H⁺]

Example 39**Preparation of 3-acetamido benzaldehyde.**

5 ¹H NMR (CDCl₃) δ 9.98 (1H,s), 7.97 (1H,s), 7.86 (1H,d), 7.62 (1H,d), 7.48 (1H,t), 2.21 (3H,s).
MS (EI): m/z = 164 [M+H⁺].

Example 40**10 Preparation of 4-(4-N-propylphenyl) benzaldehyde.**

15 ¹H NMR (CDCl₃) δ 10.02 (1H,s), 7.92 (2H,d), 7.72 (2H,d), 7.53 (2H,d), 7.26 (2H,d), 2.65 (2H,t),
1.68 (2H, dt), 0.95 (3H,t); MS (EI): m/z = 225 [M+H⁺].

15

Example 41**Preparation of 3-quinoline aldehyde.**

20 ¹H NMR (CDCl₃) δ 10.26 (1H,s), 9.38 (1H,s), 8.64 (1H,s), 8.20 (1H,d), 7.98 (1H,t), 7.89 (1H,t),
7.65 (1H,t); MS (EI): m/z = 158 [M+H⁺].

Example 42**Preparation of 3-(3,4-methylenedioxy) propionaldehyde.**

25 ¹H NMR (CDCl₃) δ 9.80 (1H,s), 7.60-7.74 (3H,m), 5.92 (2H,s), 2.88 (2H,t), 2.74 (2H,t); MS (EI):
m/z = 179 [M+H⁺].

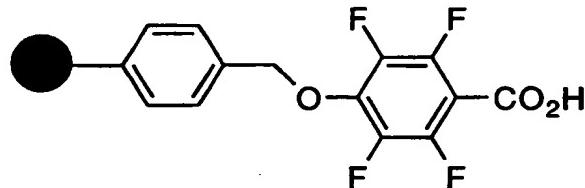
30 **Example 43****Preparation of 2-phenyl-4-quinoline aldehyde.**

35 ¹H NMR (CDCl₃) δ 10.58 (1H,s), 9.00 (1H,d) 8.19-8.30 (4H,m), 7.82 (1H,t), 7.70 (1H,t), 7.47-
7.59 (3H,m); MS (EI): m/z = 234 [M+H⁺].

35

Example 44

Preparation of 4-carboxy-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-1% divinylbenzene) resin.



5

Merrifield resin (2 mmol/g, 600 mg, 1.2 mmol) is swelled in anhydrous DMF (20 mL). 2,3,5,6-tetrafluoro-4-hydroxy benzoic acid hydrate (2.28 g, 10 mmol) and cesium carbonate (3.26 g, 10 mmol) are added and the reaction mixture is heated at 85 °C for 12 hours with gentle agitation. The reaction mixture is filtered and the 4-carboxy-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-1% divinylbenzene) resin is washed with DMF (5x), 20% aqueous DMF (5x), THF (5x) and dichloromethane and dried overnight in vacuo. IR (microscope, cm-1): 1640 (C=O); ¹⁹F NMR (nanoprobe) -144.4 ppm, -160.2 ppm.

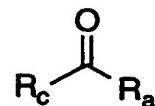
EDS

15

The energy dispersive x-ray measurements are made with an Electroscan Scanning Electron Microscope with an attached PGT digital detector. The beads are mounted on aluminum stubs and tested without a conductive coating. The net x-ray counts are reported after correction for the background. No corrections are made for atomic number, fluorescence or absorption.

What is claimed is:

1. A process for the preparation of a ketone compound of formula



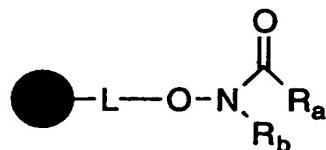
5

wherein

R_c and R_a are independently aliphatic or aromatic

10 comprising

- (a) reacting an N-alkylated polymeric hydroxamic acid resin compound of formula



15

wherein

is a solid support, L is absent or a linking group and R_a and R_b are independently aliphatic or aryl,

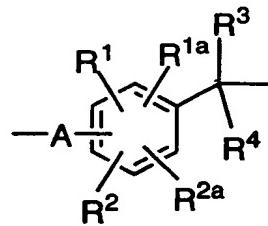
20 with an organometallic reagent of formula R_cM wherein R_c is an aliphatic or aryl anion and M is a metal cation; and

- (b) liberating the ketone compound from the resin.

25 2. The process of claim 1 wherein M is Li or MgX wherein X is Br or Cl.

3. The process of claim 2 wherein L is a linking group.

4. The process of claim 3 wherein L is a linking group of formula



5 wherein

A is absent or a group of formula -X¹-Z- wherein

X¹ is -CHR- or -CHR-Y-CO-(CH₂)_n- wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or -NO₂,

Y is -O- or -NH-,

10 n is an integer from 1 to 6, and

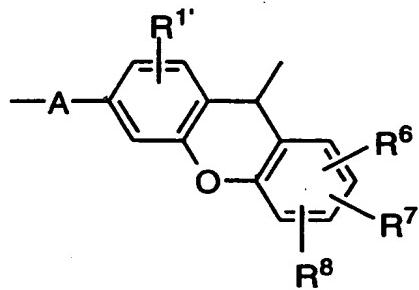
Z is -O- or -NH-;

R¹, R^{1a}, R², and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

15 R³ and R⁴ are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and -NO₂;

or one of R¹ and R² taken together with one of R³ and R⁴ and the carbon atoms to which they are attached define a linking group of formula

20



wherein

R^{1'} is -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

25 R⁶, R⁷ and R⁸ are independently selected from -H, alkyl, alkoxy, halogen, nitrile or -NO₂.

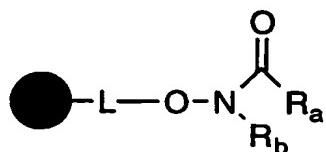
5. The process of claim 4 wherein R_b is alkyl, benzyl or substituted benzyl.

6. A process for the preparation of an aldehyde compound of formula $R_a\text{CHO}$ wherein R_a is aliphatic or aryl,

comprising

5

(a) reacting an N-alkylated polymeric hydroxamic acid resin compound of formula



10 wherein [REDACTED] is a solid support, L is absent or a linking group and R_a and R_b are independently aliphatic or aryl;

with a reducing agent; and

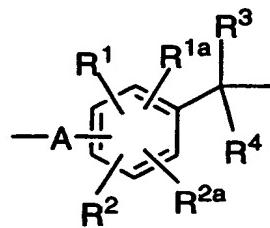
15 (b) liberating the aldehyde compound from the resin.

7. The process of claim 6 wherein the reducing agent is a hydride reducing agent.

8. The process of claim 7 wherein L is a linking group.

20

9. The process of claim 8 wherein L is a linking group of formula



25 wherein

A is absent or a group of formula $-X^1-Z-$ wherein

X^1 is $-\text{CHR}-$ or $-\text{CHR}-Y-\text{CO}-(\text{CH}_2)_n-$ wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or $-\text{NO}_2$,

Y is $-\text{O}-$ or $-\text{NH}-$,

30 n is an integer from 1 to 6, and

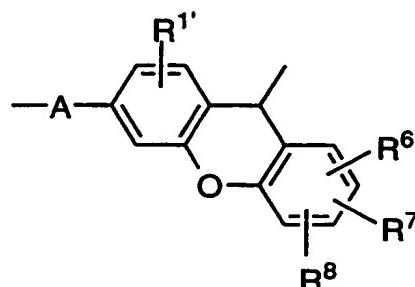
Z is $-\text{O}-$ or $-\text{NH}-$;

R^1 , R^{1a} , R^2 , and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$; and

R^3 and R^4 are independently -H, alkyl, phenyl, or phenyl substituted with one or more

5 substituents selected from alkyl, alkoxy, halogen nitrile and $-NO_2$;

or one of R^1 and R^2 taken together with one of R^3 and R^4 and the carbon atoms to which they are attached define a linking group of formula



10

wherein

R^1 is -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$; and

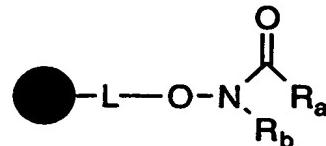
R^6 , R^7 and R^8 are independently selected from -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$.

15

10. The process of claim 8 wherein R_b is alkyl, benzyl or substituted benzyl.

11. A process for the preparation of a N-alkylated polymeric hydroxamic acid resin compound of formula

20



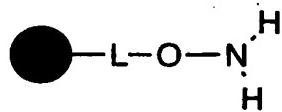
wherein

is a solid support, L is absent or a linking group and R_a and R_b are independently aliphatic

25 or aryl;

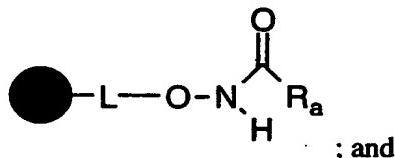
comprising

(a) coupling a carboxylic acid compound of formula R_aCO_2H with a polymeric hydroxylamine resin
30 compound of formula



to form a polymeric hydroxamic acid resin compound of formula

5

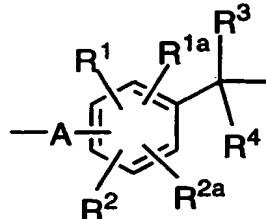


- (b) reacting the polymeric hydroxamic acid resin compound with an alkylating agent of formula R_bLG wherein LG is a leaving group.

10

12. The process of claim 11 wherein L is a linking group.

13. The process of claim 12 wherein L is a linking group of formula



15

wherein

A is absent or a group of formula -X¹-Z- wherein

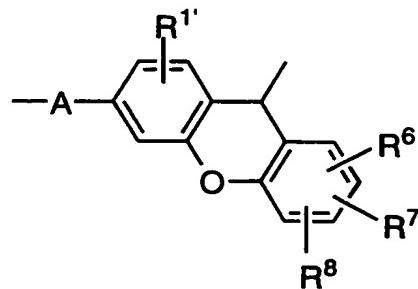
- X¹ is -CHR- or -CHR-Y-CO-(CH₂)_n- wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or -NO₂,

Y is -O- or -NH-,

n is an integer from 1 to 6, and

Z is -O- or -NH-;

- 25 R¹, R^{1a}, R², and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and
R³ and R⁴ are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and -NO₂;
- 30 or one of R¹ and R² taken together with one of R³ and R⁴ and the carbon atoms to which they are attached define a linking group of formula

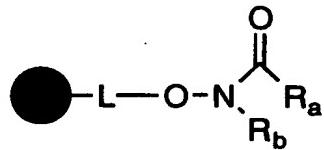


wherein

- 5 R^{1'} is -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and
 R⁶, R⁷ and R⁸ are independently selected from -H, alkyl, alkoxy, halogen, nitrile or -NO₂.

14. The process of claim 13 wherein R_b is alkyl, benzyl or substituted benzyl.
- 10 15. The process of claim 11 wherein the polymeric hydroxylamine resin compound is 4-(O-methylhydroxylamine)phenoxy methyl-copoly(styrene-1% divinylbenzene) resin, 4-[4-(O-methylhydroxylamine)-3-methoxyphenoxy]-(N-4-methylbenzhydryl)-butyramide-copoly(styrene-1%-divinylbenzene)-resin, 4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-phenoxy methyl-copoly(styrene-1% divinylbenzene) resin, 4-[4-(1-aminoxyethyl)-2-methoxy-5-nitrophenoxy]-(N-4-methylbenzhydryl)-butyramide-copoly(styrene-1% divinylbenzene) resin, O-hydroxylamine-2'-chlorotriyl-copolystyrene-1%-divinylbenzene-resin, O-hydroxylamine-trityl-copolystyrene-1%-divinylbenzene-resin,
- 15 20. 5-(4-O-methylhydroxylamine -3,5-dimethoxyphenoxy)-valeric acid-copolystyrene-1%-divinyl benzene resin, 4-(O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxy methyl-copoly(styrene-1% divinylbenzene) resin, 4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxy methyl-copoly(styrene-1% divinylbenzene) resin,
- 25 25. 4-O-methylhydroxylamine-3-methoxyphenoxy-copolystyrene-1%-divinyl benzene resin, or 3-hydroxy-xanthydrolamine-copolystyrene-1%-divinylbenzene resin.
16. The process of claim 11 wherein the polymeric hydroxylamine resin compound is 4-(O-methylhydroxylamine)phenoxy methyl-copoly(styrene-1% divinylbenzene) resin, or
- 30 30. 4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-phenoxy methyl-copoly(styrene-1% divinylbenzene) resin.

17. A process for the preparation of a N-alkylated polymeric hydroxamic acid resin compound of formula



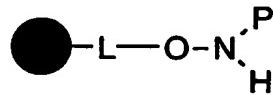
5

wherein

is a solid support, L is absent or a linking group and R_a and R_b are independently aliphatic or aryl;

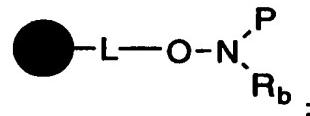
10 comprising

(a) reacting a N-protected polymeric hydroxamic acid resin compound of formula



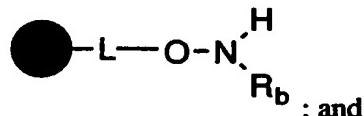
15

wherein P is an amine protecting group, with an alkylating agent of formula R_bLG wherein LG is a leaving group, to form a polymeric N-protected N-alkylated hydroxylamine resin compound of formula



20

(b) removing the amine protecting group to form a polymeric N-alkylated hydroxylamine resin compound of formula

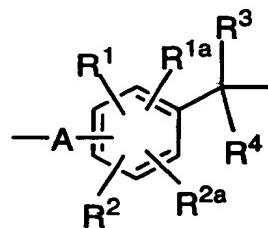


25

(c) coupling the polymeric N-alkylated hydroxylamine resin compound with a carboxylic acid compound of formula R_aCO₂H.

18. The of claim 17 wherein L is a linking group.

19. The process of claim 18 wherein L is a linking group of formula



5

wherein

A is absent or a group of formula -X¹-Z- wherein

X¹ is -CHR- or -CHR-Y-CO-(CH₂)_n- wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or -NO₂,

10

Y is -O- or -NH-,

n is an integer from 1 to 6, and

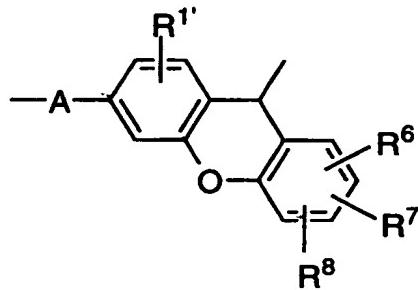
Z is -O- or -NH-;

15

R¹, R^{1a}, R², and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

R³ and R⁴ are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and -NO₂;

20 or one of R¹ and R² taken together with one of R³ and R⁴ and the carbon atoms to which they are attached define a linking group of formula



wherein

25 R^{1'} is -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and
R⁶, R⁷ and R⁸ are independently selected from -H, alkyl, alkoxy, halogen, nitrile or -NO₂.

20. The process of claim 19 wherein R_b is alkyl, benzyl or substituted benzyl.

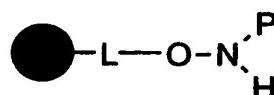
21. The process of claim 17 wherein P is allyloxycarbonyl, benzyloxycarbonyl, p-methoxybenzyloxycarbonyl, p-nitrobenzyloxycarbonyl, trimethylsilylethoxycarbonyl, 2,4-dimethoxybenzyloxycarbonyl, o-nitrobenzyloxycarbonyl, o-nitrobenzylsulfonyl, p-nitrobenzylsulfonyl, and 2-nitro-4-trifluoromethylbenzenesulfonyl.

5

22. The process of claim 21 wherein P is allyloxycarbonyl.

23. A polymeric N-protected hydroxylamine resin compound of formula

10



wherein

is a solid support;

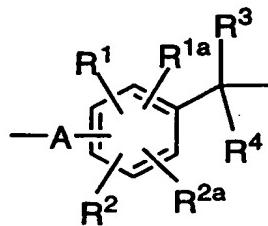
L is absent or a linking group; and

15 P is an amine protecting group, provided that P is other than 4-methoxybenzyl or 2,4-dimethoxybenzyl.

24. A polymeric N-protected hydroxylamine resin compound according to claim 23 wherein L is a linking group.

20

25. A polymeric N-protected hydroxylamine resin compound according to claim 24 wherein L is a linking group of formula



25

wherein

A is absent or a group of formula -X¹-Z- wherein

30 X¹ is -CHR- or -CHR-Y-CO-(CH₂)_n- wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or -NO₂,

Y is -O- or -NH-,

n is an integer from 1 to 6, and

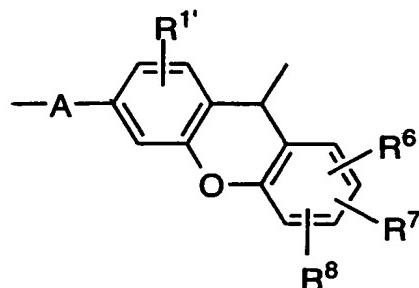
Z is -O- or -NH-;

R^1 , R^{1a} , R^2 , and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$; and

R^3 and R^4 are independently -H, alkyl, phenyl, or phenyl substituted with one or more

5 substituents selected from alkyl, alkoxy, halogen nitrile and $-NO_2$;

or one of R^1 and R^2 taken together with one of R^3 and R^4 and the carbon atoms to which they are attached define a linking group of formula



10

wherein

R^1 is -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$; and

R^6 , R^7 and R^8 are independently selected from -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$.

15

26. A polymeric N-protected hydroxylamine resin compound according to claim 25 wherein P is allyloxycarbonyl, benzyloxycarbonyl, p-methoxybenzyloxycarbonyl, p-nitrobenzyloxycarbonyl, trimethylsilylethoxycarbonyl, 2,4-dimethoxybenzyloxycarbonyl, o-nitrobenzyloxycarbonyl, o-nitrobenzylsulfonyl, p-nitrobenzylsulfonyl, and 2-nitro-4-trifluoromethylbenzenesulfonyl.

20

27. A polymeric N-protected hydroxylamine resin compound according to claim 26 wherein P is allyloxycarbonyl.

25

28. A polymeric N-protected hydroxylamine resin compound according to claim 27 which is N-allyloxycarbonyl-4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin,

N-allyloxycarbonyl-4-[4-(O-methylhydroxylamine)-3-methoxyphenoxy]-(N-4-methylbenzhydryl)-butyramide-copoly(styrene-1%-divinylbenzene)-resin,

30

N-allyloxycarbonyl-4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-phenoxyethyl-copoly(styrene-1% divinylbenzene) resin,

N-allyloxycarbonyl-4-[4-(1-aminoxyethyl)-2-methoxy-5-nitrophenoxy]-(N-4-methylbenzhydryl)-butyramide-copoly(styrene-1% divinylbenzene) resin,

N-allyloxycarbonyl-O-hydroxylamine-2'-chlorotriyl-copolystyrene-1%-divinylbenzene-resin,

N-allyloxycarbonyl-O-hydroxylamine-trityl-copolystyrene-1%-divinylbenzene-resin,

N-allyloxycarbonyl-5-(4-O-methylhydroxylamine -3,5-dimethoxyphenoxy)-valeric acid-copolystyrene-1%-divinyl benzene resin,

N-allyloxycarbonyl-4-(O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-1% divinylbenzene) resin,

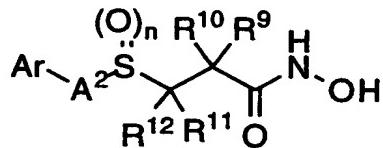
5 N-allyloxycarbonyl-4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-1% divinylbenzene) resin,

N-allyloxycarbonyl-4-O-methylhydroxylamine-3-methoxyphenoxy-copolystyrene-1%-divinyl benzene resin, or

N-allyloxycarbonyl-3-hydroxy-xanthydrolamine-copolystryene-1%-divinylbenzene resin.

10 29. A polymeric N-protected hydroxylamine resin compound according to claim 27 which is N-allyloxycarbonyl-4-(O-methylhydroxylamine)phenoxyethyl-copoly(styrene-1% divinylbenzene) resin.

15 30. A process for preparing a hydroxamic acid compound of formula



wherein

20 A^2 is a direct bond or an alkylene, or NR¹³ wherein R¹³ is hydrogen or alkyl;

R^9 is a group of formula -L¹-R¹⁴, where L¹ represents a direct bond or a straight- or branched C₁₋₆alkylene chain optionally substituted by alkoxy, aryl, carboxy, cyano, cycloalkyl, halogen,

25 heteroaryl, hydroxyl, or oxo, and R¹⁴ is hydrogen, aryl, carboxy, cyano, cycloalkyl, cycloalkenyl, cyclocarbamoyl, cycloimidyl, heterocycloalkyl, heteroaryl, -NH-C(=O)-NH₂, (N-carbamoyl)cyclic amine, -C=N-O-C(=O)-NH₂, -C(=O)-NY¹Y² [where Y¹ and Y² are independently hydrogen, alkyl, arylalkyl, and aryl, or the substituent Y¹Y²N- forms a 4-6 membered cyclic amine which optionally contains an additional heteroatom selected from O, S, NH or NR¹³], -NY¹SO₂aryl, -NHR¹³, -SR¹³ or

30 -OR¹³; or a group L²-R¹⁵ where L² represents a straight- or branched-carbon chain comprising from 2 to about 6 carbon atoms, optionally substituted with carboxy or cyano, which contains a double or triple carbon-carbon bond, or is interrupted by an oxygen or sulfur atom, a phenylene, imino (-NH-) or alkylimino linkage, or a sulfinyl or sulfonyl group, and R¹⁵ is hydrogen, aryl, carboxy, cyano, cycloalkyl, cycloalkenyl, heterocycloalkyl or heteroaryl; or R⁹ and R¹⁰ taken together with the atom to which th y

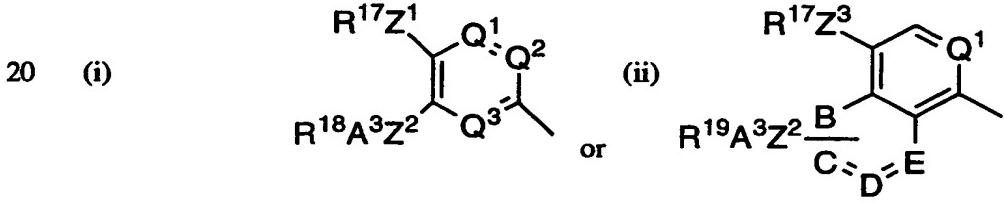
are attached form a ring; or R⁹ and R¹¹ taken together with the atoms through which they are attached form a ring;

R¹⁰ and R¹² are independently hydrogen or alkyl;

- 5 or R¹⁰ and R¹² together form a bond;

R¹¹ represents a group -L³-R¹⁶ where L³ represents a direct bond or a straight- or branched C₁-6alkylene chain optionally substituted by alkoxy, aryl, carboxy, cyano, cycloalkyl, halogen, heteroaryl, hydroxyl, or oxo; or L³ represents a straight- or branched-carbon chain comprising from 2 to about 6 carbon atoms which contains a double or triple carbon-carbon bond, or is interrupted by an oxygen or sulfur atom, a phenylene, imino (-NH-) or alkylimino linkage, or a sulfinyl or sulfonyl group; and R¹⁶ is hydrogen, aryl, cycloalkyl, cycloalkenyl, cyclocarbamoyl, cycloimidyl, heterocycloalkyl, heteroaryl, -NH-C(=O)-NH₂, (N-carbamoyl)cyclic amine, -C=N-O-C(=O)-NH₂, -C(=O)-NY¹Y² [where Y¹ and Y² are independently hydrogen, alkyl, arylalkyl, and aryl, or the substituent Y¹Y²N- forms a 4-6 membered cyclic amine which optionally contains an additional heteroatom selected from O, S, NH or NR¹³], -NY¹SO₂aryl, or R¹¹ and R⁹ together with the atoms to which they are attached form a ring; or R¹¹ and R¹² together with the atom to which they are attached form a ring;

Ar is a group chosen from:



where R¹⁷ is a straight- or branched-chain alkyl group of 1 to about 6 carbon atoms, optionally substituted by one or more halogen atoms, or when Z³ is a direct bond R¹⁷ may also represent a hydrogen atom, alkenyl or alkynyl group;

25 R¹⁸ represents an optionally substituted cycloalkyl, cycloalkenyl, heterocycloalkyl, aryl, partially saturated bicycloaryl or heteroaryl group;
 R¹⁹ represents R²⁰, -OR²⁰, -SR²⁰, -SOR²⁰, -SO₂R²⁰, -SO₂NR²⁰R²¹, -NR²⁰SO₂R²¹, -NR²⁰R²¹, -O(C=O)NR²⁰R²¹, -NR²⁰C(=O)R²¹, -N(OH)C(=O)R²⁰, or -C(=O)N(OH)R²¹, where R²⁰ and R²¹, which may be the same or different, each represent a hydrogen atom, or an alkyl, alkenyl, heterocycloalkyl, cycloalkyl, cycloalkenyl, aryl, heteroaryl, arylalkyl or heteroarylalkyl group, or the group NR²⁰R²¹ represents a 5 to 7 membered cyclic amine optionally containing one or more additional heteroatom selected from O, N, or S), wherein where R¹⁸ represents a substituted cycloalkyl-group, the cycloalkyl group is substituted by one or more (e.g. 1, 2 or 3) substituents chosen from OR²³, SR²⁴,

SOR²⁴, SO₂R²⁴, NH₂, NR¹³R²⁴, =NOR²⁴, =NOH, =NNHR²⁴, =NOCONHR²⁴, =NCO₂R²⁴, SOR²⁴, NHCOR²⁴, NSO₂R²⁴, SO₂NR¹³R²⁴, R²³, CONHR²⁴, CONHCH₂CO₂R¹³, CONR²⁴R¹³, or N₃; wherein R²³ is hydrogen, alkyl, cycloalkyl, aryl, arylalkyl, heteroaryl or heteroarylalkyl; R²⁴ is alkyl, cycloalkyl, cycloalkenyl, heterocycloalkyl, aryl, arylalkyl, heteroaryl or heteroarylalkyl; or the substituent

- 5 NR¹³R²⁴ forms a 4-7 membered cyclic amine which optionally contains an additional heteroatom selected from O, S, NH or NR¹³, and wherein R¹⁸ represents a substituted heterocycloalkyl group containing a nitrogen atom the ring is substituted on one or more (e.g. 1, 2 or 3) of the ring carbon atoms and the substituents are chosen from oxo, cyano, CO₂R¹³, CONHCH₂CO₂R¹³, aryl, arylalkyl, alkyl or hydroxyalkyl, and/or is substituted on the ring nitrogen atom and the substituent is chosen from R¹³,
- 10 (CH₂)_nCO₂H, (CH₂)_nCO₂R²⁴, (CH₂)_nCONR¹³R²⁴, (CH₂)_nCOR²⁴, CONH₂, CONHR²⁴, COR²⁴, SO₂R²⁴, or OR²⁴;

A³ represents a direct bond, a straight- or branched C₁₋₆alkylene chain optionally substituted by halogen, hydroxyl, alkoxy, oxo, cycloalkyl, aryl or heteroaryl; or A³ represents a straight- or branched-
15 carbon chain comprising from 2 to about 6 carbon atoms which contains a double or triple carbon-carbon bond, or is interrupted by an oxygen or sulfur atom, a phenylene, imino (-NH-) or alkylimino linkage, or a sulfinyl or sulfonyl group,

Z¹ and Z³ each represents an oxygen or sulfur atom, a direct bond or NH;

20 Z² represents an oxygen or sulfur atom, or a direct bond;

B, C, D, and E independently represent a carbon or heteroatom selected from O, S, N, NOR²² or NR²² where R²² is hydrogen or a C₁₋₄straight- or branched-chain alkyl, aryl, arylC₁₋₄alkyl, heteroaryl or
25 heteroarylC₁₋₄alkyl group, or three of B, C, D or E represent a carbon or heteroatom selected from O, N, NR²², or S and the other represents a direct bond; but excluding compounds where two O or S atoms are in adjacent positions, and the bonds joining B, C, D and E may be single or double bonds;

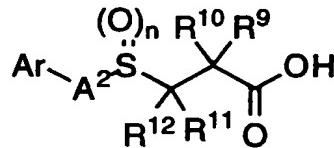
30 Q¹, Q² and Q³, which may be the same or different, each represents a CH or CX¹ linkage or a nitrogen atom; and X¹ represents a halogen atom; and

n is 0, 1 or 2; or

35 an N-oxide thereof, prodrug thereof, acid isostere thereof, pharmaceutically acceptable salt thereof, or solvate thereof,

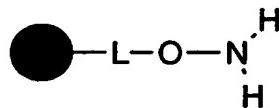
comprising

- (a) coupling a carboxylic acid compound of formula



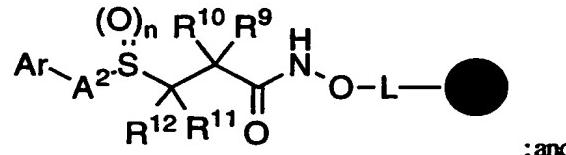
5

to a polymeric hydroxylamine resin compound of formula



10

to form a polymeric hydroxamic resin compound of formula

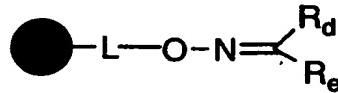


- 15 (b) treating the polymeric hydroxamic acid resin compound with acid.

31. The process of claim 31 wherein the acid is trifluoroacetic acid.

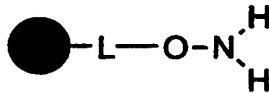
32. A process for the preparation of a polymeric oxime ether resin compound of formula

20

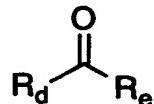


wherein \bullet is a solid support, L is absent or a linking group and R_d and R_e are independently H, aliphatic or aromatic, comprising reacting a polymeric hydroxylamine resin compound of formula

25



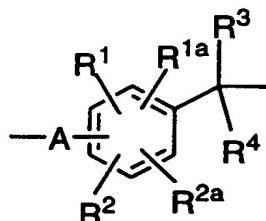
wherein R_d is a solid support and L is absent or a linking group, with a carbonyl compound of formula



5

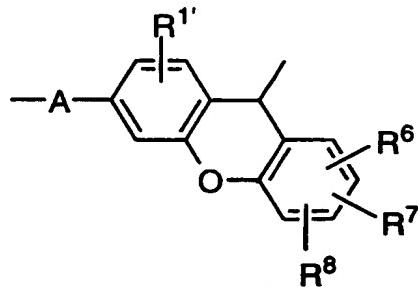
33. The process of claim 32 wherein L is a linking group.
34. The process of claim 33 wherein L is a linking group of formula

10



wherein

- A is absent or a group of formula $-X^1-Z-$ wherein
 X^1 is $-\text{CHR}-$ or $-\text{CHR-Y-CO-(CH}_2\text{)}_n-$ wherein R is H, alkyl, phenyl, or phenyl substituted with -H,
15 alkyl, alkoxy, halogen, nitrile or $-\text{NO}_2$,
Y is $-\text{O-}$ or $-\text{NH-}$,
n is an integer from 1 to 6, and
Z is $-\text{O-}$ or $-\text{NH-}$;
- 20 R^1 , R^{1a} , R^2 , and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or $-\text{NO}_2$; and
 R^3 and R^4 are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and $-\text{NO}_2$;
- 25 or one of R^1 and R^2 taken together with one of R^3 and R^4 and the carbon atoms to which they are attached define a linking group of formula

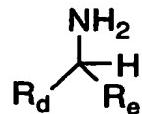


wherein

R^{1'} is -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

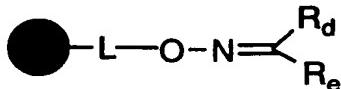
5 R⁶, R⁷ and R⁸ are independently selected from -H, alkyl, alkoxy, halogen, nitrile or -NO₂.

35. A process for the preparation of an α -amine compound of formula



10

wherein R_d and R_e are independently H, aliphatic or aryl, provided that R_d and R_e are not both H, comprising reductively cleaving the α -amine compound from a polymeric oxime ether resin compound of formula



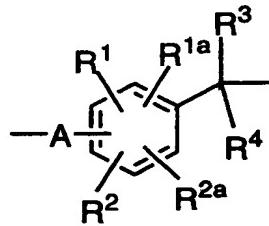
15

wherein [REDACTED] is a solid support and L is absent or a linking group.

36. The process of claim 35 wherein L is a linking group.

20

37. The process of claim 36 wherein L is a linking group of formula



wherein

A is absent or a group of formula -X¹-Z- wherein

X¹ is -CHR- or -CHR-Y-CO-(CH₂)_n- wherein R is H, alkyl, phenyl, or phenyl substituted with -H,

5 alkyl, alkoxy, halogen, nitrile or -NO₂,

Y is -O- or -NH-,

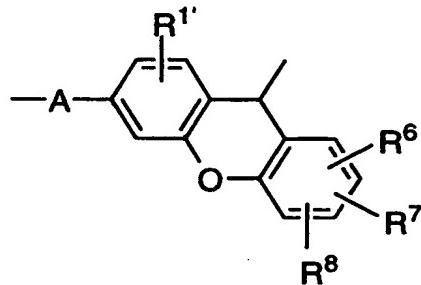
n is an integer from 1 to 6, and

Z is -O- or -NH-;

10 R¹, R^{1a}, R², and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

R³ and R⁴ are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and -NO₂;

15 or one of R¹ and R² taken together with one of R³ and R⁴ and the carbon atoms to which they are attached define a linking group of formula



20 wherein

R^{1'} is -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

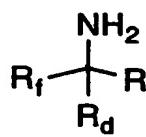
R⁶, R⁷ and R⁸ are independently selected from -H, alkyl, alkoxy, halogen, nitrile or -NO₂.

38. The process of claim 37 wherein the reductive cleavage is accomplished using a hydride reducing

25 agent.

39. The process of claim 38 wherein the reductive cleavage is accomplished by sequential treatment of the polymeric oxime ether resin compound with NaBH₃CN and LiAlH₄.

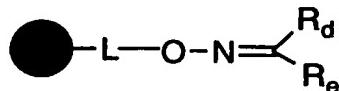
30 40. A process for the preparation of a substituted α -amine compound of formula



wherein R_d and R_e are independently H, aliphatic or aromatic, provided that R_d and R_e are not both H, and R_f is aliphatic or aromatic,

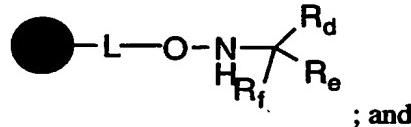
5 comprising

- (a) reacting a polymeric oxime ether compound of formula



10

wherein \bullet is a solid support, L is absent or a linking group, with an organometallic reagent of formula $R_f M$ wherein R_f is an aliphatic or aromatic anion and M is a metal cation, to form a polymeric α -substituted hydroxylamine resin compound of formula



15 ; and

- (b) reductively cleaving the α -substituted hydroxylamine resin compound.

41. The process of claim 40 wherein M is Li or MgX wherein X is Br or Cl.

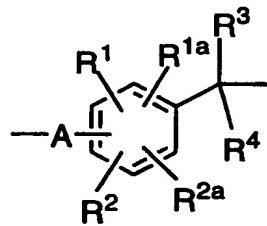
20

42. The process of claim 41 wherein the reductive cleavage is accomplished using a hydride base.

43. The process of claim 42 wherein the hydride base is $BH_3 \cdot THF$ or $LiAlH_4$.

25 44. The process of claim 43 wherein L is a linking group.

45. The process of claim 44 wherein L is a linking group of formula



30

wherein

A is absent or a group of formula -X¹-Z- wherein

X¹ is -CHR- or -CHR-Y-CO-(CH₂)_n- wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or -NO₂,

5 Y is -O- or -NH-,

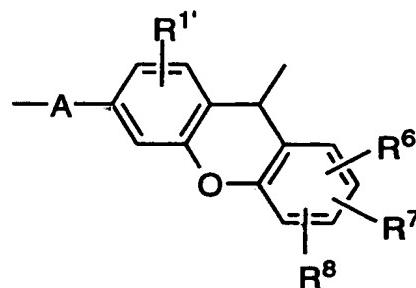
n is an integer from 1 to 6, and

Z is -O- or -NH-;

10 R¹, R^{1a}, R², and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

R³ and R⁴ are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and -NO₂;

15 or one of R¹ and R² taken together with one of R³ and R⁴ and the carbon atoms to which they are attached define a linking group of formula

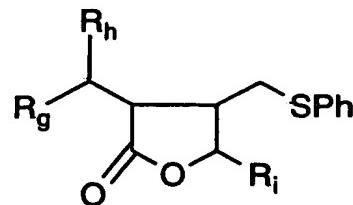


wherein

20 R¹ is -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

R⁶, R⁷ and R⁸ are independently selected from -H, alkyl, alkoxy, halogen, nitrile or -NO₂.

46. A process for the preparation of a lactone compound of formula



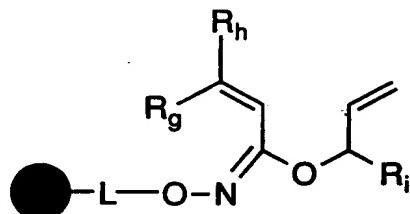
25

wherein R_g, R_h and R_i are aliphatic or aromatic and Ph is phenyl,

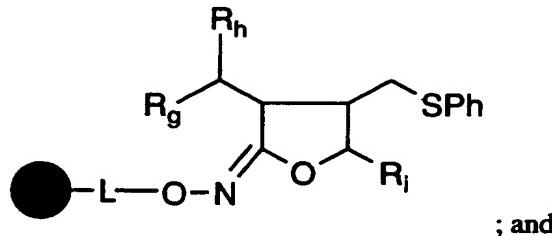
comprising

30

(a) treating an α,β -unsaturated polymeric hydroxamic acid ester resin compound of formula



5 wherein [REDACTED] is a solid support, L is absent or a linking group, with thiophenol and a radical initiator to form a polymeric oximyl lactone compound of formula



; and

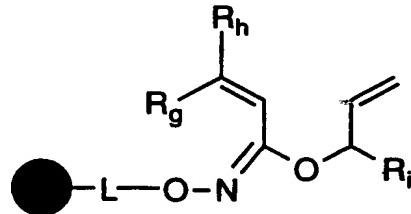
10 (b) treating the polymeric oximyl lactone compound with aqueous acid.

47. The process of claim 46 wherein the radical initiator is 2,2'-azobisisobutyronitrile.

48. The process of claim 47 wherein the aqueous acid is aqueous HCl.

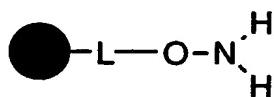
15

49. The process of claim 46 wherein the α,β -unsaturated polymeric hydroxamic acid-ester resin compound of formula

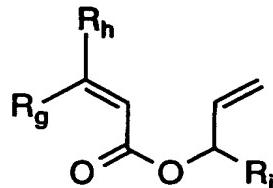


20

wherein [REDACTED], L and Rg and Rh and Ri are defined therein is prepared by reacting a polymeric hydroxylamine resin compound of formula



with an α,β -unsaturated carboxylic acid ester compound of formula

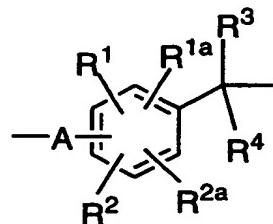


5

50. The process of claim 49 wherein L is a linking group.

51. The process of claim 50 wherein L is a linking group of formula

10



wherein

A is absent or a group of formula $-X^1-Z-$ wherein

15 X^1 is $-CHR-$ or $-CHR-Y-CO-(CH_2)_n-$ wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$,

Y is $-O-$ or $-NH-$,

n is an integer from 1 to 6, and

Z is $-O-$ or $-NH-$;

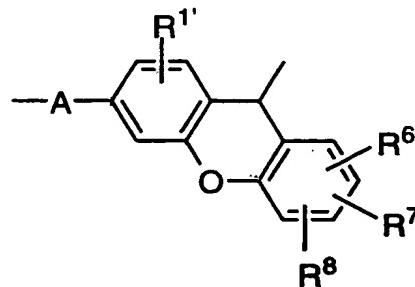
20

R^1 , R^{1a} , R^2 , and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$; and

R^3 and R^4 are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and $-NO_2$;

25

or one of R^1 and R^2 taken together with one of R^3 and R^4 and the carbon atoms to which they are attached define a linking group of formula

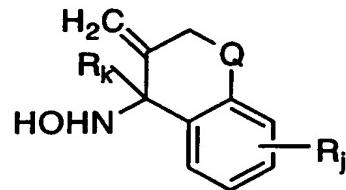


wherein

R¹ is -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

5 R⁶, R⁷ and R⁸ are independently selected from -H, alkyl, alkoxy, halogen, nitrile or -NO₂.

52. A process for the preparation of an α -cyclic hydroxylamine compound of formula

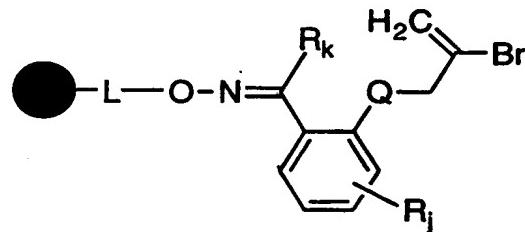


10

wherein R_j and R_k are aliphatic or aromatic and Q is -O- or -CH₂-,

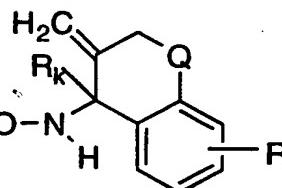
comprising

15 (a) treating a polymeric acetophenone oxime compound of formula



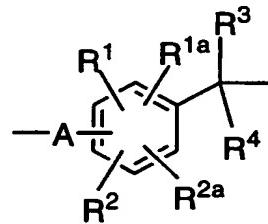
wherein [REDACTED] is a solid support and L is absent or a linking group,

20 with trialkyltin hydride and a radical initiator to form a polymeric α -cyclic hydroxylamine resin compound of formula



; and

- (b) treating the polymeric α -cyclic hydroxylamine resin compound with aqueous acid.
- 5 53. The process of claim 52 wherein L is a linking group.
54. The process of claim 53 wherein L is a linking group of formula



10

wherein

A is absent or a group of formula -X¹-Z- whereinX¹ is -CHR- or -CHR-Y-CO-(CH₂)_n- wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or -NO₂,

15

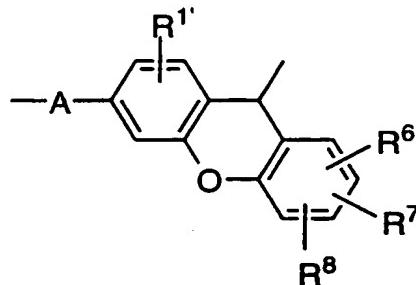
Y is -O- or -NH-,

n is an integer from 1 to 6, and

Z is -O- or -NH-;

20

R¹, R^{1a}, R², and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or -NO₂; andR³ and R⁴ are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and -NO₂;25 or one of R¹ and R² taken together with one of R³ and R⁴ and the carbon atoms to which they are attached define a linking group of formula



wherein

R¹ is -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

5 R⁶, R⁷ and R⁸ are independently selected from -H, alkyl, alkoxy, halogen, nitrile or -NO₂.

55. The process of claim 54 wherein the trialkyltin hydride is tri-n-butyltin hydride.

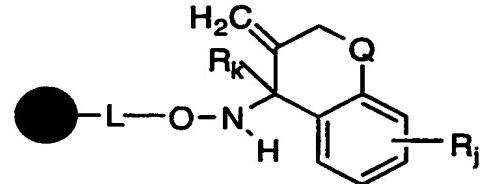
56. The process of claim 55 wherein the radical initiator is 2,2'-azobisisobutyronitrile.

10

57. A process for the preparation of a α -cyclic amino compound of formula



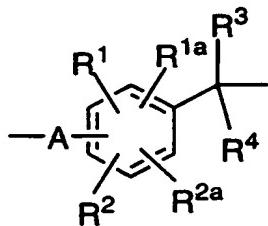
15 wherein R_j and R_k are aliphatic or aromatic and Q is -O- or -CH₂- comprising
reductively cleaving a polymeric α -cyclic hydroxylamine resin compound of formula



20 wherein is a solid support and L is absent or a linking group.

58. The process of claim 57 wherein the reductive cleavage is accomplished using a hydride reducing agent.

59. The process of claim 58 wherein the hydride reducing agent is LiAlH₄.
 60. The process of claim 59 wherein L is a linking group.
 - 5 61. The process of claim 60 wherein L is a linking group of formula



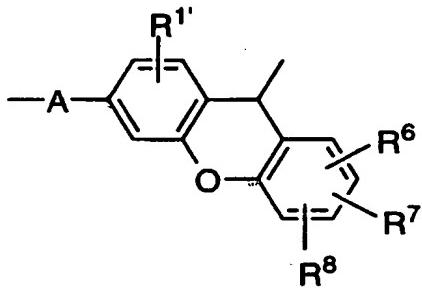
wherein

- 10 A is absent or a group of formula $-X^1-Z-$ wherein
 X^1 is $-CHR-$ or $-CHR-Y-CO-(CH_2)_n-$ wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$,
Y is $-O-$ or $-NH-$,
n is an integer from 1 to 6, and

15 Z is $-O-$ or $-NH-$;

R¹, R^{1a}, R², and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$; and

20 R³ and R⁴ are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and $-NO_2$;
or one of R¹ and R² taken together with one of R³ and R⁴ and the carbon atoms to which they are attached define a linking group of formula

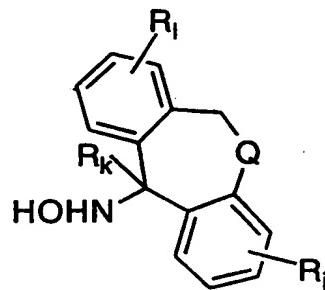


.25

wherein

R' is -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$; and

R^6 , R^7 and R^8 are independently selected from -H, alkyl, alkoxy, halogen, nitrile or $-NO_2$.

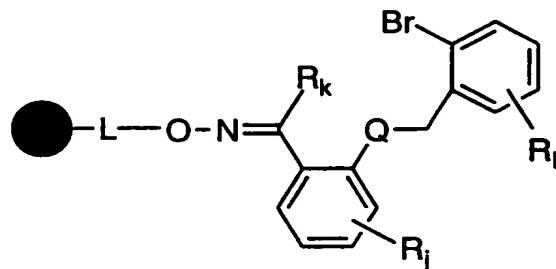
62. A process for the preparation of a α -cyclic hydroxylamine compound of formula

5

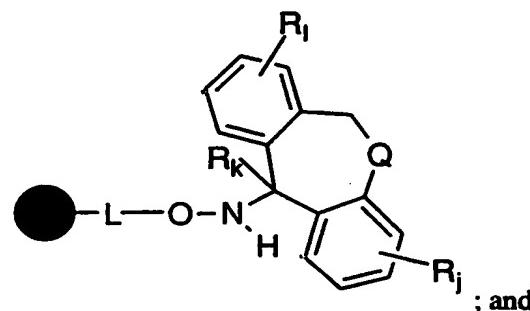
wherein R_j , R_k and R_i are aliphatic or aromatic and Q is $-O-$ or $-CH_2-$,

comprising

- 10 (a) treating a polymeric acetophenone oxime compound of formula



- 15 wherein L is a solid support and L is absent or a linking group,
with trialkyltin hydride and a radical initiator to form a polymeric α -cyclic hydroxylamine resin compound of formula

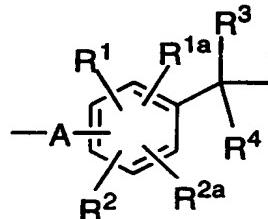


- 20 (b) treating the polymeric α -cyclic hydroxylamine resin compound with aqueous acid.

SUBSTITUTE SHEET (RULE 26)

63. The process of claim 62 wherein L is a linking group.
64. The process of claim 63 wherein L is a linking group of formula

5



wherein

A is absent or a group of formula -X¹-Z- wherein

10 X¹ is -CHR- or -CHR-Y-CO-(CH₂)_n- wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or -NO₂,
Y is -O- or -NH-,
n is an integer from 1 to 6, and
Z is -O- or -NH-;

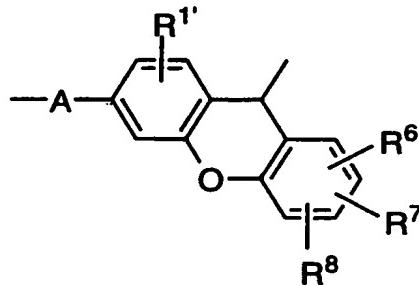
15

R¹, R^{1a}, R², and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

R³ and R⁴ are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and -NO₂;

20

or one of R¹ and R² taken together with one of R³ and R⁴ and the carbon atoms to which they are attached define a linking group of formula



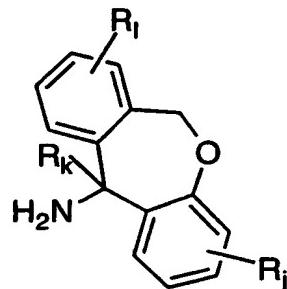
25

wherein

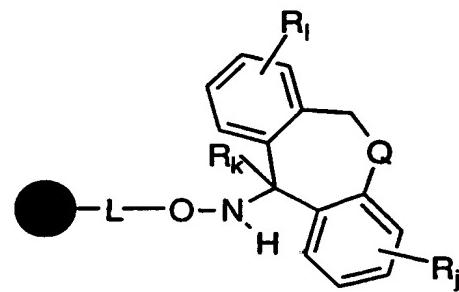
R^{1'} is -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

R⁶, R⁷ and R⁸ are independently selected from -H, alkyl, alkoxy, halogen, nitrile or -NO₂.

65. The process of claim 64 wherein the trialkyltin hydride is tri-n-butyltin hydride.
66. The process of claim 65 wherein the radical initiator is 2,2'-azobisisobutyronitrile.
- 5 67. A process for the preparation of a α -cyclic amino compound of formula



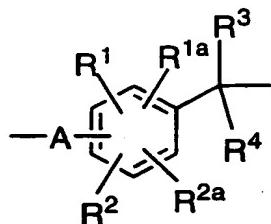
10 wherein Rj, Rk and Rl are aliphatic or aromatic and Q is -O- or -CH₂-, comprising
reductively cleaving a polymeric α -cyclic hydroxylamine resin compound of formula



15 wherein [REDACTED] is a solid support and L is absent or a linking group.

68. The process of claim 67 wherein the reductive cleavage is accomplished using a hydride reducing agent.
- 20 69. The process of claim 68 wherein the hydride reducing agent is LiAlH₄.
70. The process of claim 69 wherein L is a linking group.

71. The process of claim 70 wherein L is a linking group of formula



5 wherein

A is absent or a group of formula -X¹-Z- wherein

X¹ is -CHR- or -CHR-Y-CO-(CH₂)_n- wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or -NO₂,

Y is -O- or -NH-,

10 n is an integer from 1 to 6, and

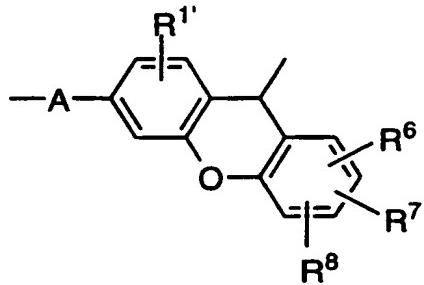
Z is -O- or -NH-;

R¹, R^{1a}, R², and R^{2a} are independently -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

15 R³ and R⁴ are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and -NO₂;

or one of R¹ and R² taken together with one of R³ and R⁴ and the carbon atoms to which they are attached define a linking group of formula

20

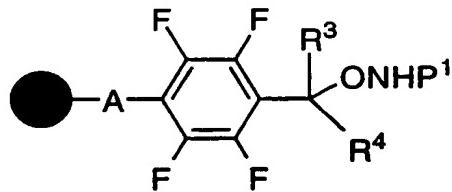


wherein

R^{1'} is -H, alkyl, alkoxy, halogen, nitrile or -NO₂; and

25 R⁶, R⁷ and R⁸ are independently selected from -H, alkyl, alkoxy, halogen, nitrile or -NO₂.

72. A polymeric tetrafluorophenyl hydroxylamine resin compound of formula



5 wherein

is a solid support;

A is absent or a group of formula -X¹-Z- wherein

10 X¹ is -CHR- or -CHR-Y-CO-(CH₂)_n- wherein R is H, alkyl, phenyl, or phenyl substituted with -H, alkyl, alkoxy, halogen, nitrile or -NO₂,
Y is -O- or -NH-,
n is an integer from 1 to 6, and
Z is -O- or -NH-;

15 R³ and R⁴ are independently -H, alkyl, phenyl, or phenyl substituted with one or more substituents selected from alkyl, alkoxy, halogen nitrile and -NO₂; and

P¹ is H or an amine protecting group.

20 73. A polymeric tetrafluorophenyl hydroxylamine resin compound according to claim 72 wherein A is -O-.

25 74. A polymeric tetrafluorophenyl hydroxylamine resin compound according to claim 73 wherein one of R³ and R⁴ is H and the other is H or 2,4-dimethoxyphenyl.

75. A polymeric tetrafluorophenyl hydroxylamine resin compound according to claim 74 wherein P¹ is H.

30 76. A polymeric hydroxylamine resin compound according to claim 74 wherein P¹ is allyloxycarbonyl.

77. A polymeric hydroxylamine resin compound according to claim 74 which is
4-(O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-1% divinylbenzene) resin
or
4-(2',4'-dimethoxyphenyl-O-methylhydroxylamine)-2,3,5,6-tetrafluorophenoxyethyl-copoly(styrene-
5 1% divinylbenzene) resin.

INTERNATIONAL SEARCH REPORT

International application No.

PCT/US97/23920

A. CLASSIFICATION OF SUBJECT MATTER

IPC(6) :Please See Extra Sheet.

US CL :Please See Extra Sheet.

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

U.S. : 526/347; 549/323, 354, 404; 562/621; 564/298, 299, 300, 489; 568/315, 318.

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched
none

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

CAS ONLINE

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim N .
A	WO 96/26223 A1 (BRITISH BIOTECH PHARMACEUTICALS LIMITED) 29 August 1996, see the entire document.	1-75

 Further documents are listed in the continuation of Box C. See patent family annex.

•	Special categories of cited documents:	"T"	later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
"A"	document defining the general state of the art which is not considered to be of particular relevance	"X"	document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
"B"	earlier document published on or after the international filing date	"Y"	document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art
"L"	document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)	"Z"	document member of the same patent family
"O"	document referring to an oral disclosure, use, exhibition or other means		
"P"	document published prior to the international filing date but later than the priority date claimed		

Date of the actual completion of the international search

21 MAY 1998

Date of mailing of the international search report

10 JUN 1998 (10.06.98)

Name and mailing address of the ISA/US
Commissioner of Patents and Trademarks
Box PCT
Washington, D.C. 20231

Facsimile N . (703) 305-3230

Authorized officer

BA K. TRINH

Telephone No. (703) 308-1235

INTERNATIONAL SEARCH REPORT

International application No.

PCT/US97/23920

A. CLASSIFICATION OF SUBJECT MATTER:

IPC (6):

C07C 45/00, 209/40, 239/08, 259/06, 291/04; C07D 307/33, 311/68, 313/12; C08F 212/08, 212/36

A. CLASSIFICATION OF SUBJECT MATTER:

US CL :

526/347; 549/323, 354, 404; 562/621; 564/298, 299, 300, 489; 568/315, 318.



INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(51) International Patent Classification ⁶ : C07C 45/00, 209/40, 239/08, 259/06, 291/04, C07D 307/33, 311/68, 313/12, C08F 212/08, 212/36		A1	(11) International Publication Number: WO 98/29376 (43) International Publication Date: 9 July 1998 (09.07.98)
(21) International Application Number: PCT/US97/23920			Limerick, PA 19468 (US). MASON, Helen, J. [US/US]; 8 Foxcroft Lane, Phoenixville, PA 19460 (US). LABAUDINIERE, Richard, F. [FR/US]; 220 Richard Way, Collegeville, PA 19426 (US).
(22) International Filing Date: 17 December 1997 (17.12.97)			
(30) Priority Data: 60/032,453 19 December 1996 (19.12.96) US 60/033,881 24 December 1996 (24.12.96) US			(74) Agents: MARTIN, Michael, B. et al.; Rhône-Poulenc Rorer Pharmaceuticals Inc., P.O. Box 5093, Mail Stop 3C43, Collegeville, PA 19426-0997 (US).
(63) Related by Continuation (CON) or Continuation-in-Part (CIP) to Earlier Applications US 60/033,881 (CIP) Filed on 24 December 1996 (24.12.96) US 60/032,453 (CIP) Filed on 19 December 1996 (19.12.96)			(81) Designated States: AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, CA, CN, CU, CZ, DE, DK, EE, ES, FI, GB, GE, GH, HU, IL, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MD, MG, MK, MN, MW, MX, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR, TT, UA, UG, US, UZ, VN, YU, ZW, ARIPO patent (GH, GM, KE, LS, MW, SD, SZ, UG, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, CH, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, ML, MR, NE, SN, TD, TG).
(71) Applicant (for all designated States except US): RHONE-POULENC RORER PHARMACEUTICALS INC. [US/US]; Legal/Patents, Mail Stop #3C43, P.O. Box 5093, Collegeville, PA 19426-0997 (US).			Published <i>With international search report.</i> <i>Before the expiration of the time limit for amending the claims and to be republished in the event of the receipt of amendments.</i>
(72) Inventors; and (75) Inventors/Applicants (for US only): SALVINO, Joseph, M. [US/US]; 272 Second Street, Schwenksville, PA 19473 (US). MORTON, George, C. [US/US]; 206 Bassett Court,			

(54) Title: PROCESS FOR THE SOLID PHASE SYNTHESIS OF ALDEHYDES, KETONES, OXIMES, AMINES AND HYDROXAMIC ACID COMPOUNDS

(57) Abstract

This invention is directed to processes for the solid-phase synthesis of aldehydes, ketones, oximes, amines and hydroxamic acid compounds and to polymeric hydroxylamine resin compounds useful therefor.

FOR THE PURPOSES OF INFORMATION ONLY

Codes used to identify States party to the PCT on the front pages of pamphlets publishing international applications under the PCT.

AL	Albania	ES	Spain	LS	Lesotho	SI	Slovenia
AM	Armenia	FI	Finland	LT	Lithuania	SK	Slovakia
AT	Austria	FR	France	LU	Luxembourg	SN	Senegal
AU	Australia	GA	Gabon	LV	Latvia	SZ	Swaziland
AZ	Azerbaijan	GB	United Kingdom	MC	Monaco	TD	Chad
BA	Bosnia and Herzegovina	GE	Georgia	MD	Republic of Moldova	TG	Togo
BB	Barbados	GH	Ghana	MG	Madagascar	TJ	Tajikistan
BE	Belgium	GN	Guinea	MK	The former Yugoslav Republic of Macedonia	TM	Turkmenistan
BF	Burkina Faso	GR	Greece	ML	Mali	TR	Turkey
BG	Bulgaria	HU	Hungary	MN	Mongolia	TT	Trinidad and Tobago
BJ	Benin	IE	Ireland	MR	Mauritania	UA	Ukraine
BR	Brazil	IL	Israel	MW	Malawi	UG	Uganda
BY	Belarus	IS	Iceland	MX	Mexico	US	United States of America
CA	Canada	IT	Italy	NE	Niger	UZ	Uzbekistan
CF	Central African Republic	JP	Japan	NL	Netherlands	VN	Viet Nam
CG	Congo	KE	Kenya	NO	Norway	YU	Yugoslavia
CH	Switzerland	KG	Kyrgyzstan	NZ	New Zealand	ZW	Zimbabwe
CI	Côte d'Ivoire	KP	Democratic People's Republic of Korea	PL	Poland		
CM	Cameroon	KR	Republic of Korea	PT	Portugal		
CN	China	KZ	Kazakhstan	RO	Romania		
CU	Cuba	LC	Saint Lucia	RU	Russian Federation		
CZ	Czech Republic	LJ	Liechtenstein	SD	Sudan		
DE	Germany	LK	Sri Lanka	SE	Sweden		
DK	Denmark	LR	Liberia	SG	Singapore		